



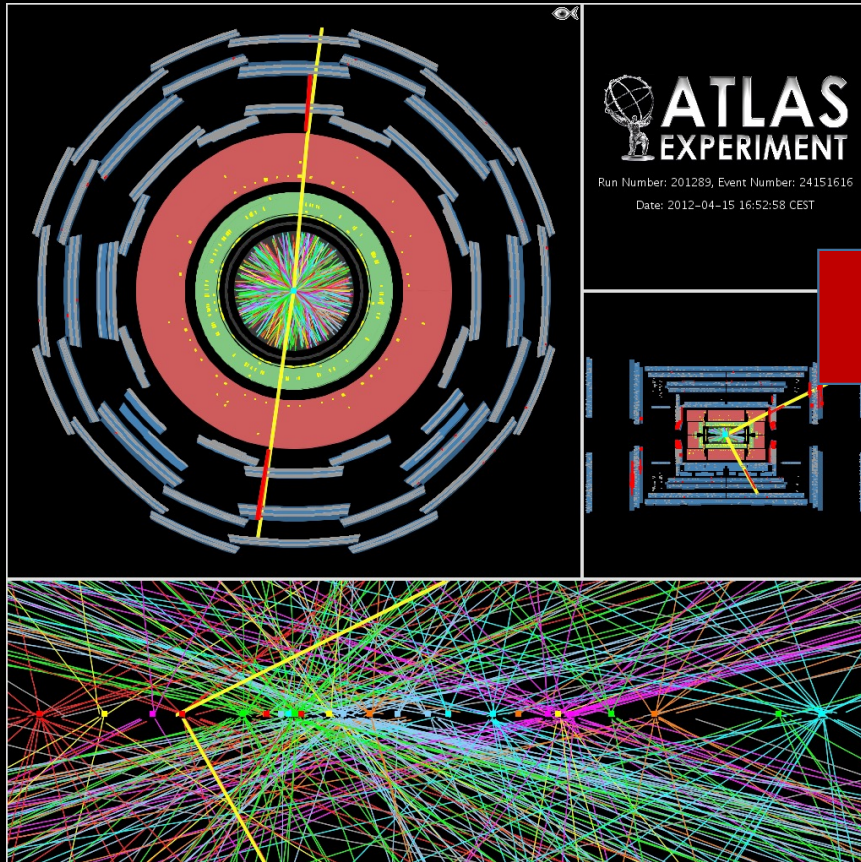
Innovative silicon detectors for HL-LHC

Daniela Bortoletto

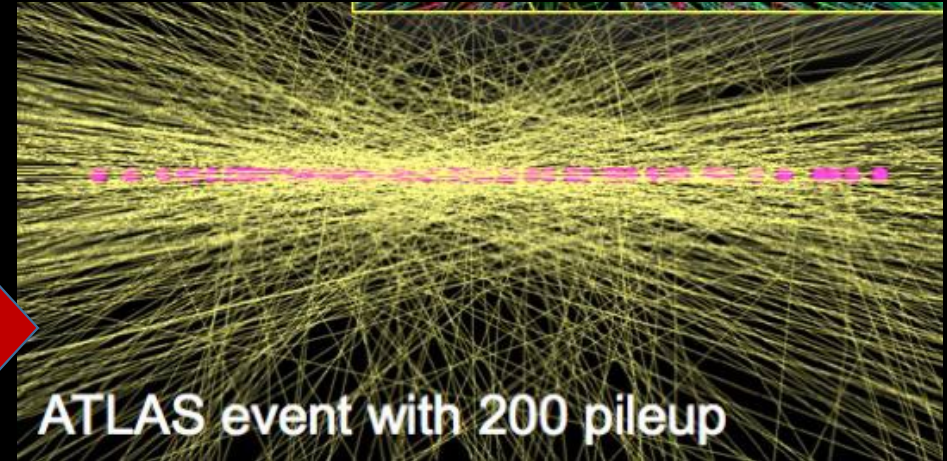
D. Bortoletto, Lecture 2

The incredible challenge of HL-LHC

Run 2 LHC pileup $\langle \mu \rangle = 37$



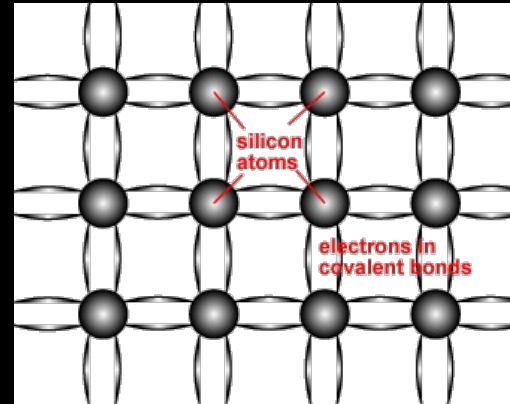
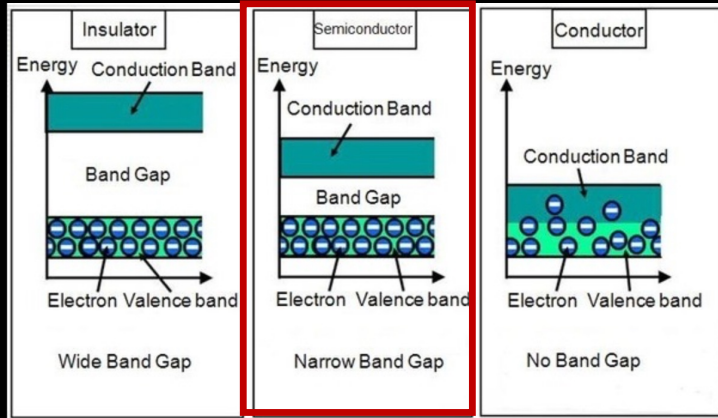
HL-LHC pileup $\langle \mu \rangle = 200$



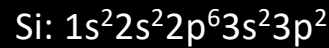
- Radiation levels up to:
 - fluence of 2×10^{16} 1 MeV n_{eq}/cm^2
 - Total Ionizing Dose (TID) ~ 1 Grad
 - Damage due to multitude of particles (charged particles, neutrons, etc...)

Silicon

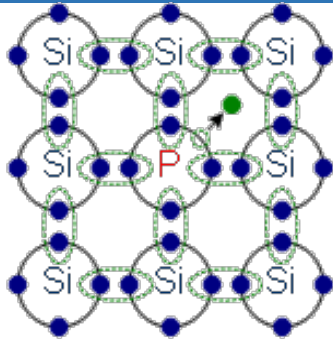
- Second-most abundant element on the planet, after oxygen.



- At $T > 0$ K electrons can move to the conduction band
- In a semiconductor the number of mobile charge carriers varies with temperature.



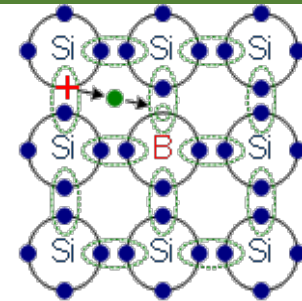
n-type silicon doped with P or As – contains excess electron (donor)



Electrons – Majority carriers

13 5 B Boron 10.811	14 6 C Carbon 12.011	15 7 N Nitrogen 14.007
13 13 Al Aluminum 26.982	14 14 Si Silicon 28.086	15 15 P Phosphorus 30.974
31 31 Ga Gallium 69.723	32 32 Ge Germanium 72.631	33 33 As Arsenic 74.922

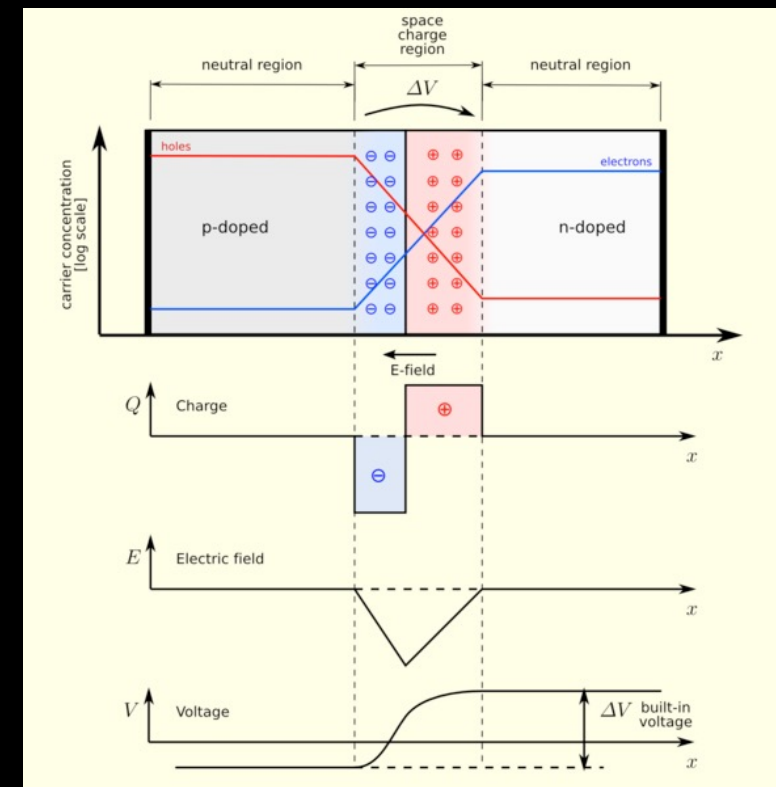
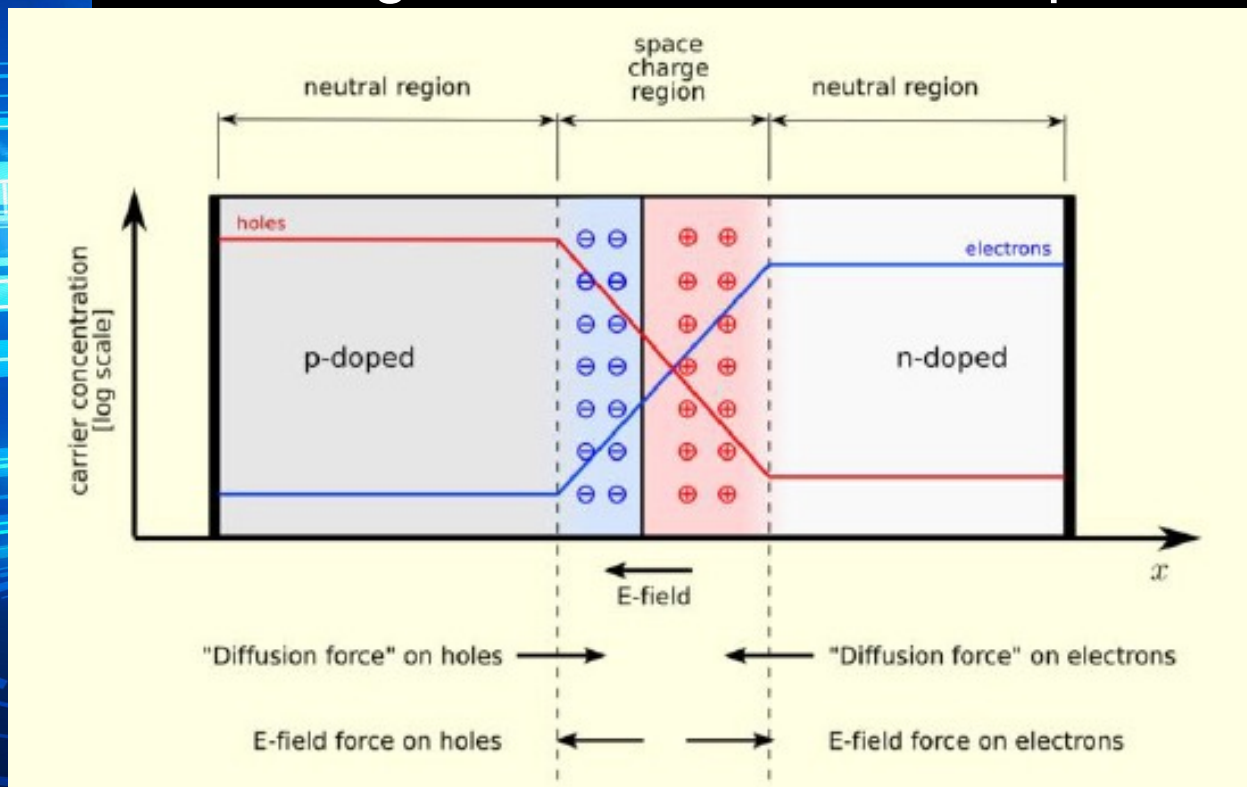
p-type silicon doped with B, or Ga – with one less electron (acceptor)



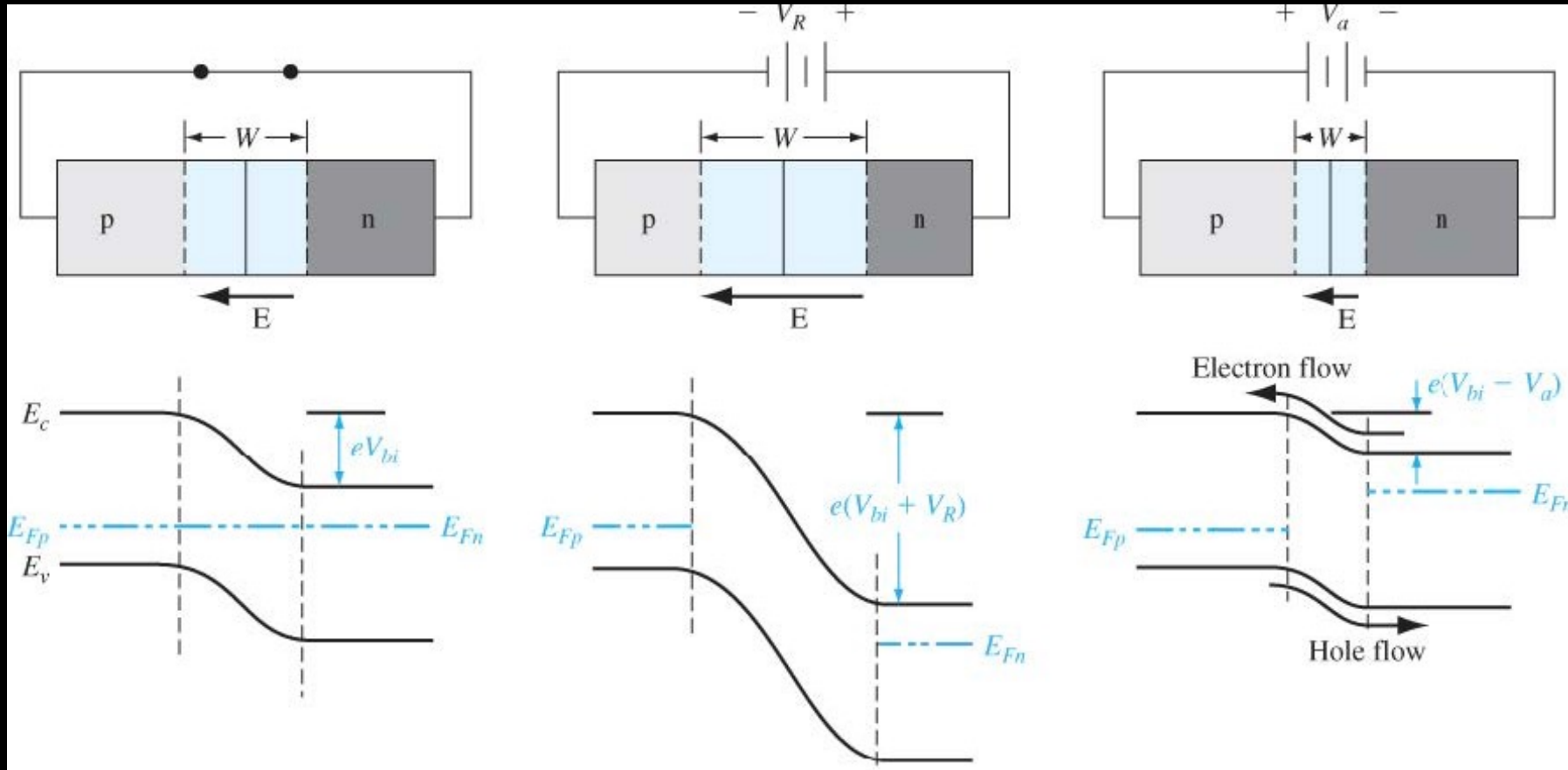
Holes – Majority carriers

P-N junction

- In an unbiased p-n junction diode majority carriers migrate from one side to the opposite side, until the potential difference - ΔV – due to the charge distribution halts the process.



P-N Junction



Principles of a semiconductor detector

- Voltage to deplete thickness d

$$V_{dep} = d^2 N_{eff} \frac{e}{2\epsilon\epsilon_0}$$

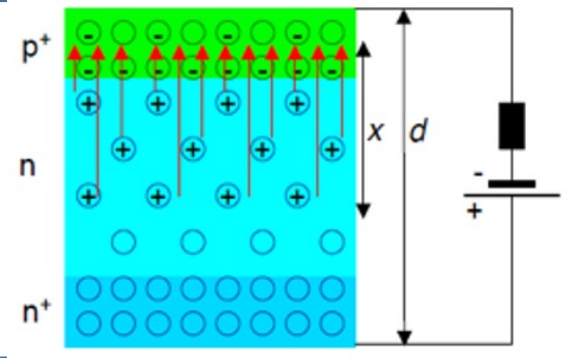
$$N_{eff} = N_{donors} - N_{acceptors}$$

doping concentration =

$$N_a \approx 10^{15} \text{ cm}^{-3}$$

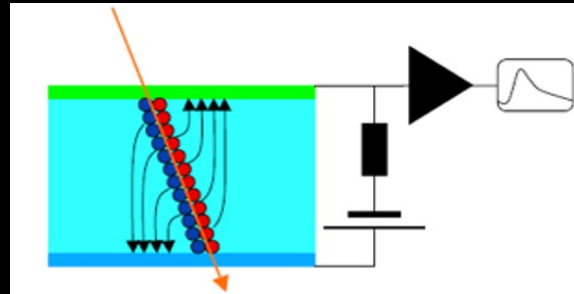
$$N_d \approx 10^{12} \text{ cm}^{-3}$$

$$N_d \approx 10^{15} \text{ cm}^{-3}$$



- Ionizing particles create e-h pairs that drift in the E field and induce signal on electrodes

$E(\text{e-h pair}) = 3.62 \text{ eV}$ ($\approx 30 \text{ eV}$ for e-ion in gas)
 dE/dx (M.I.P.) $\approx 3.87 \text{ MeV/cm}$
 $N(\text{e-h}) \approx 107/\mu\text{m}$ average value
 $N(\text{e-h}) \approx 80/\mu\text{m}$ most probable value



e and h are different

$$v_{e,h} = \mu_{e,h} E \quad \text{Drift velocity}$$

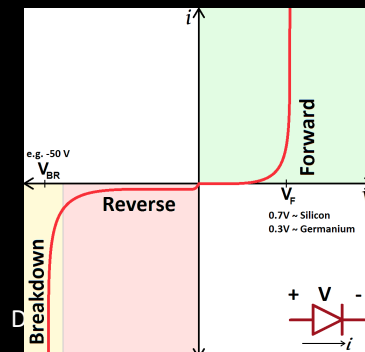
$$\mu_{e,h} = e \tau_{e,h} / m_{e,h} \quad \text{Mobility}$$

$$\mu_e(\text{Si}, 300 \text{ K}) \approx 1450 \text{ cm}^2/\text{Vs}$$

$$\mu_h(\text{Si}, 300 \text{ K}) \approx 450 \text{ cm}^2/\text{Vs}$$

- Keep leakage current low (approximately doubles for $\approx 8^\circ\text{C}$ increase in temperature)

$$I \propto T^{3/2} \exp\left(-\frac{E_g}{2kT}\right) \times \text{Volume}$$



electrons about 3 times faster than holes

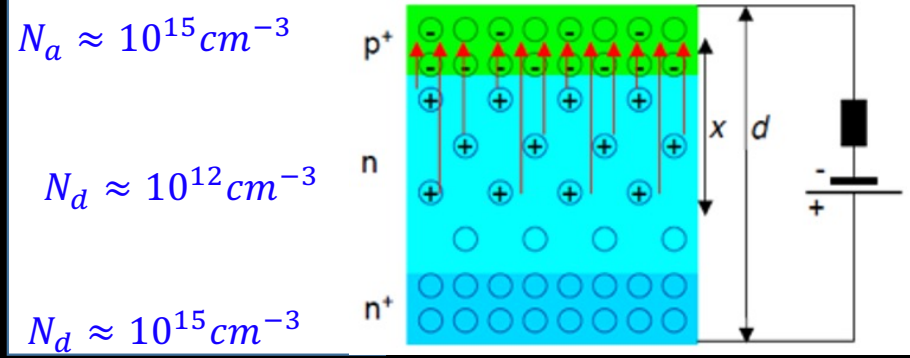
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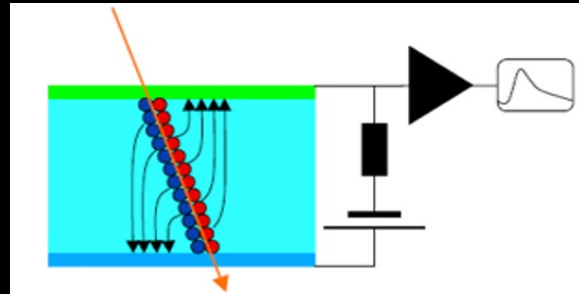
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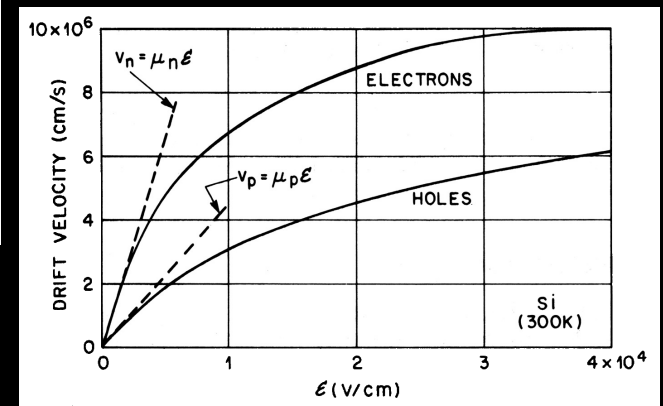


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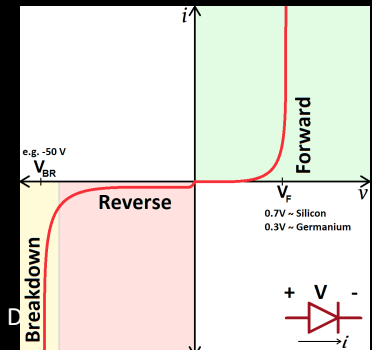


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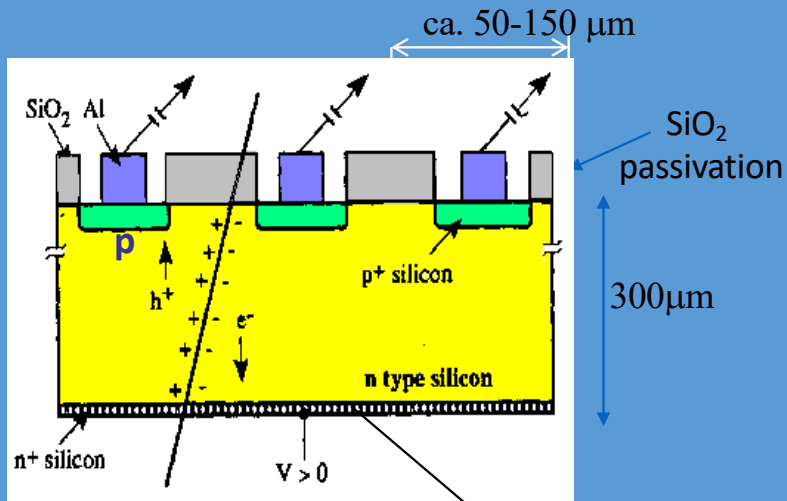
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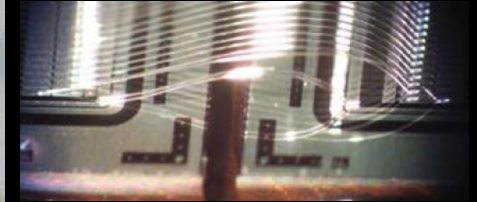
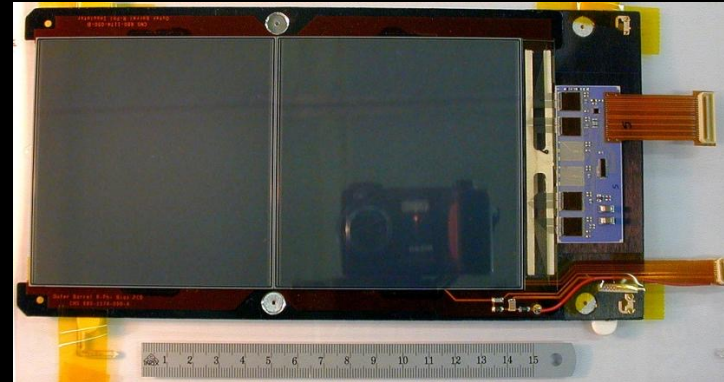
electrons about 3 times faster than holes

Silicon Sensors

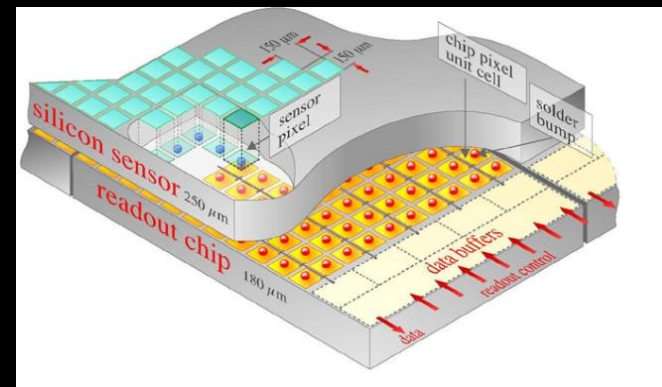


Fully depleted zone

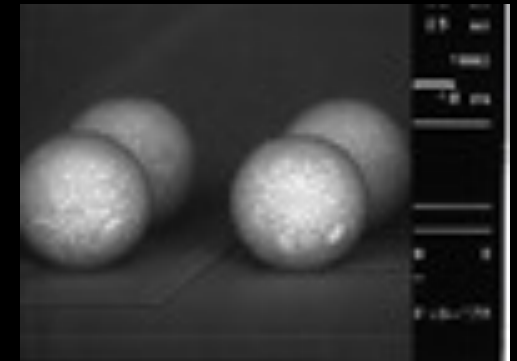
STRIPS



Pixel



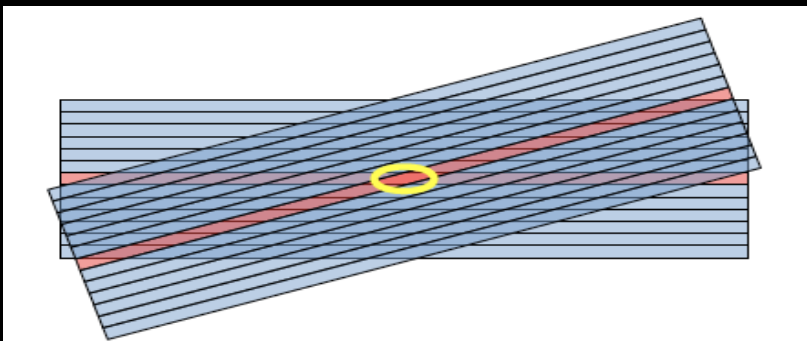
Solder bumps $r \approx 20 \mu\text{m}$



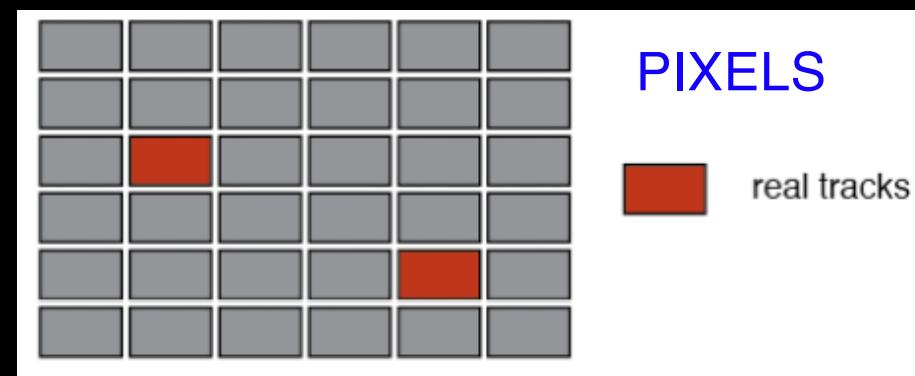
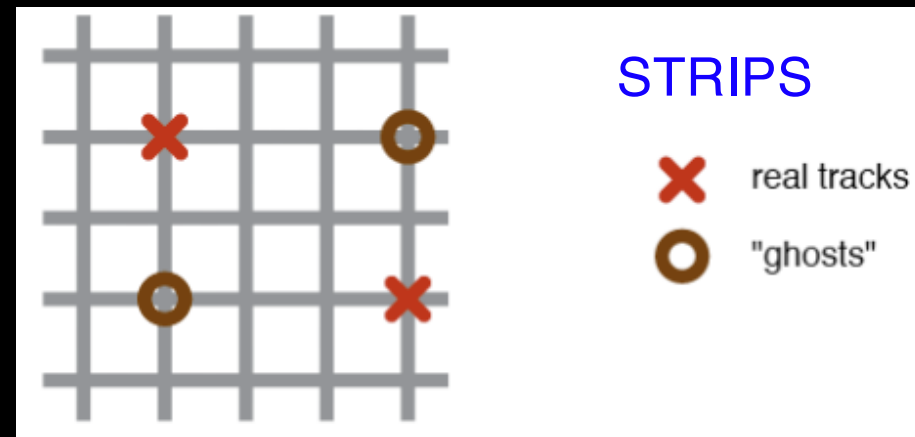
- Thickness 150 - 500 μm
- Strip separation (pitch) 20 - 150 μm
- Resolution 5 - 40 μm (pitch/ $\sqrt{12}$)
- Most probable Energy loss ≈ 80 e-h pairs per μm
- 300 μm thickness \rightarrow 24000 pairs/MIP
- Output signal: $Q_{\text{out}} \sim 4$ fC
- Charge collection 20 ns

Strips versus Pixels

- A strip detector measures 1 coordinate only. Two orthogonal/angled arranged strip detectors could give a 2-dimensional position of a particle track.

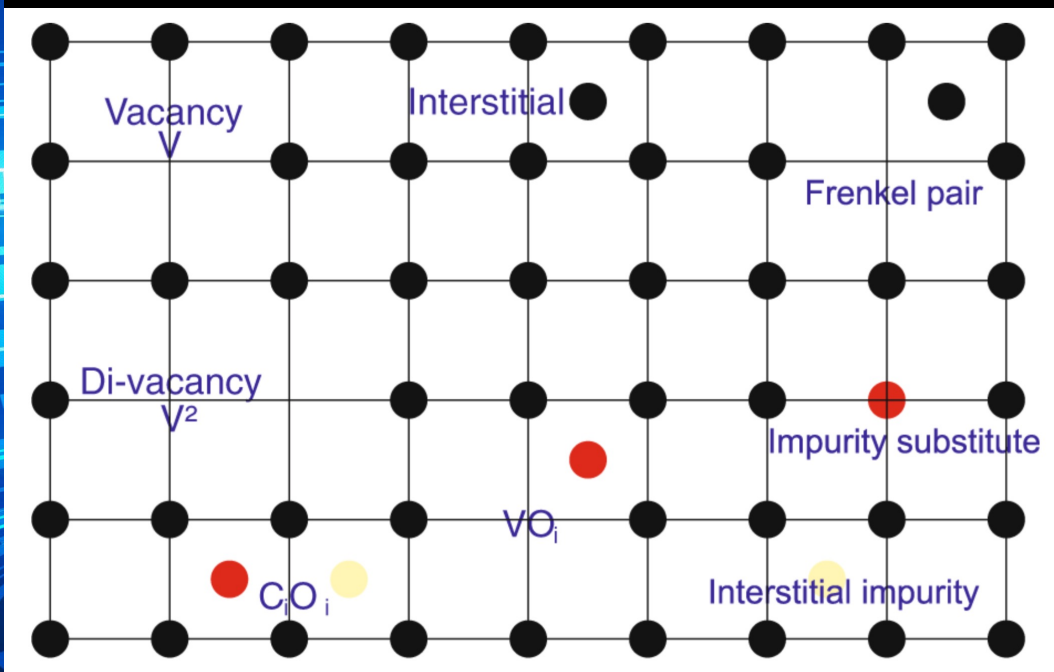


- Pixel detectors produce unambiguous hits!
 - Large number of electrical connections and large power consumption.



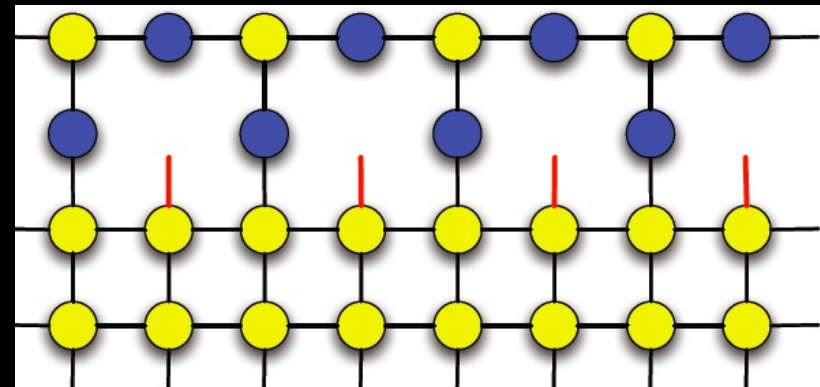
Radiation damage

- **Non ionizing energy loss (NIEL)**
 - Atomic displacement caused by p, n, π
 - Frenkel pair $E \sim 25\text{eV}$, Defect cluster $E \sim 5\text{keV}$



- Affects mainly the sensors and measured in $1\text{ MeV } n_{\text{eq}}$

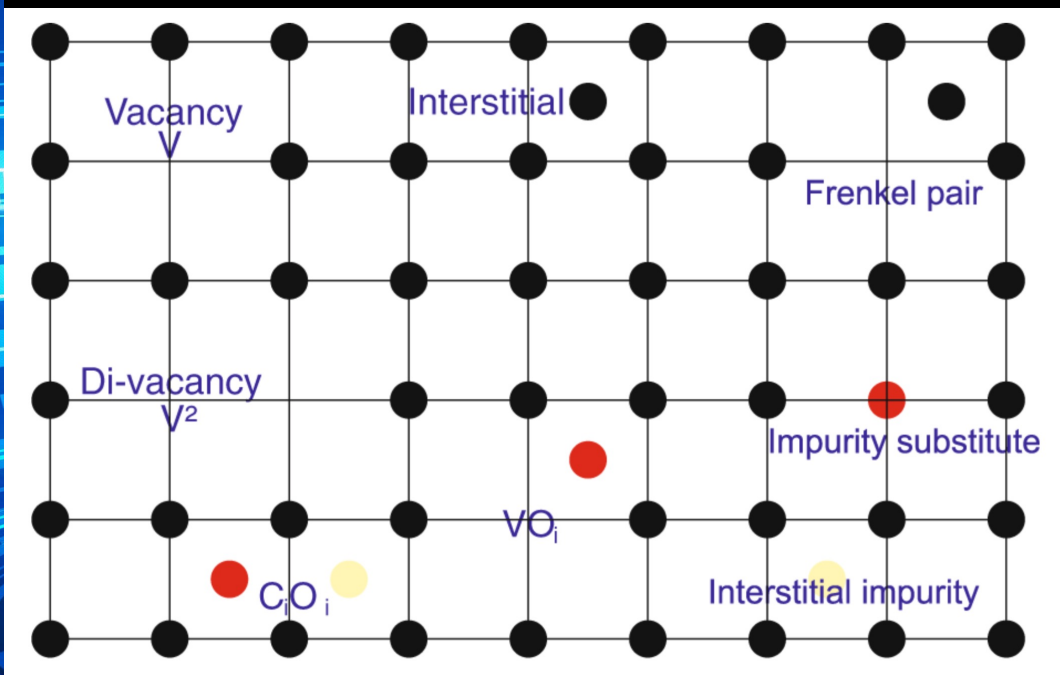
- **Ionizing energy loss**
 - Proportional to absorbed radiation dose
- Measured in $1\text{ Gy} = 100\text{ rad}$
- Ionizing radiation generates bound charge in the SiO_2 layer at the surface of the detectors and at the interface between the Si and the SiO_2 .



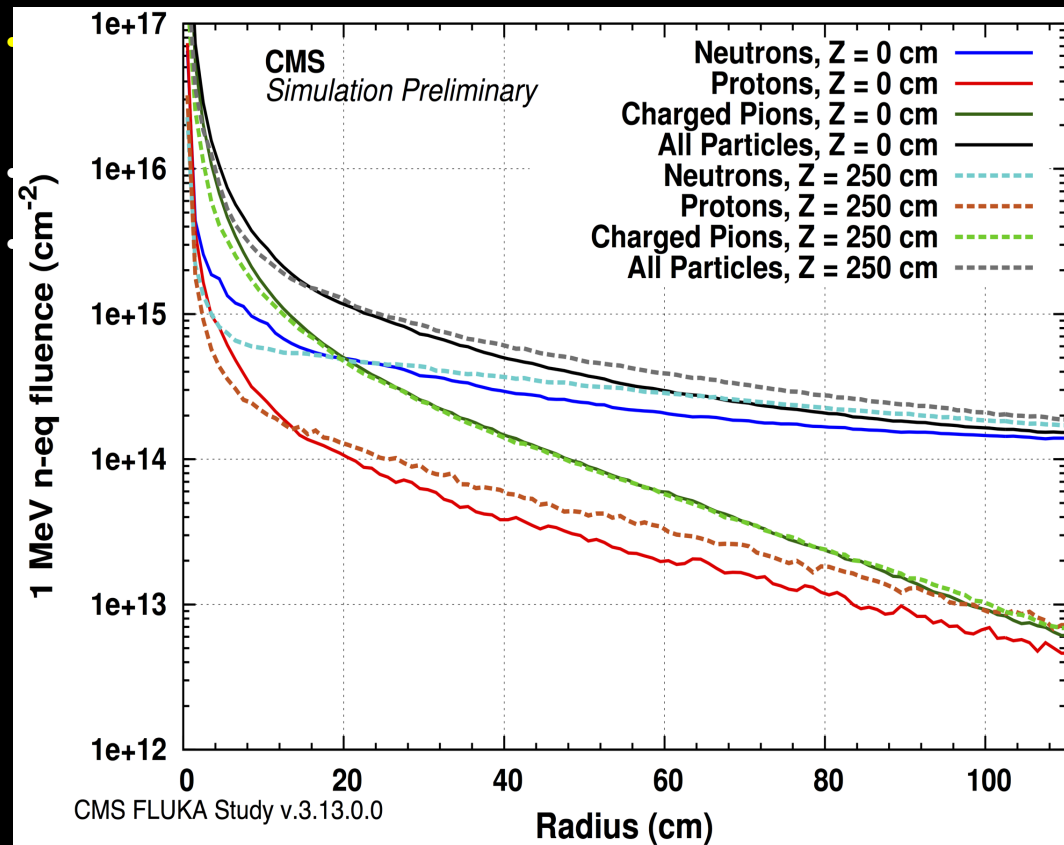
- More problematic for electronics
- Charged particles flux is due to the collisions at the interaction point and decreases as $\sim 1/r^2$.
- Neutrons flux is mainly due backscplash from the calorimeter and it depends on shielding and design

Radiation damage

- Non ionizing energy loss (NIEL)
 - Atomic displacement caused by p,n, π
 - Frenkel pair $E \sim 25\text{eV}$, Defect cluster $E \sim 5\text{keV}$

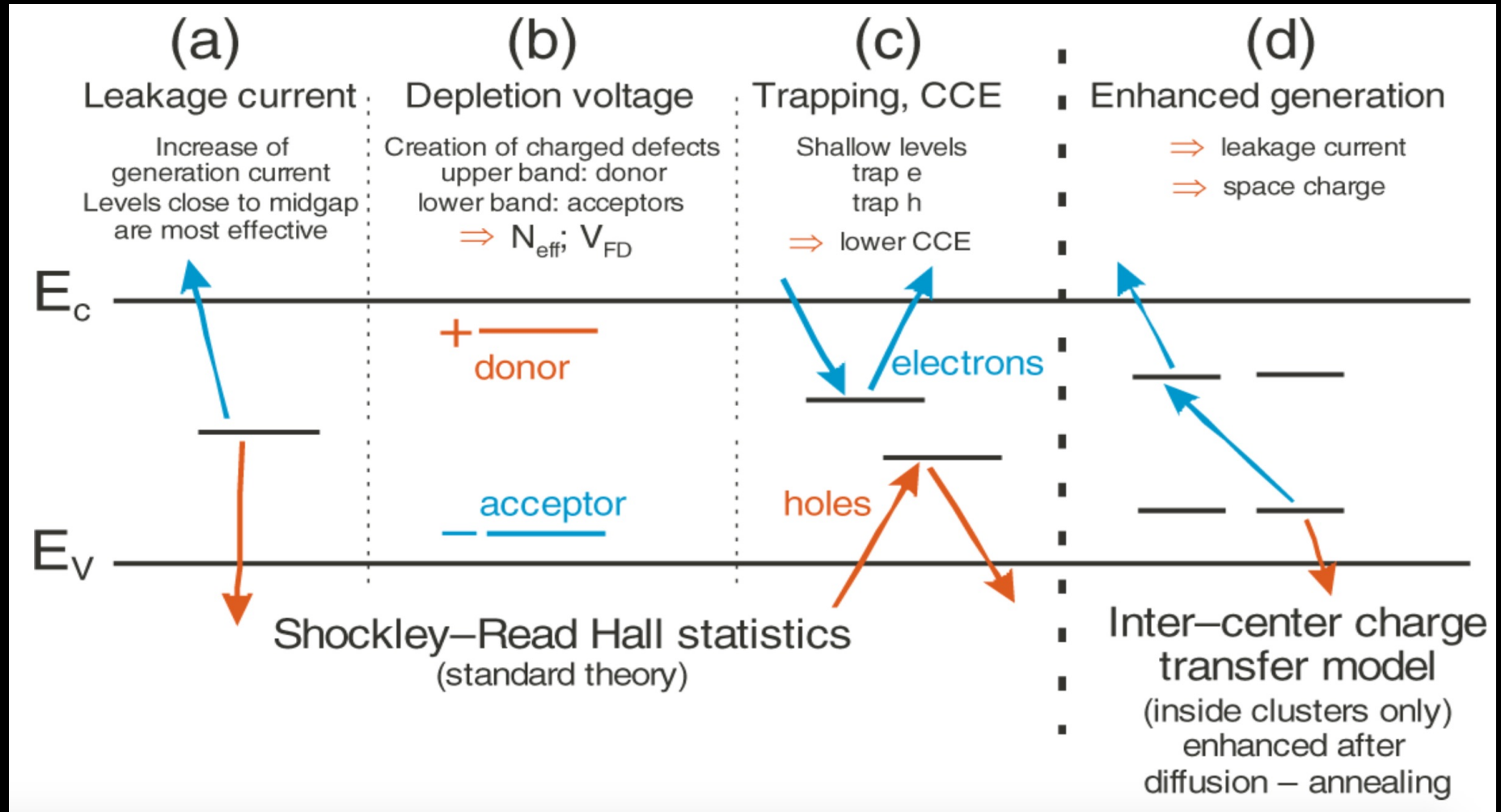


- Affects mainly the sensors and measured in 1 MeV n_{eq}



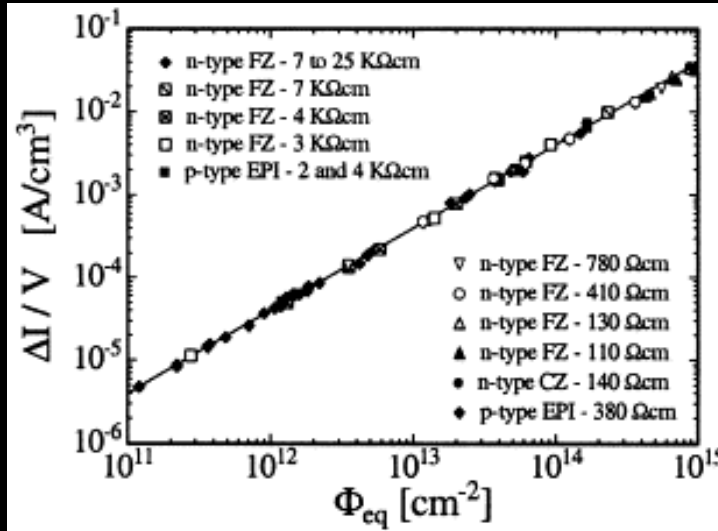
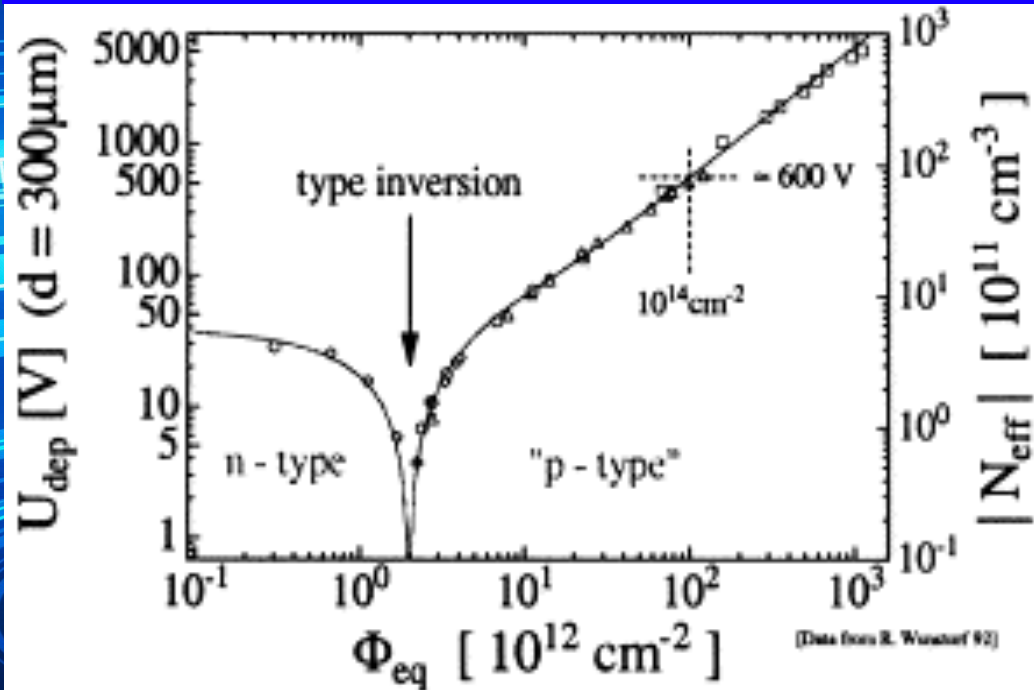
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Radiation effects (RD50)

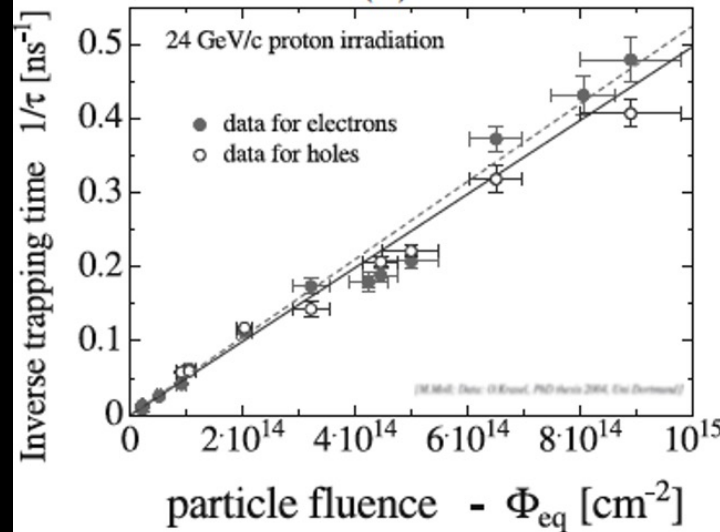


Radiation effects

Increase in V_{dep} – which becomes very large after $1 \times 10^{14} n_{eq}/cm^2$



Increase in I_{leak} - could lead to thermal runaway



Decrease in trapping time

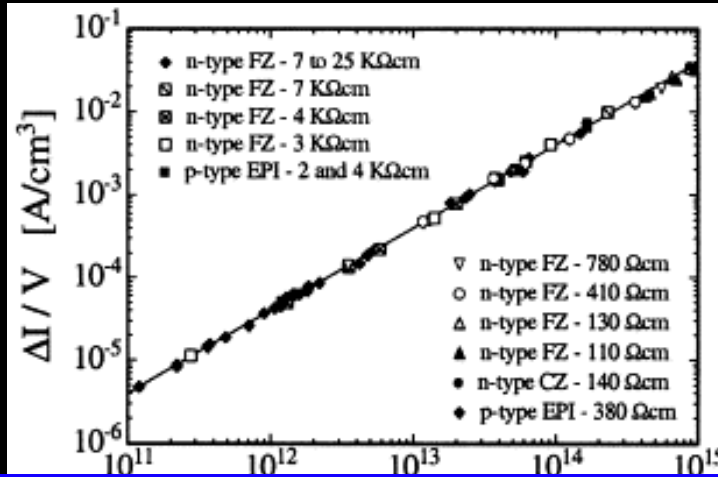
$$\tau_{eff} (10^{15} n/cm^2) = 2 ns: x = (10^7 cm/s) \cdot 2 ns = 200 \mu m$$

$$\tau_{eff} (10^{16} n/cm^2) = 0.2 ns: x = (10^7 cm/s) \cdot 0.2 ns = \underline{20 \mu m}$$

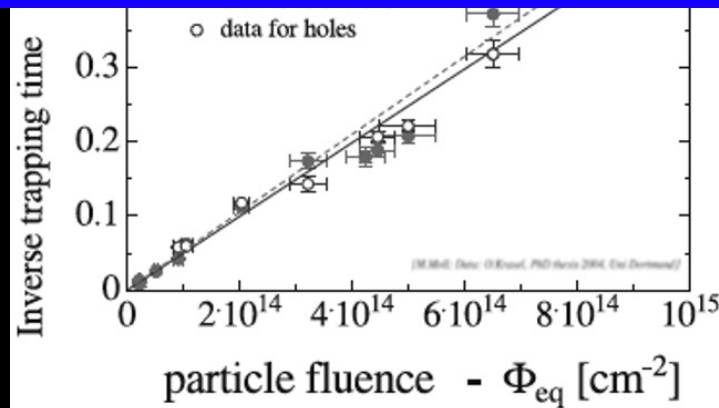
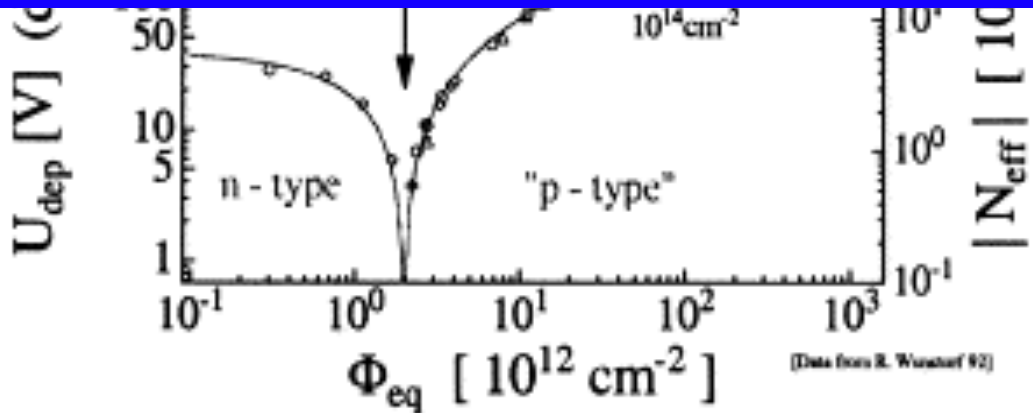
Radiation effects

Increase in V_{dep} – which becomes very large after $1 \times 10^{14} n_{eq}/cm^2$

V_{dep} and I both depend upon the fluence $\Phi \rightarrow$ power consumption (heat generated) \sim fluence $\Phi^2 \rightarrow$ cooling



Increase in I_{leak} - could lead to thermal runaway



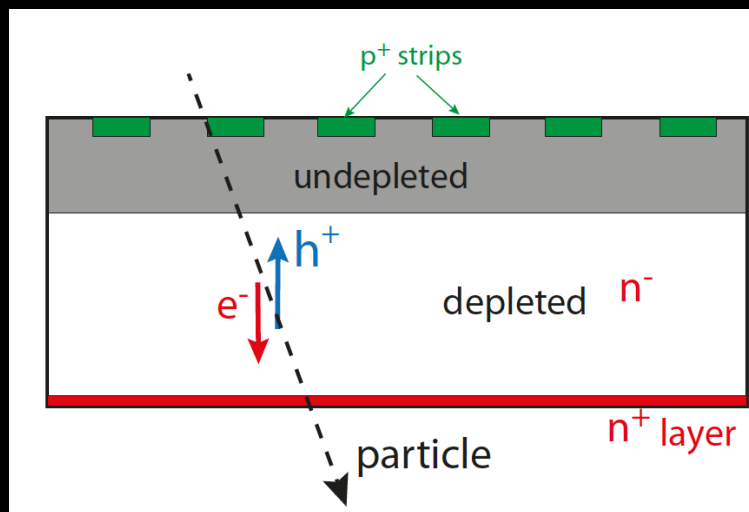
Decrease in trapping time

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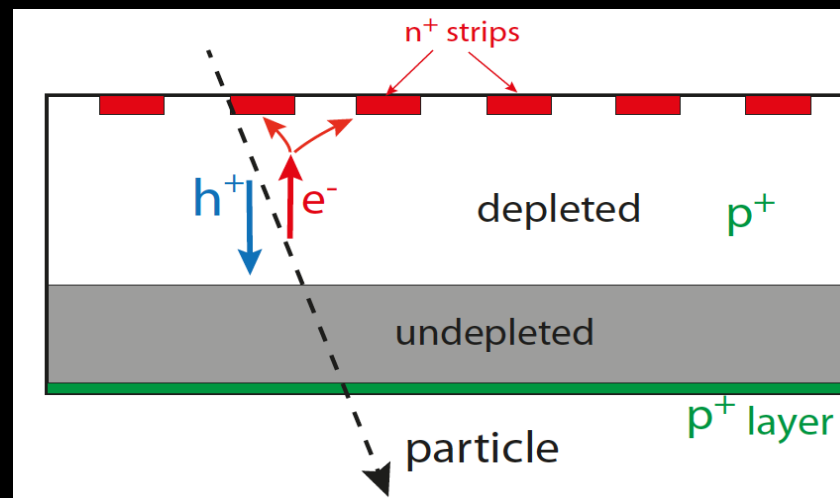
$$\tau_{eff} (10^{16} n/cm^2) = 0.2 ns: x = (10^7 cm/s) \cdot 0.2 ns = \underline{20 \mu m}$$

Silicon detectors for HL-LHC

- LHC and pre-LHC: p^+ in n
- For HL-LHC upgrade: n^+ in p



- Consequences:
 - signal loss
 - resolution degradation due to charge spreading

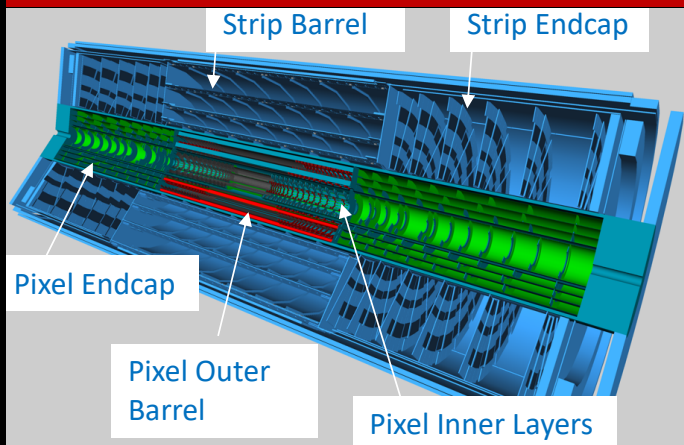


- Advantages:
 - faster charge collection (electrons have higher v_{drift})
 - Less signal and CCE degradation

p – type substrates used for both strips and pixels

ATLAS ITk

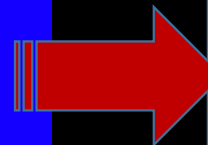
All silicon tracker: ITk



- Same or better performance than current Inner Detector
- Increased granularity to maintain occupancy <1%
- Low mass mechanics, cooling and serial power to minimize material
- Increased radiation hardness

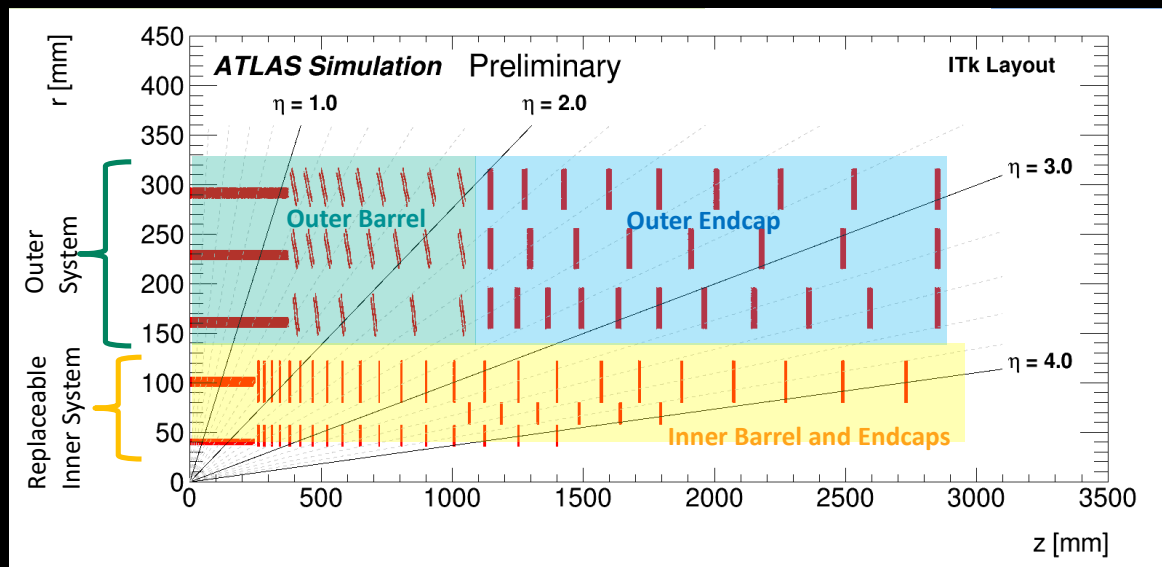
Current pixel system
 ~92M pixels
 ~2000 modules
 ~1.9 m² active area

All sensors 50x500 μm²
 IBL 50x250 μm²



ITk Pixel System
 ~1.4G pixels
 ~9,400 modules
 ~13 m² active area

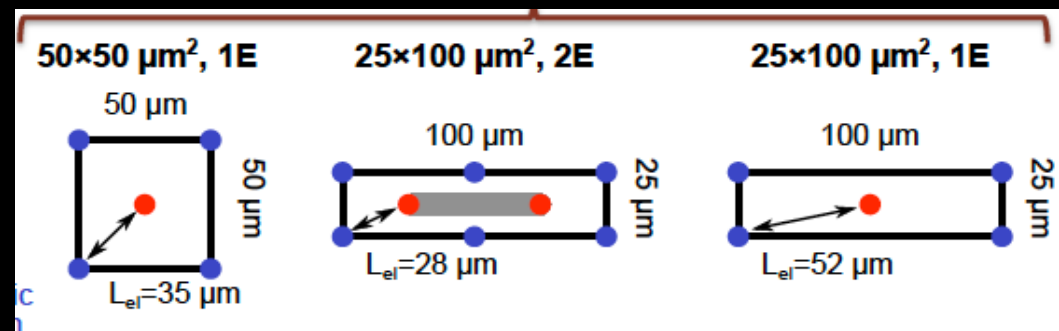
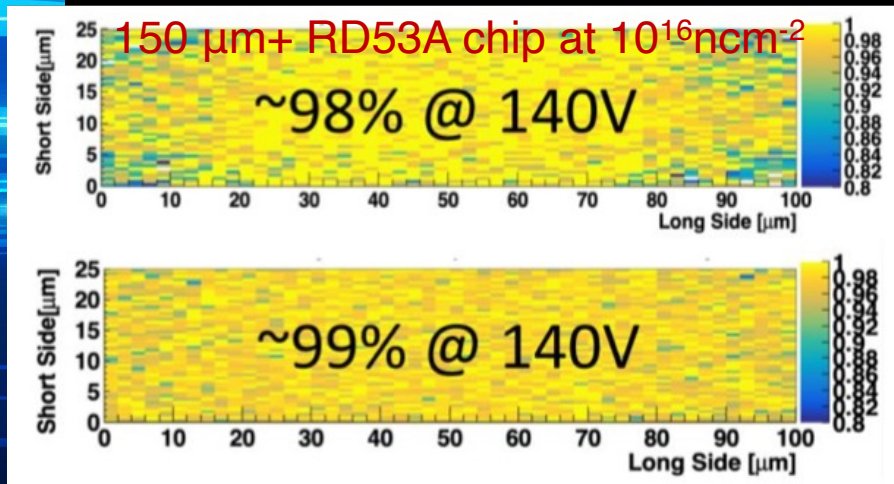
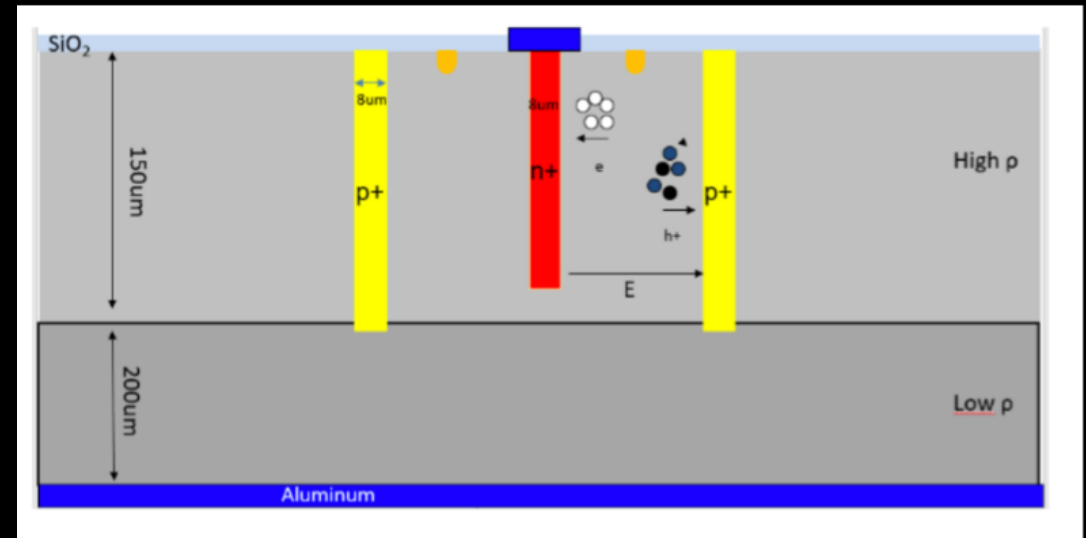
Layer 0 barrel sensors
 25x100 μm²
 All other layers 50x50 μm²



Inner System Replaceable. For (Layer-0 radius=39mm)
 Fluence: $9.2 \times 10^{15} \text{ ncm}^{-2}$ TID: 7.3MGy @2000fb⁻¹

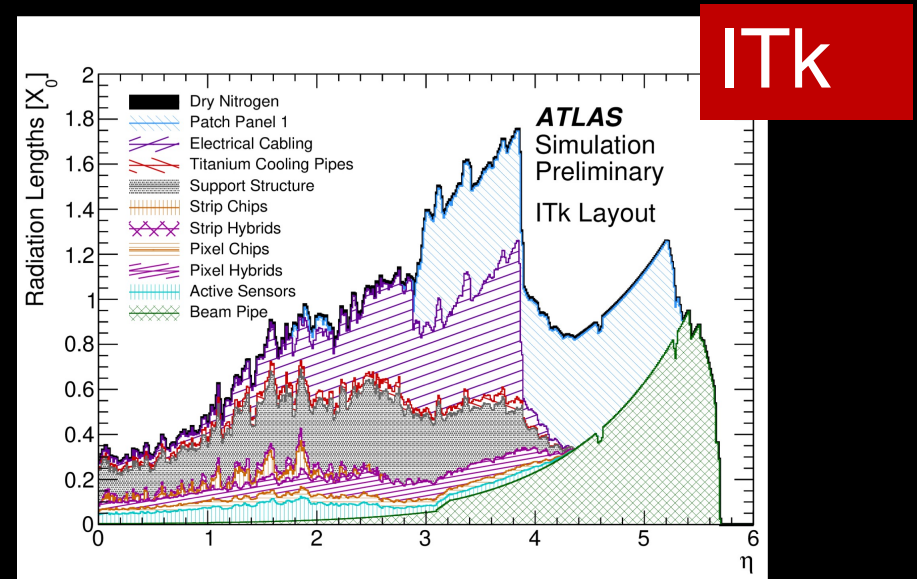
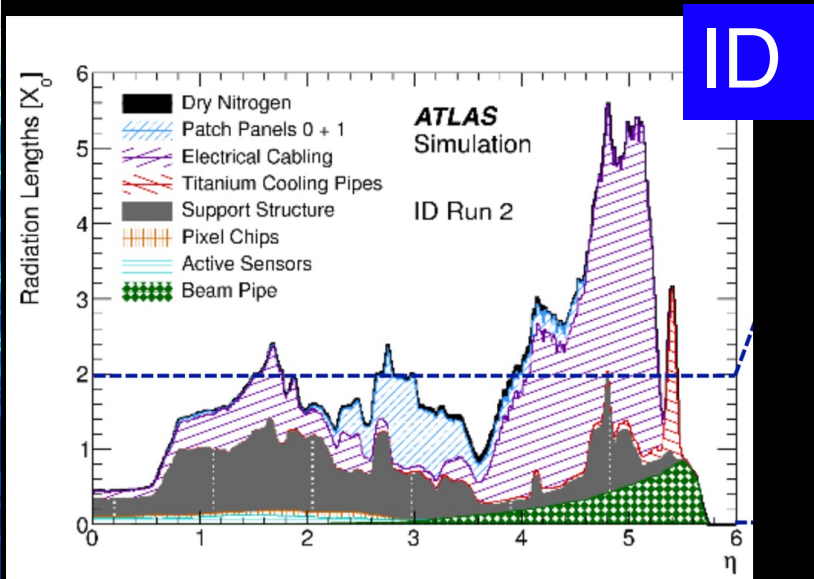
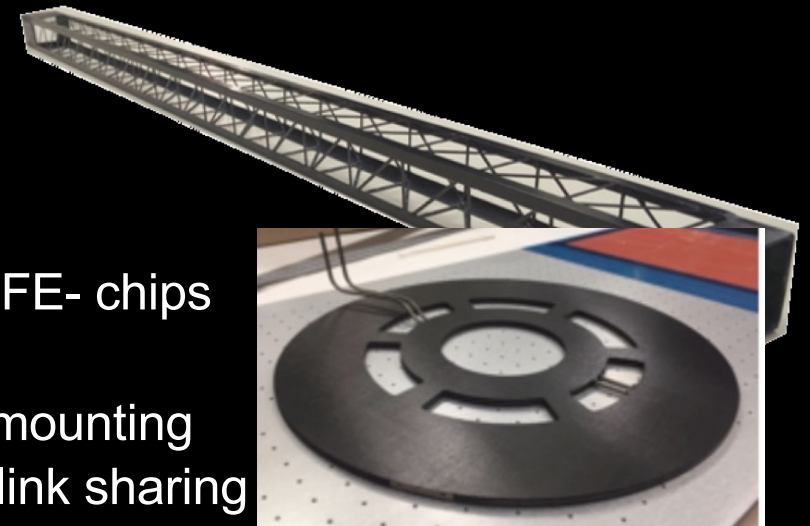
3D: Ultra Radiation hard sensors for L0

- 3D sensors are used in L0
- Requirements:
 - Radiation hard to $10^{16} n_{eq} cm^{-2}$
 - Operating voltage $< 250V$
 - Power $< 10 mWcm^{-2}$
 - $> 97%$ hit efficiency



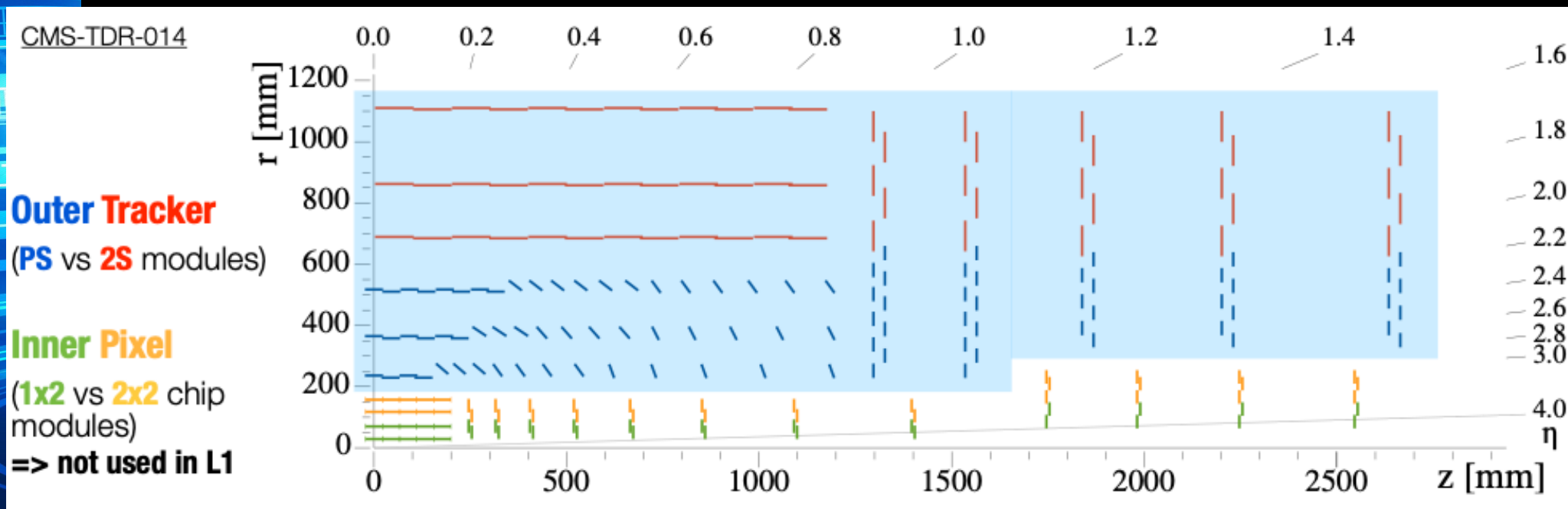
Material

- Reduce of material using
 - CO₂ cooling with thin titanium pipes
 - Minimise material in modules using thin Si and FE- chips
 - Advanced powering: serial powering for pixels
 - Carbon structures for mechanical stability and mounting
 - Optimise number of readout cables using data link sharing



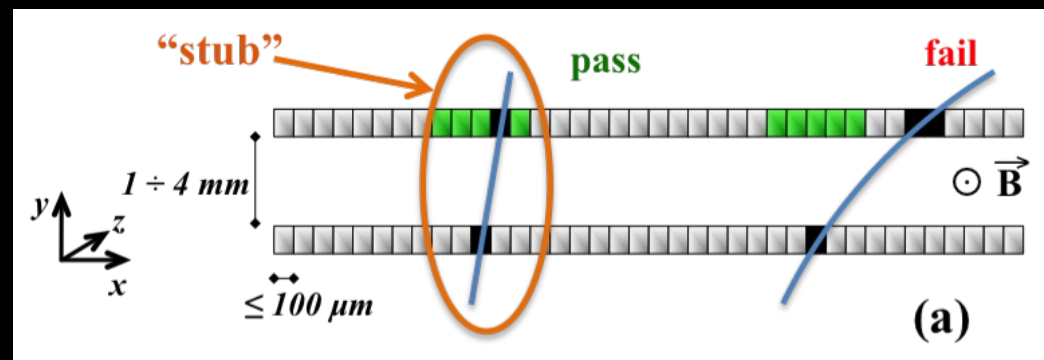
CMS HL-LHC Tracker

- New all silicon outer tracker + inner pixel detector
 - Increased granularity for HL-LHC occupancies
 - Tracking in hardware trigger



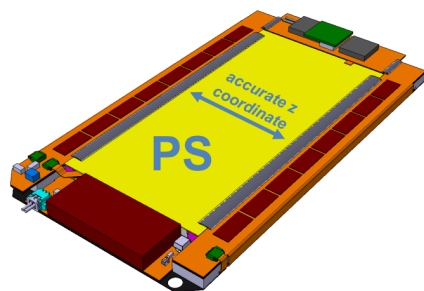
pT module concept

- Modules provide p_T discrimination in front-end electronics through hit correlations between two closely spaced sensors
- **Stubs:** Correlated pairs of clusters, consistent with ≥ 2 GeV track providing data reduction by factor of 20-30



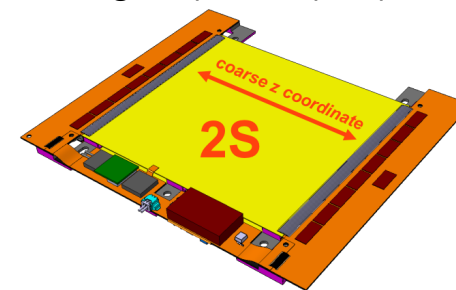
PS modules (pixel-strip)

- Top sensor: 2x2.5 cm strips, 100 μm pitch
- Bottom sensor: 1.5 mm x 100 μm pixels



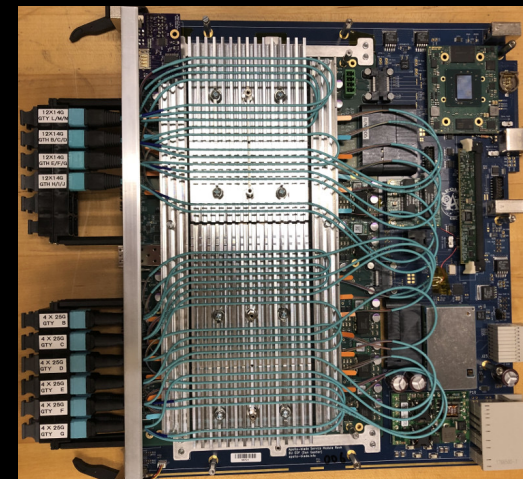
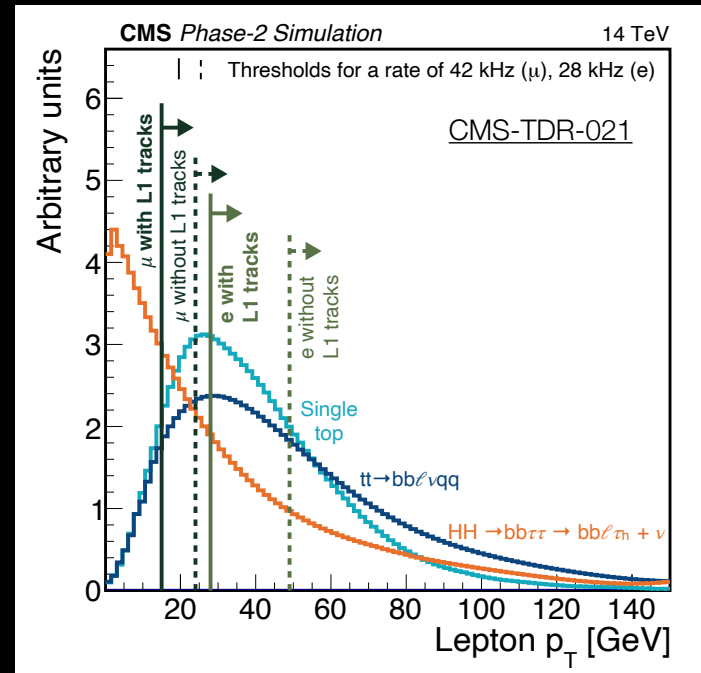
2S modules (strip-strip)

- Strip sensors 10x10 cm²
- 2x5 cm long strips, 90 μm pitch



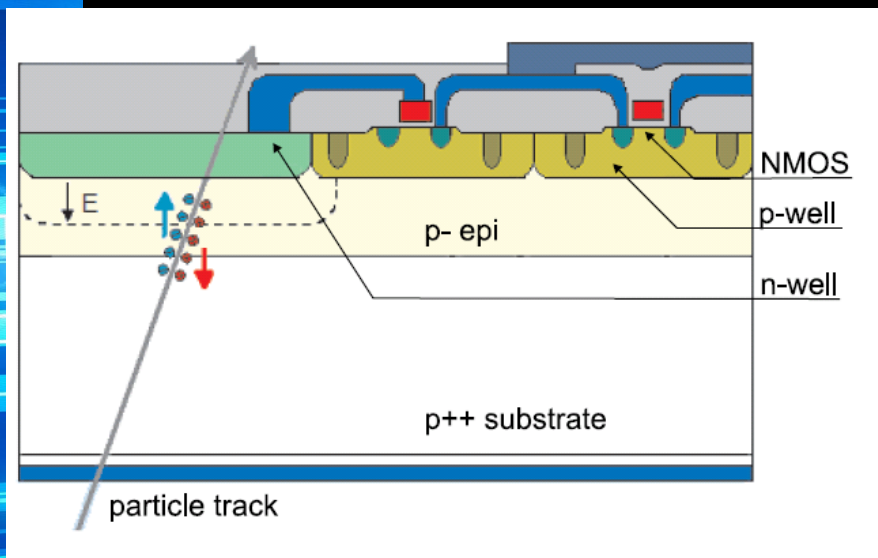
Track Triggering

- **Track information in hardware trigger**
 - Allow lower p_T threshold
 - Improve p_T measurement & identification of charged leptons
 - Identify primary interaction vertex
 - Associate e.g. jets to common vertex when defining multi-object triggers
- **Challenges**
 - Combinatorics from $\sim 15K$ input stubs / BX
 - Data volumes of up to ~ 30 Tbits/s
 - L1 trigger decision within $12.5 \mu s$, $\sim 4 \mu s$ available for track finding
- Utilize extensive parallel processing to tackle above challenges
- Track finding implemented as a fully FPGA-based system



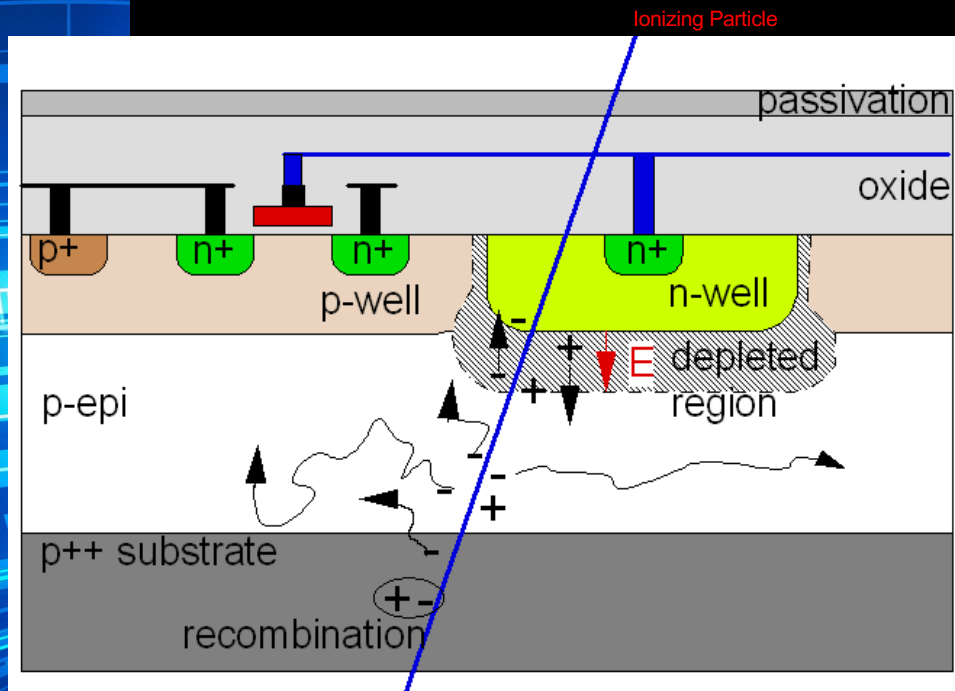
Apollo: track finding processing boards

Monolithic Silicon Pixel Detectors



- FE electronics is integrated in sensor and produced in commercial CMOS processes (many different variants).
- Allows very thin sensors to achieve ultimate low mass trackers ($0.3\% X_0$ in Heavy-Ion experiments or $<1\%$ for pp).
- High volume and large wafers (200 mm) reduces detector cost opens possibility for large area pixel detectors.
- Saves cost and complexity of bump bonding (one of the cost drivers in hybrid silicon detector systems).

Monolithic Active Pixels



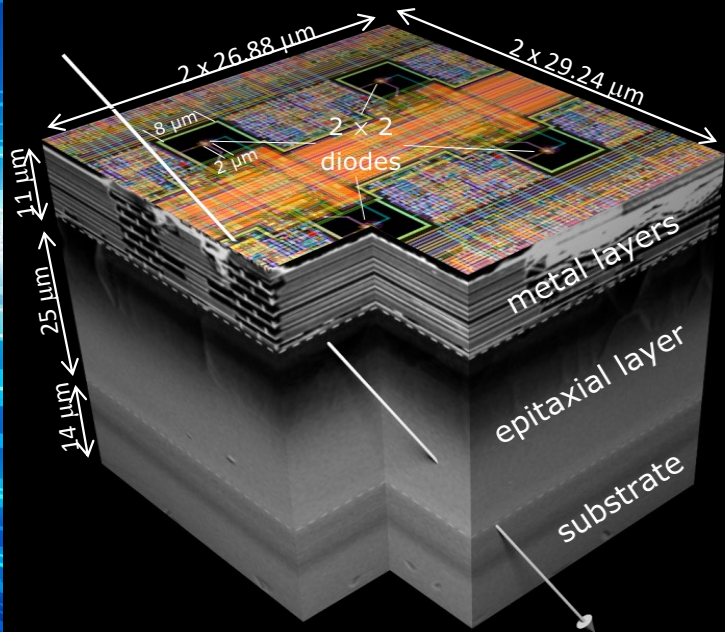
Applications:, STAR-detector (RHIC Brookhaven), Eudet beam-telescope

- Commercial CMOS technologies (e.g. AMS 0.35 μm)
- Lightly doped p-type epitaxial layer ($\sim 14\text{-}20 \mu\text{m}$)
 - MIPs produce $\sim 80 \text{ e-}/\text{h+}$ pairs per μm ($\sim 1000 \text{ e-}$)
- No reverse substrate bias:
 - Signal charge collection mainly by diffusion ($\sim 100 \text{ ns}$)
 - Sensitive to displacement damage
- N-well implantation used for collecting electrode
- Only n-MOS transistor in pixel (in p-well)
 - Very simple in-pixel circuit (few transistors)
 - Complex electronics at the periphery of the matrix
- Pixel size: $20 \times 20 \mu\text{m}^2$ or lower \Rightarrow few μm resolution

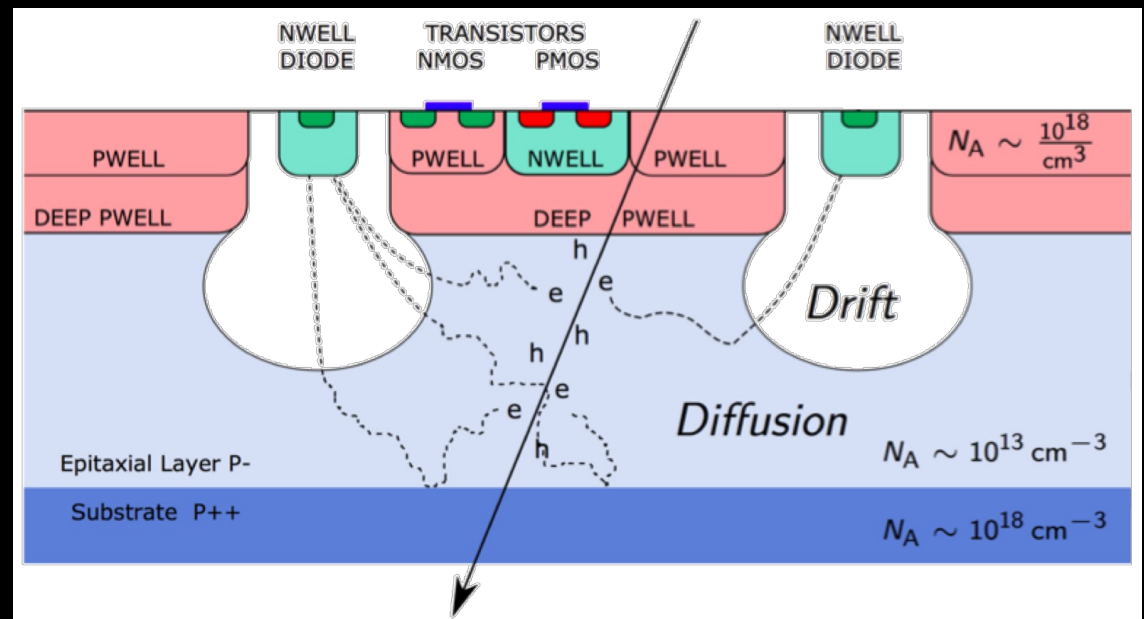
IPHC Strasbourg (PICSEL group)

ALICE ITS

- Based on the Alptide chip in TJ 180 nm



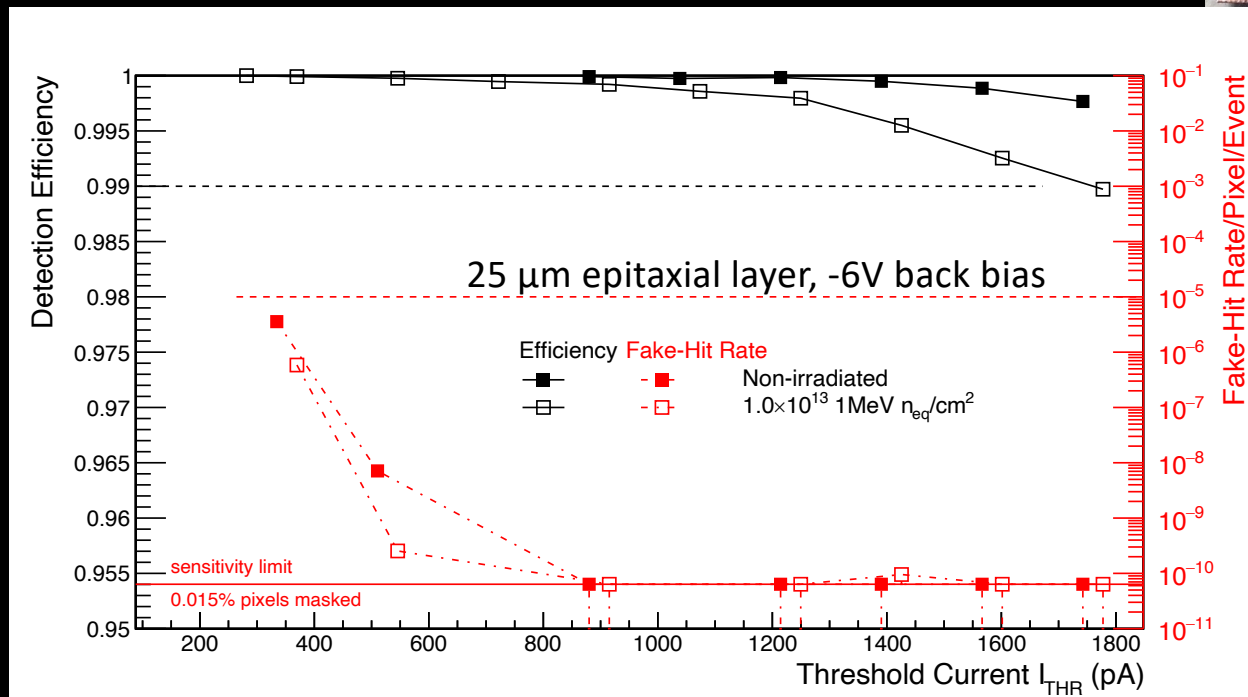
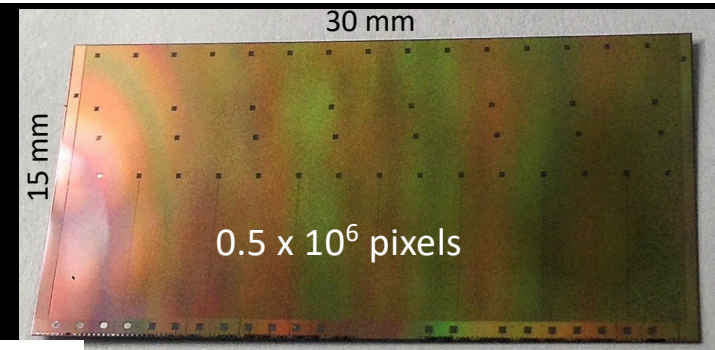
ALPIDE (ALICE)



- Tremendous progress in CMOS pixel designs
 - Pixel pitch: $29 \mu\text{m} \times 27 \mu\text{m}$
 - Power $< 40 \text{ mW}/\text{cm}^2$
 - Integration time $< 10 \mu\text{s}$

ALPIDE

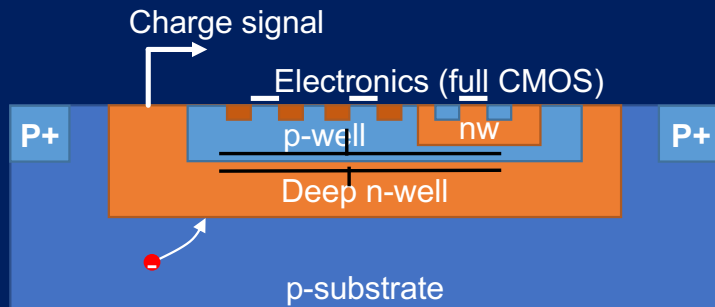
- Pixel size: $29 \times 27 \mu\text{m}^2$ with low power front-end
~40 nW/pixel
- Extensive tests before and after irradiation



- Efficiency $> 99.5\%$ and fake hit rate $\ll 10^5$ over wide threshold range
- Excellent performance also after irradiation to 10^{13} (1MeV $n_{\text{eq}}/\text{cm}^2$)

Design choices toward DMAPS

Electronics inside charge collection well

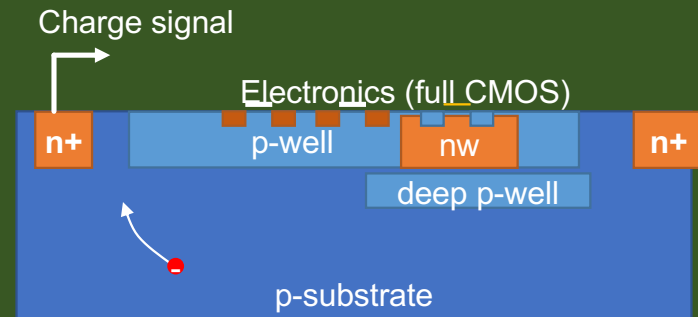


- Deep n and p wells
- Large collection node
- Shorter drift path
- Larger capacitance (DNW/PW junction!)
 - ⇒ X-talk, noise & speed (power) penalties

$$ENC_{thermal}^2 \propto \frac{4 kT}{3 g_m} \frac{C_d^2}{\tau}$$

$$\tau_{CSA} \propto \frac{1}{g_m} \frac{C_d}{C_f}$$

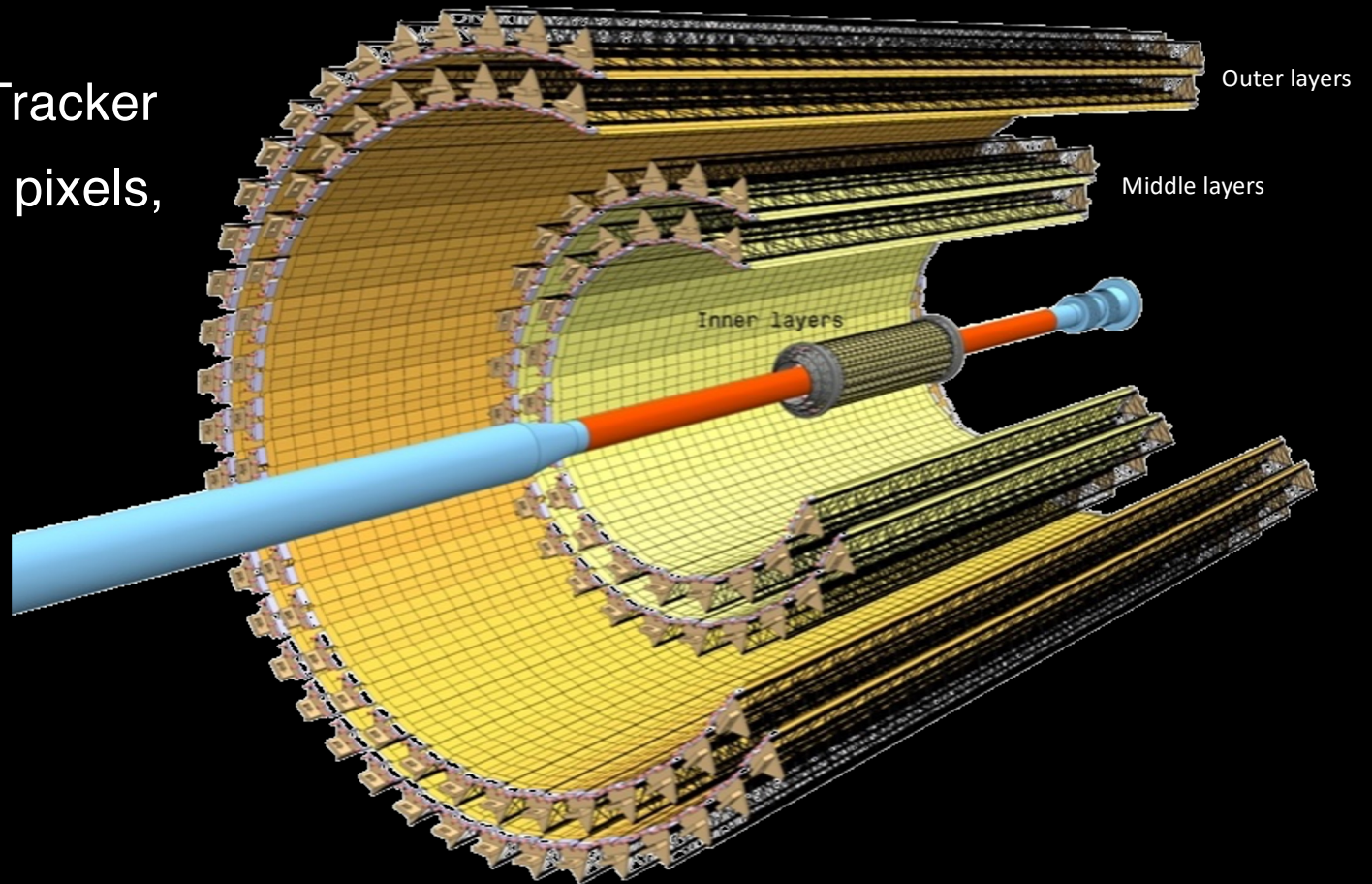
Electronics outside collection well



- Full CMOS with additional deep-p implant
- Small collection node
- Smaller capacitance ⇒ less power
- Long drift path

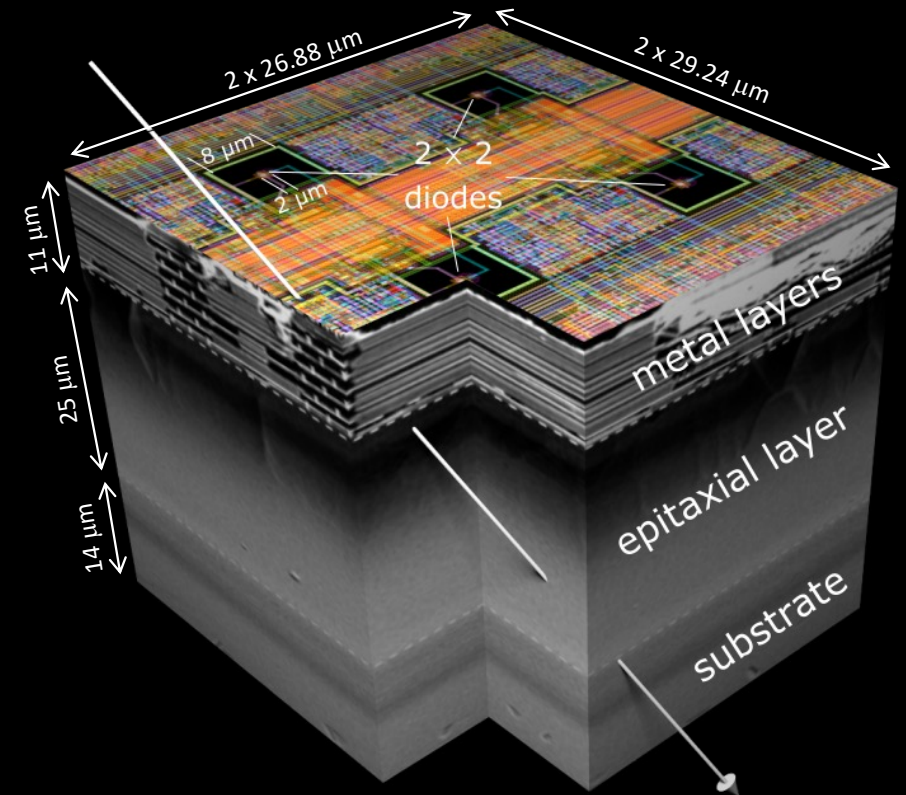
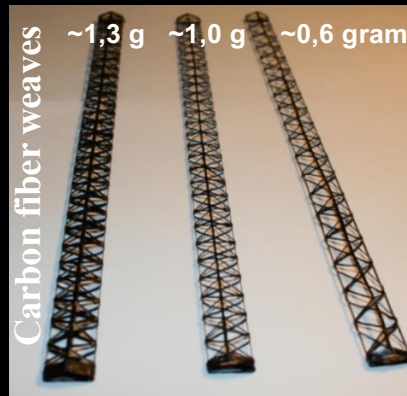
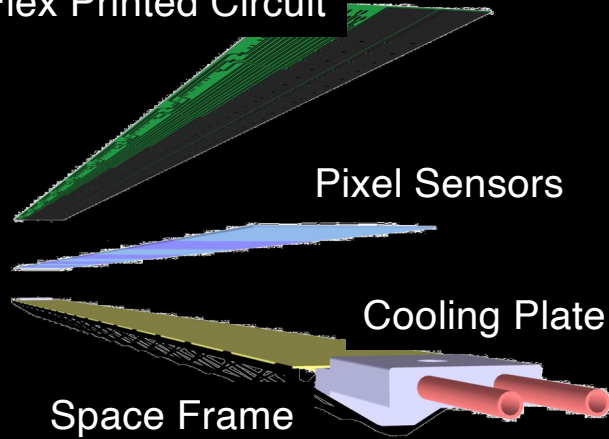
Material reduction

- ALICE MAPS-CMOS Tracker
 - 7-layers, 12.5 Giga pixels, 10m²
 - R coverage: 23 – 400 mm
- Material/layer:
 - 0.3% X₀ (IB)
 - 1.0% X₀ (OB)



CMOS Pixel Chips & Material

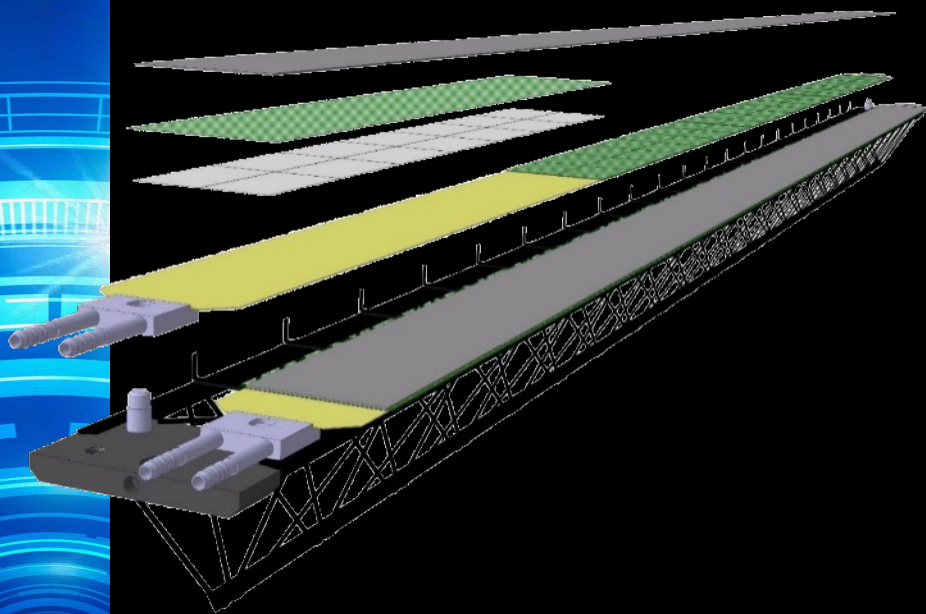
Flex Printed Circuit



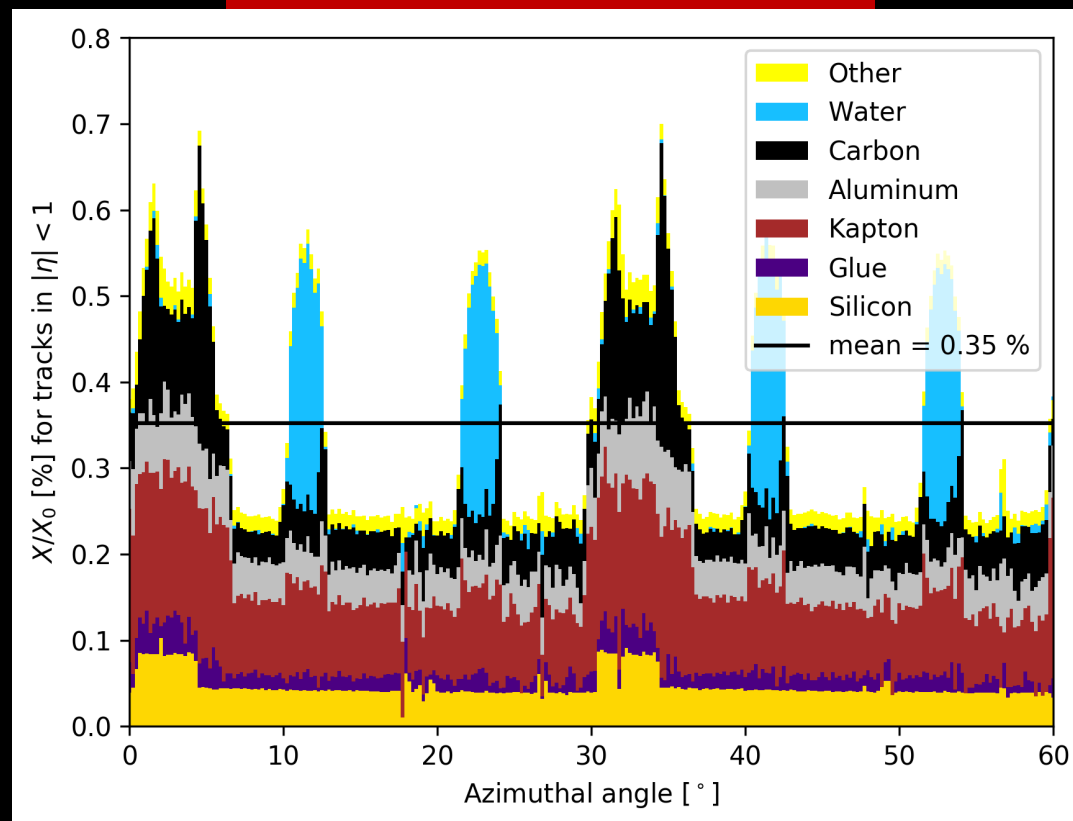
ALPIDE (ALICE)

Depleted CMOS Sensors

Minimize the material budget



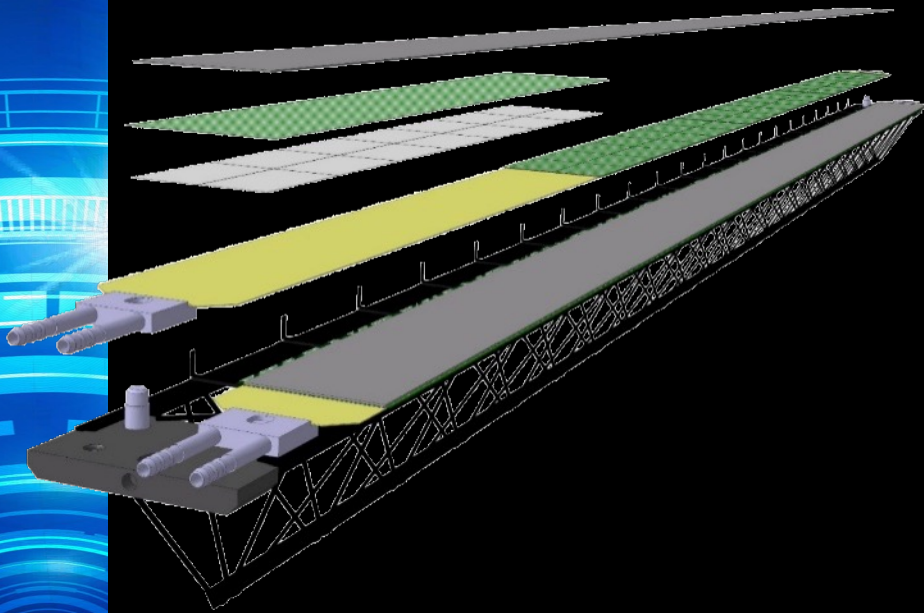
Overall Material Budget



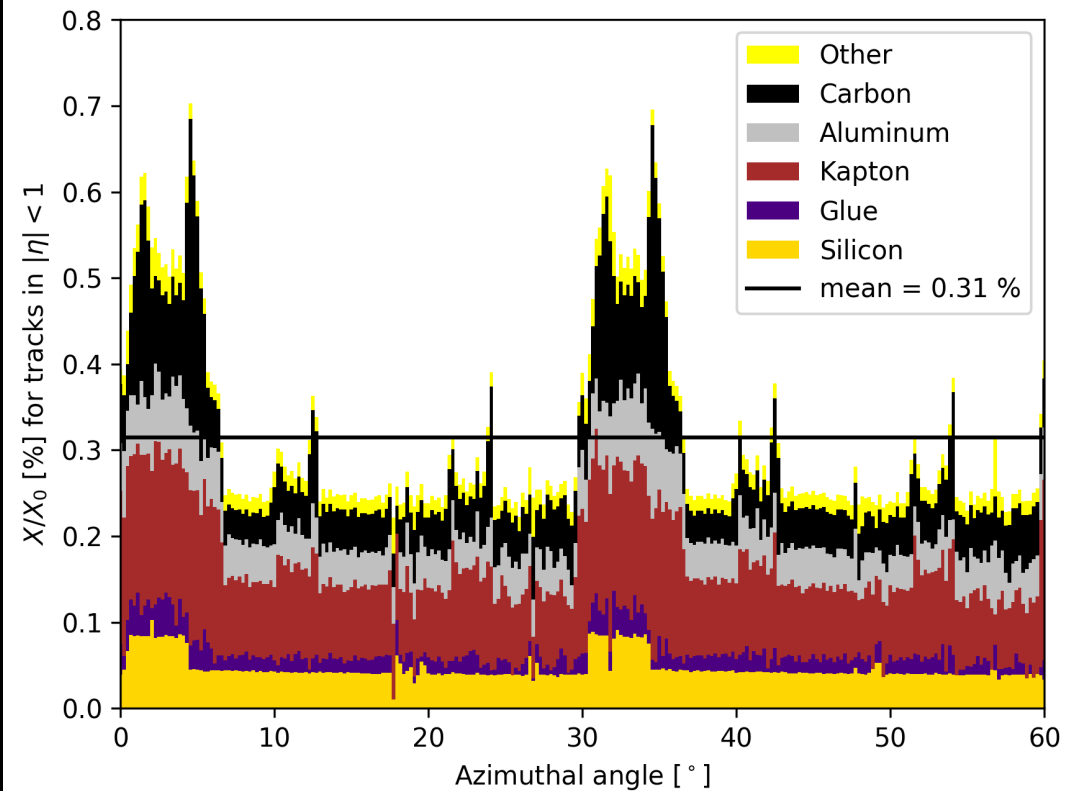
Luciano Musa, Bergen, August 2019: <https://indico.cern.ch/event/836343/>

Depleted CMOS Sensors

Minimize the material budget

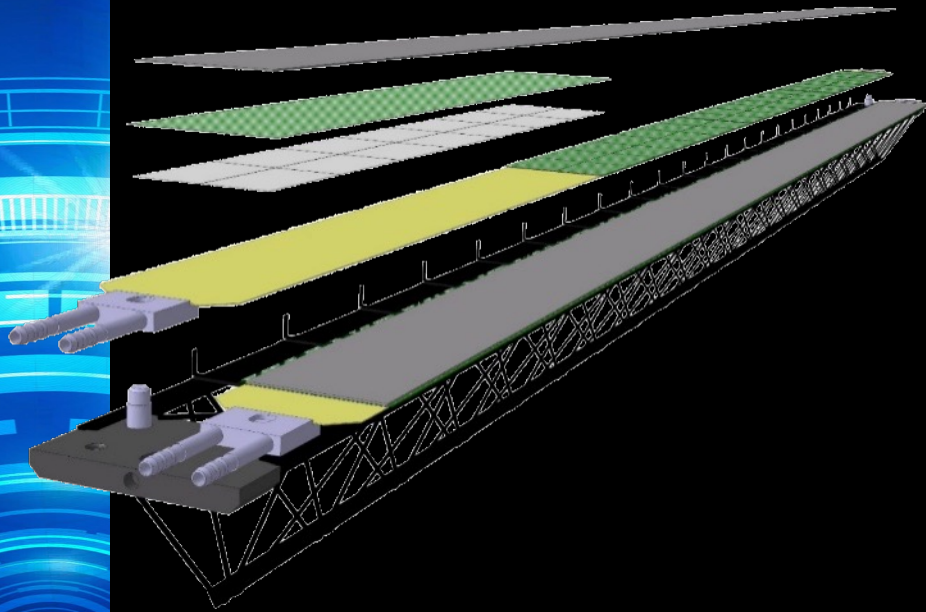


Reduce Power ($< 20 \text{ mW/cm}^2$) and
Remove Cooling

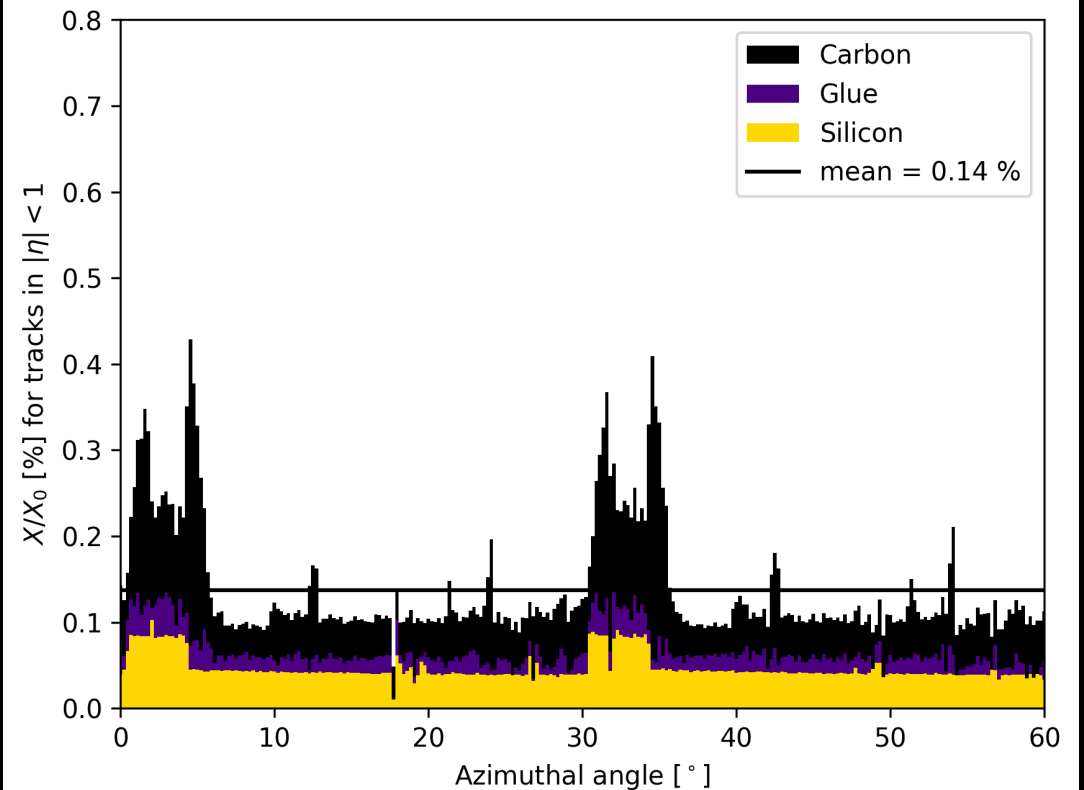


Depleted CMOS Sensors

Minimize the material budget

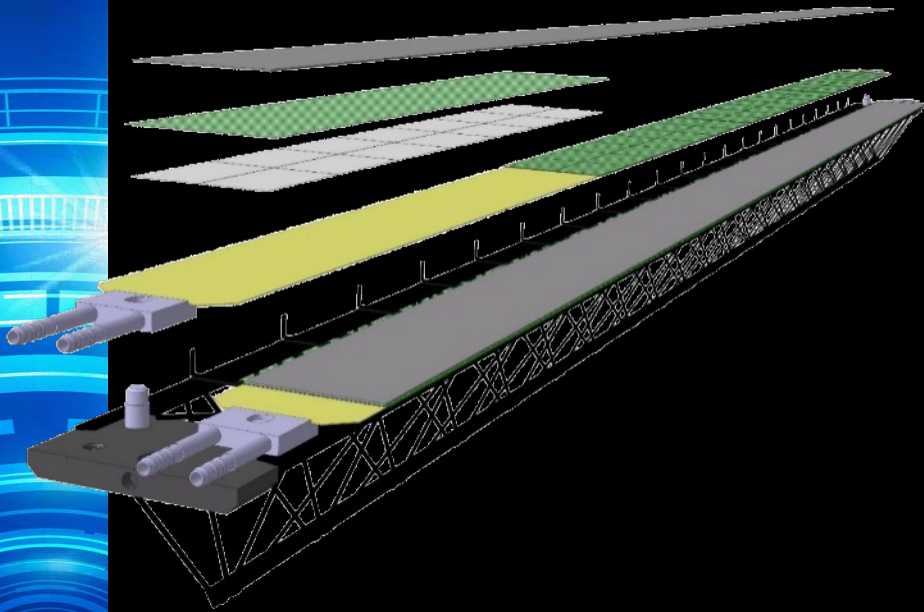


Remove PCB and integrate components on chip

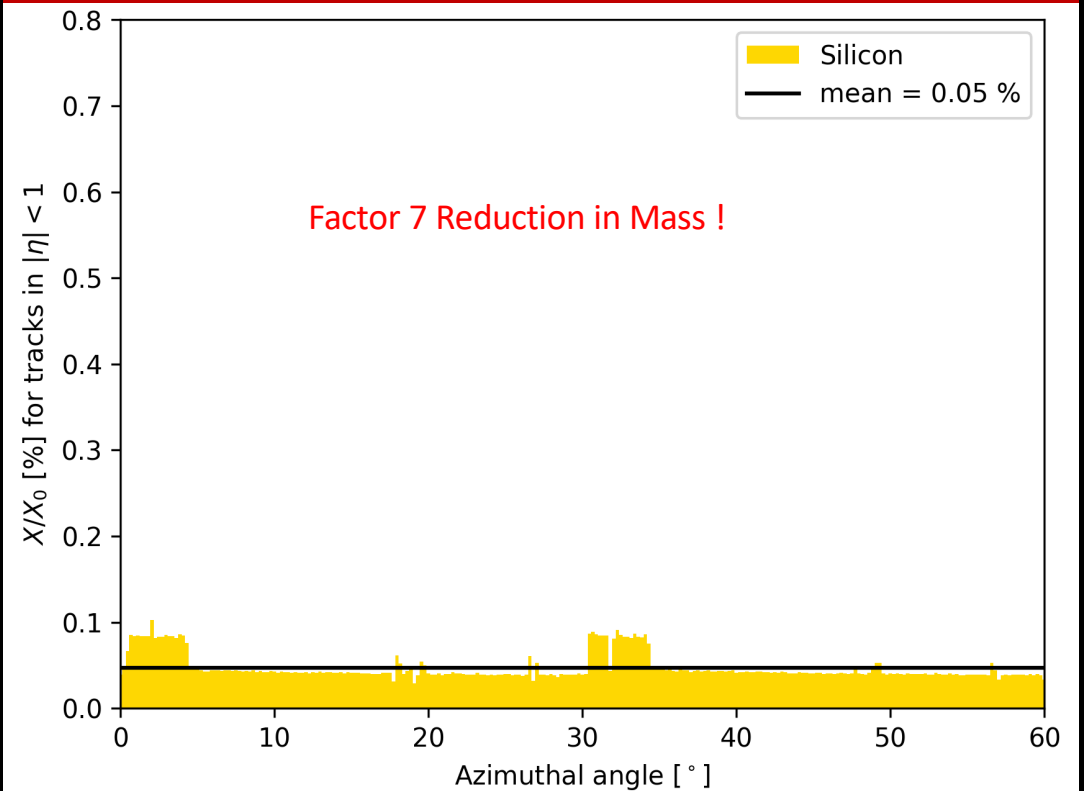


Depleted CMOS Sensors

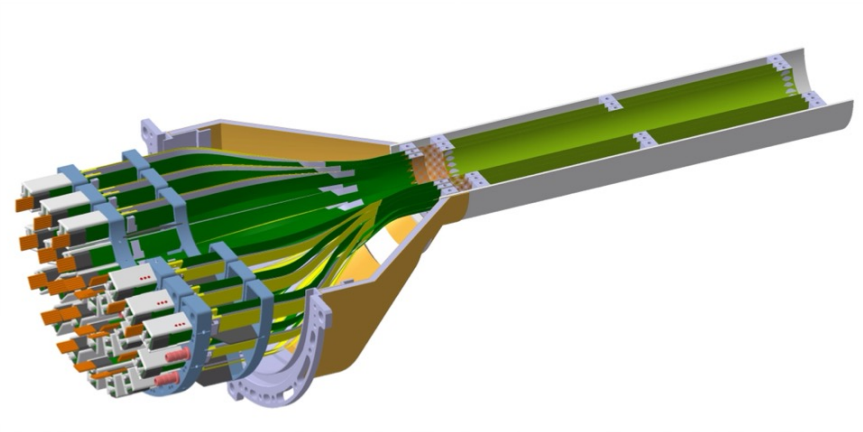
Minimize the material budget



Remove mechanical support and use stiffness provided by rolling Si wafers



IT3 Concept



Technology advances:

- 300 mm wafer-scale chips fabricated with stitching
- thinned down to 20-40 μm bent to the target radii
- held in place by carbon foam ribs

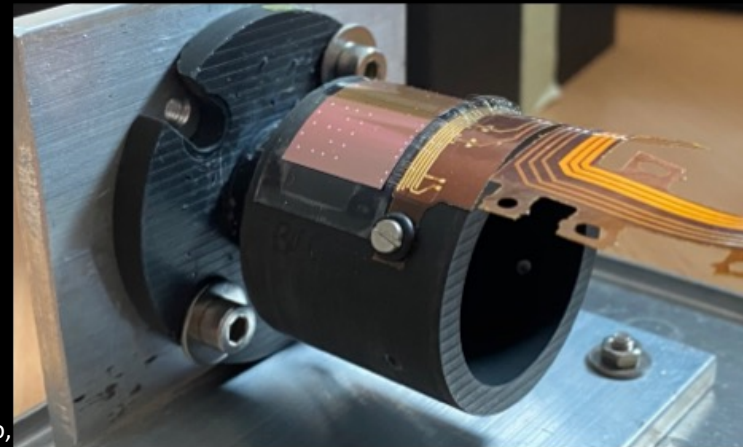
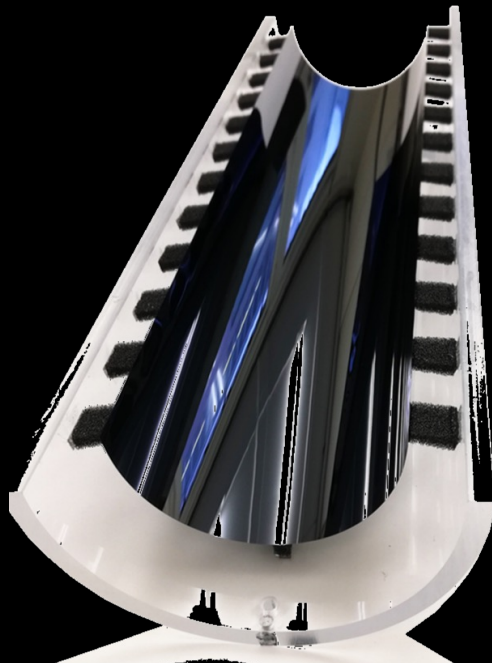
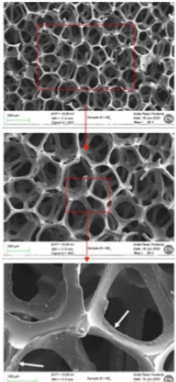
Key benefits:

- extremely low material budget: 0.02-0.04% X_0
(beampipe: 500 μm Be: 0.14% X_0)
- homogeneous material distribution leading to smaller systematic error

ERG DUOCEL_AR

0.06 kg/dm³

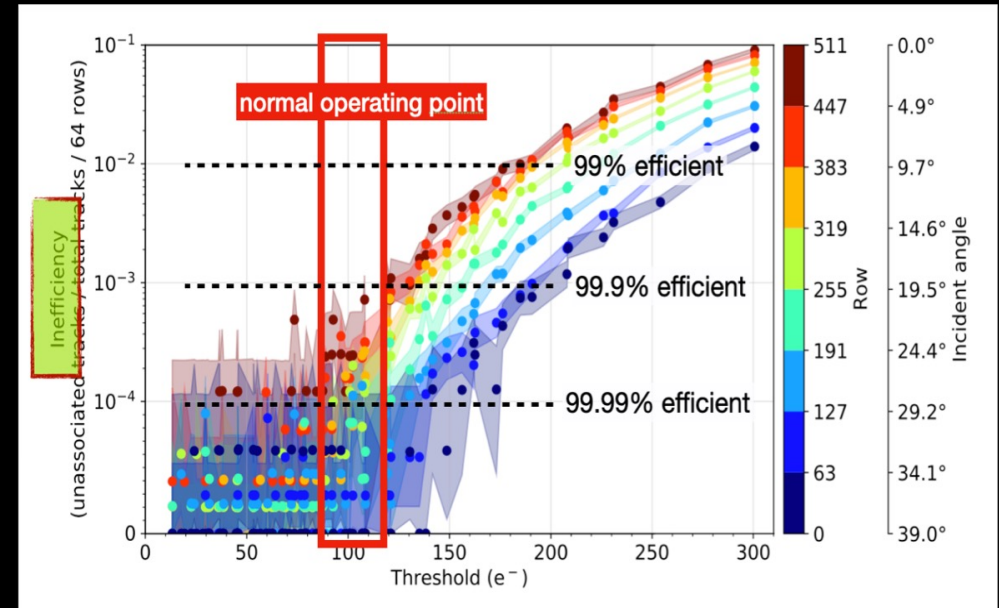
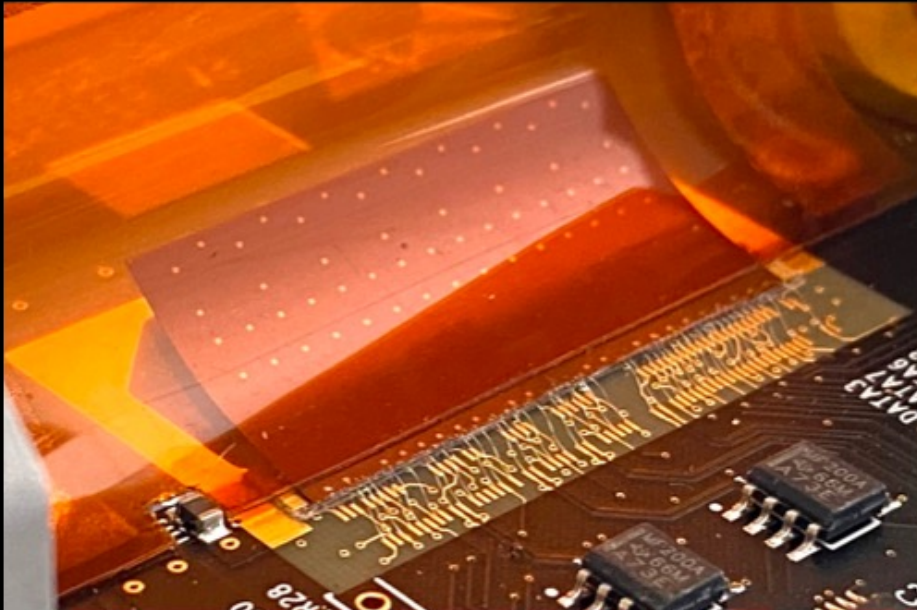
0.033 W/m-K



D. Bortoletto,

Test beams

June 2020 test beam data shows that bent MAPS work perfectly

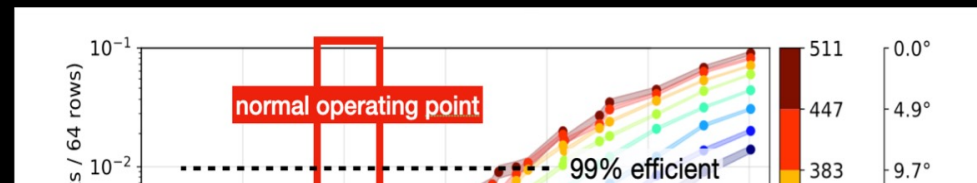


Collaboration investigating TowerJazz 65 nm

Magnus Mager (CERN) | ALICE ITS3
| TIPP 2021 | 26.05.2021 |

Test beams

June 2020 test beam data shows that bent MAPS work perfectly



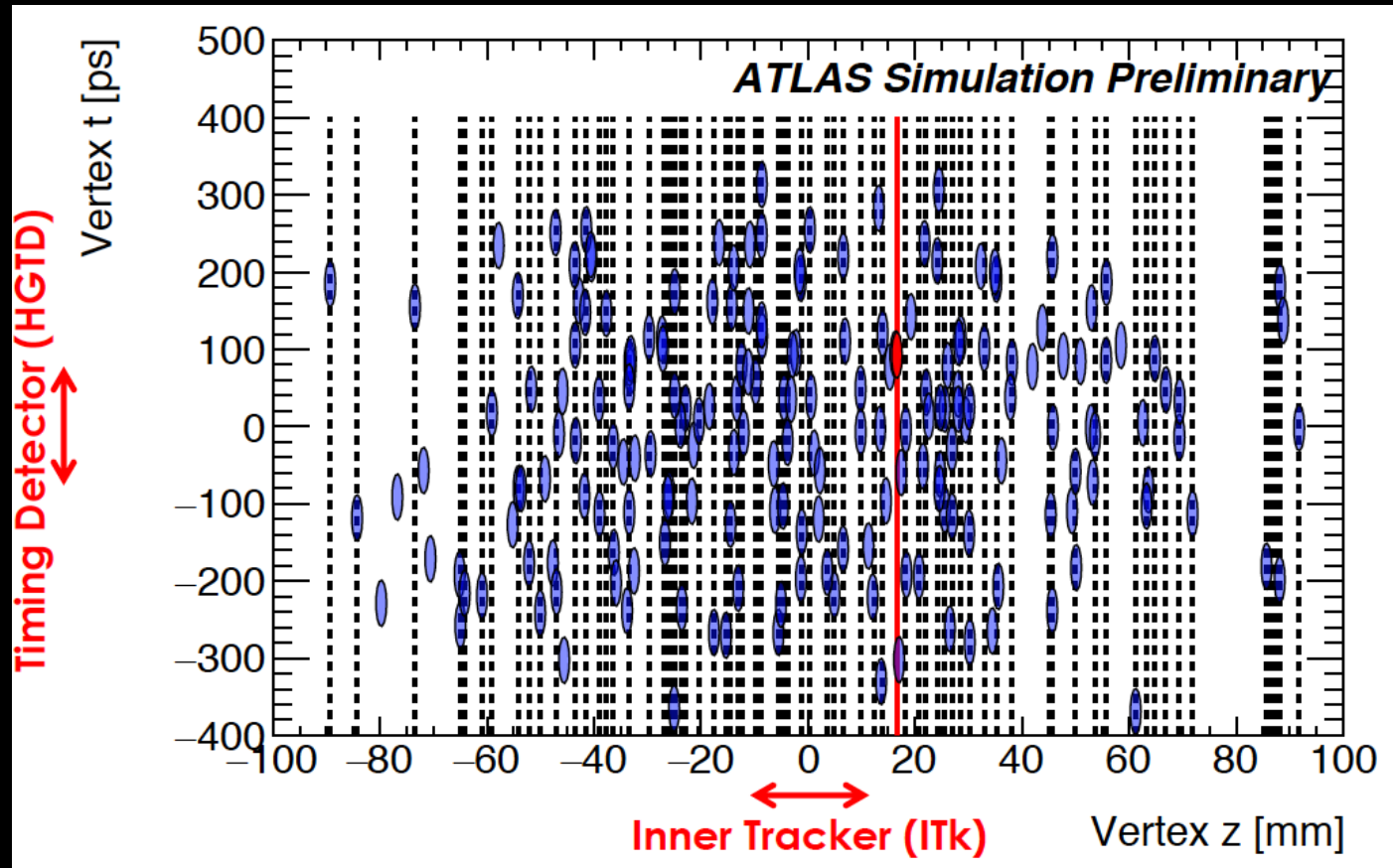
Development extremely important for future e^+e^- colliders and experiments requiring very low material



Collaboration investigating TowerJazz 65 nm

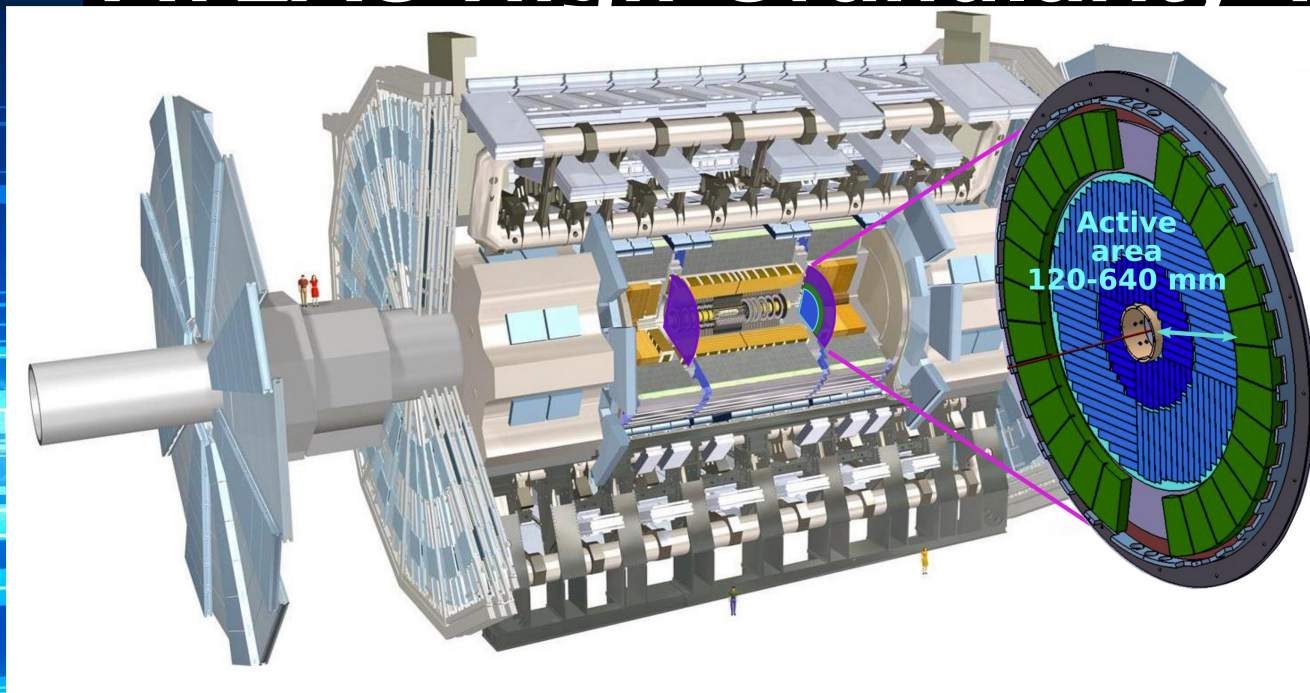
Magnus Mager (CERN) | ALICE ITS3
| TIPP 2021 | 26.05.2021 |

Timing



Exploit the time spread of collisions to reduce pileup contamination

ATLAS High Granularity Timing Detector

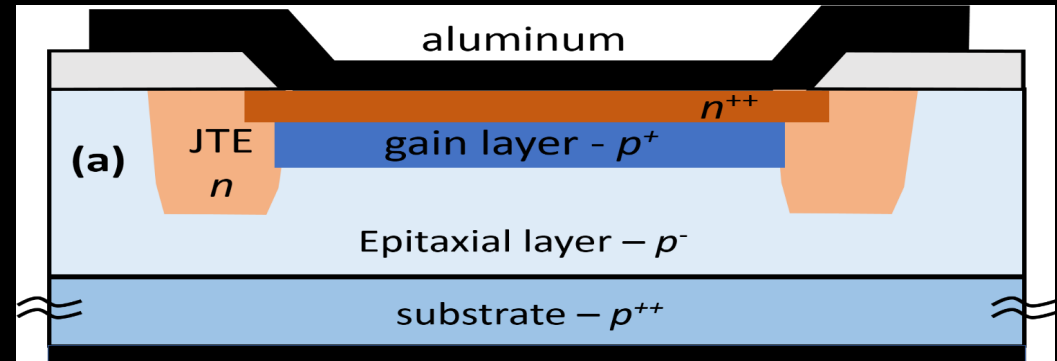
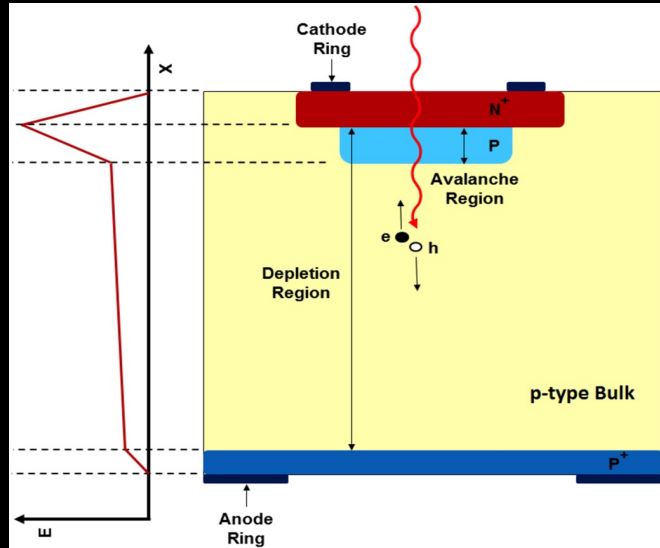


- Low Gain Avalanche Detectors (LGADs) pixel size: $1.3 \times 1.3 \text{ mm}^2$
- Excellent time resolution (30-50 ps/track)
- Radiation-hard (up to $2.5 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$ and 1.5 MGy)
- Occupancy < 10%

- 2 double planar layers per endcap providing an average number of hits per track of 2-3
- Pseudorapidity coverage: $2.4 < |\eta| < 4.0$
- Radial extension: $12 \text{ cm} < R < 64 \text{ cm}$
- z position: 3.5 m; Thickness in z: 7.5 cm
- Operated at $-30 \text{ }^\circ\text{C}$

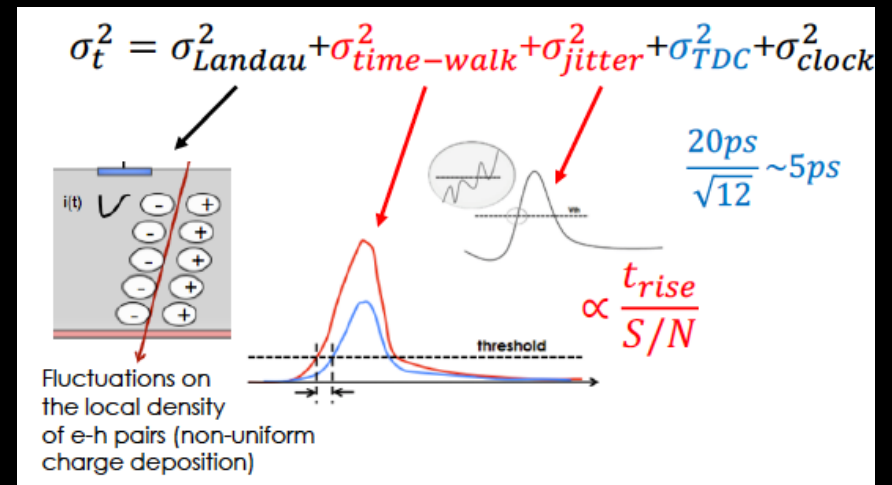
Timing detectors will also be implemented in CMS

Low Gain Avalanche Diodes

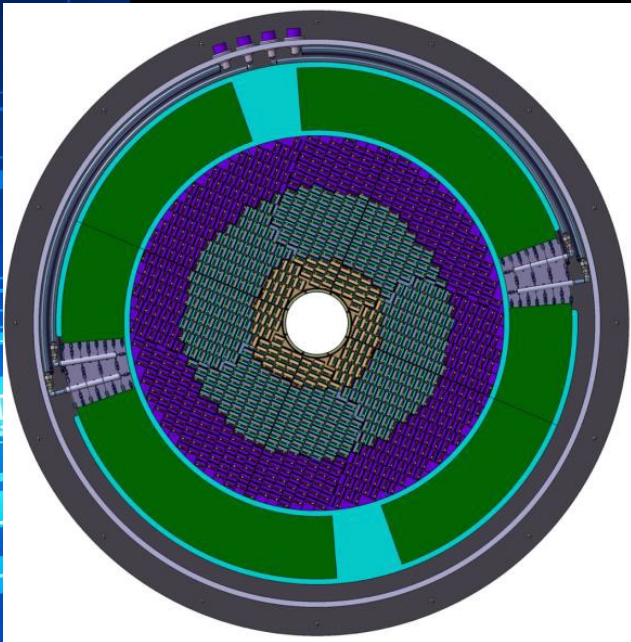


- The Junction Terminating Extension (JTE) allows high depletion but limits position resolution

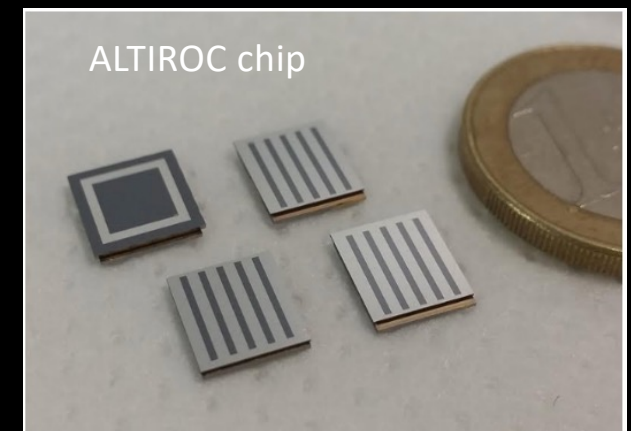
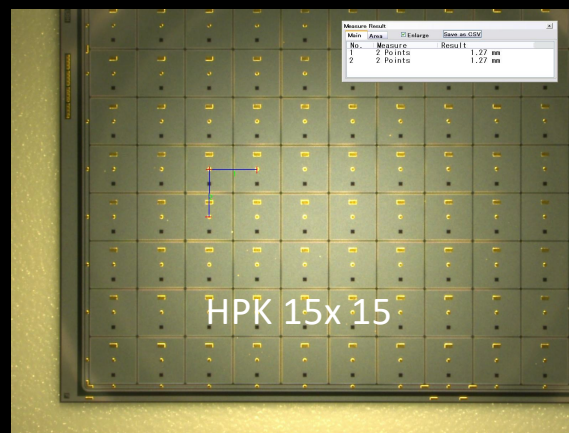
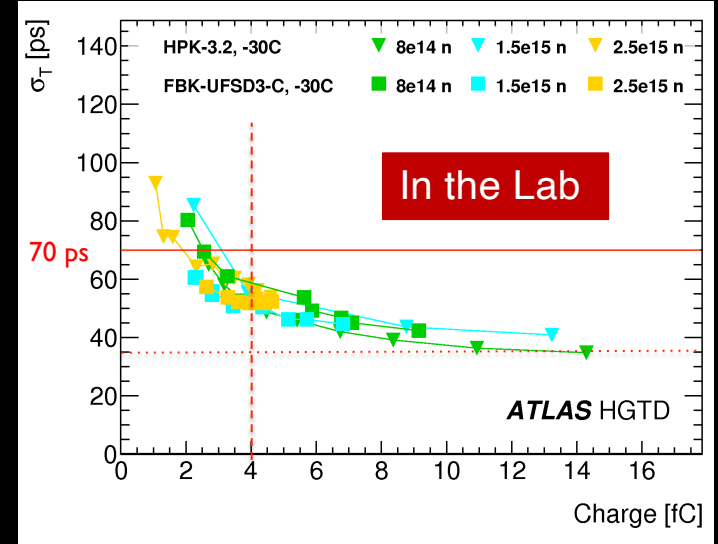
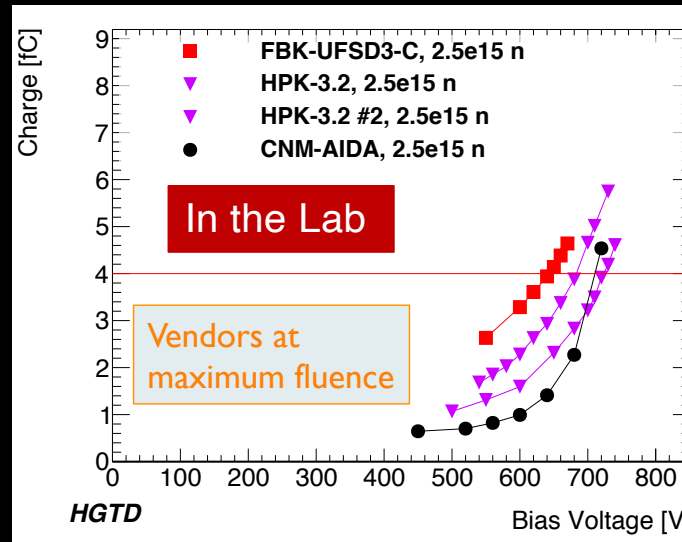
- Timing resolution: 35 - 70 ps/hit
- Gain > 20 decreases to > 8 at the end of lifetime ($V_{bias} < 800$ V)
- Collected charge > 4 fC /MIP/hit after 2.5×10^{15} n_{eq}/cm^2
- Prototypes from CNM (Spain), HPK (Japan), BNL (USA), FBK (Italy), IME & NDL (China), T-e2v & Micron (UK)



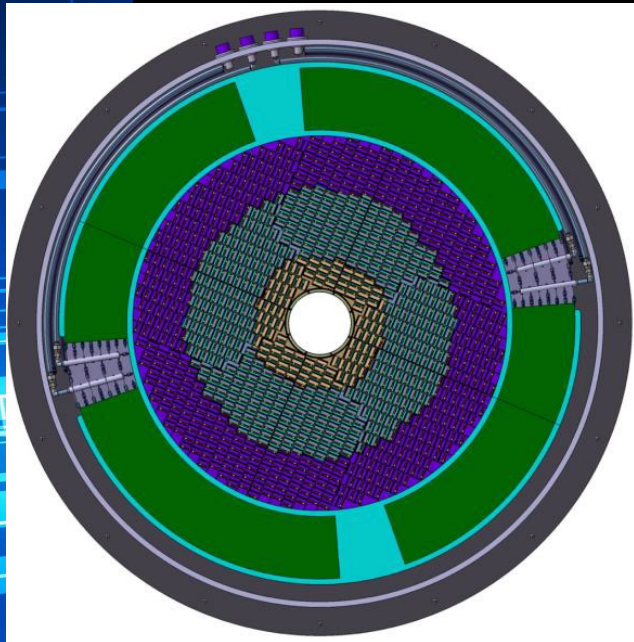
Ultra Fast Silicon Detectors



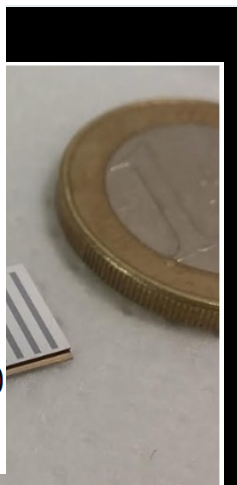
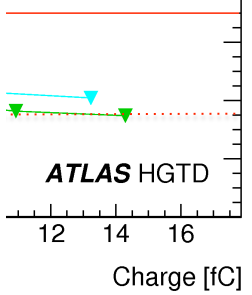
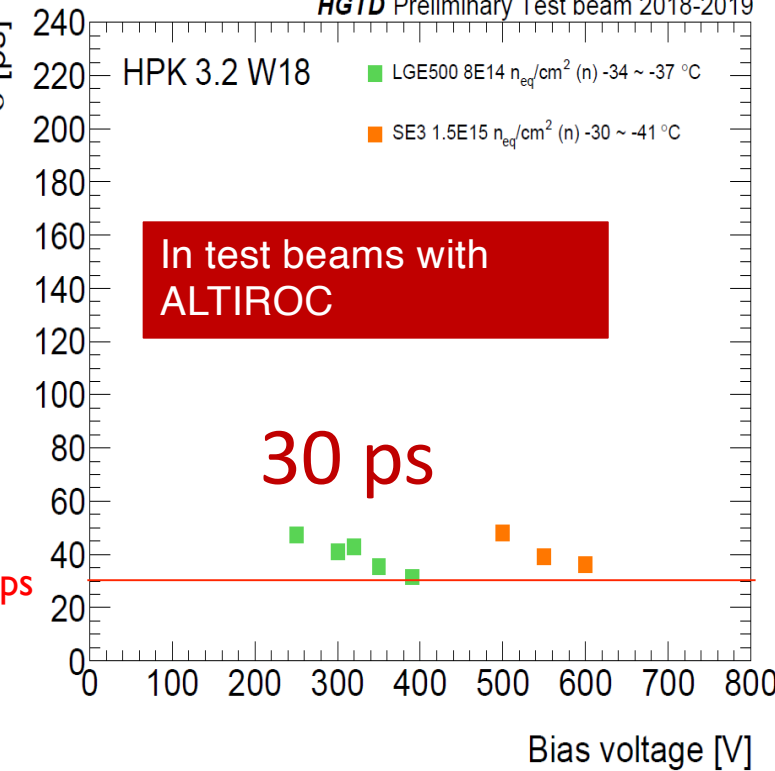
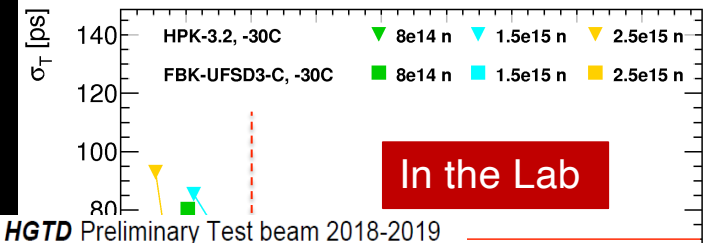
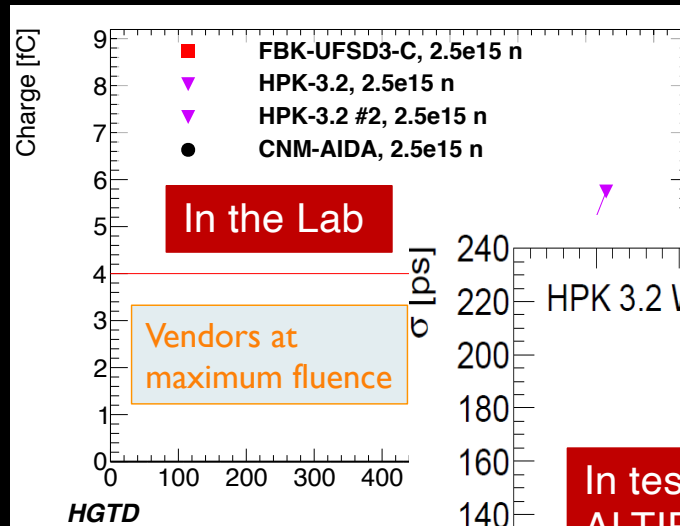
- Inner (12-23 cm) every 1000 fb⁻¹
- Middle (23-47 cm) every 2000 fb⁻¹
- Outer (47-64 cm) never replaced



Ultra Fast Silicon Detectors

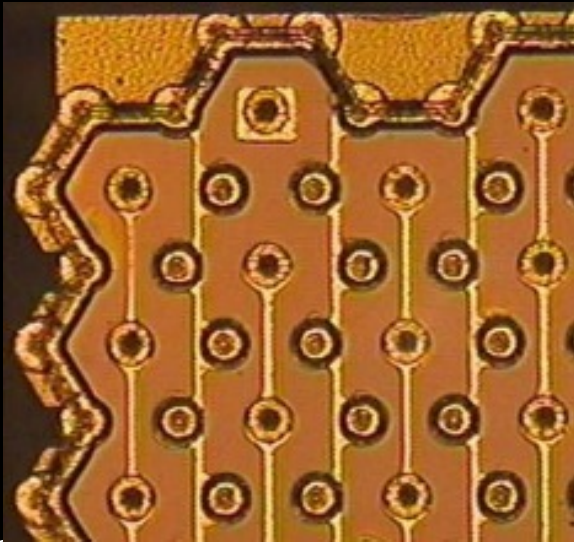


- Inner (12-23 cm) every 1000 fb⁻¹
- Middle (23-47 cm) every 2000 fb⁻¹
- Outer (47-64 cm) never replaced

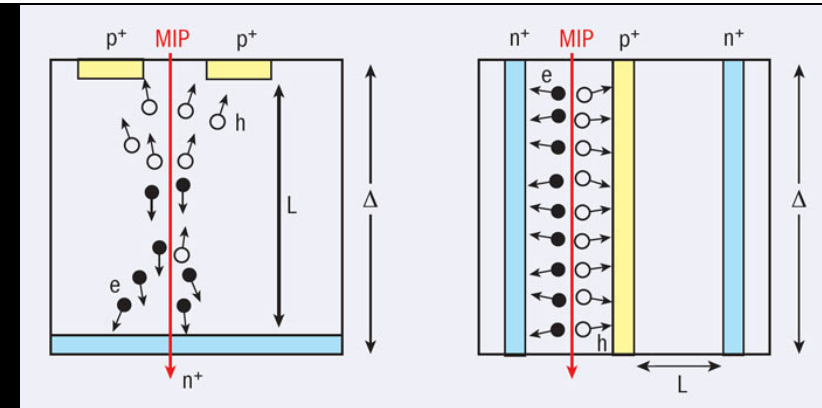


Timing with 3D sensors

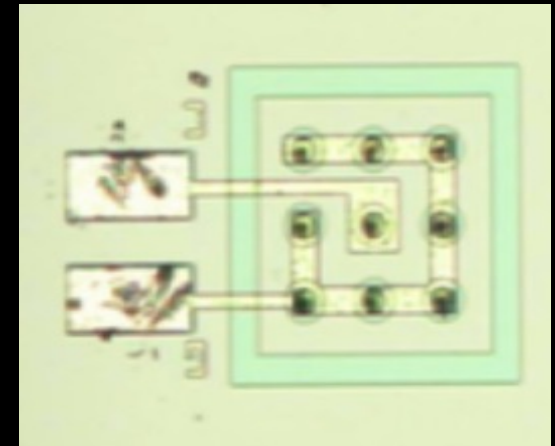
- Parker et al. IEEE TNS 58(2) (2011) 404
- Hexagonal geometry $L=50\ \mu\text{m}$, 20 V bias
- Tested under 90Sr β source at RT
- $\sigma_t = 31\text{-}177\ \text{ps}$ (according to signal amplitude)
- Limited by RO electronics noise



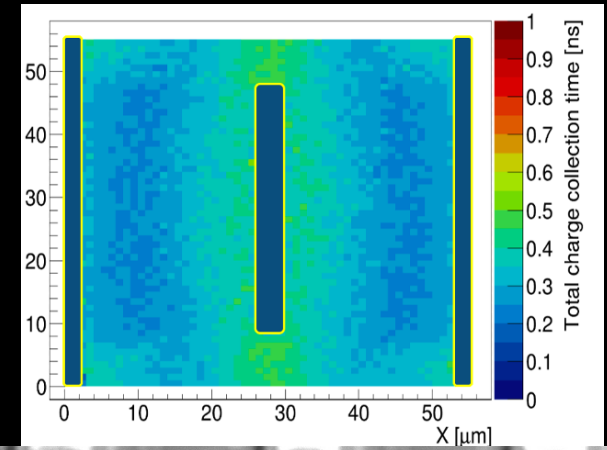
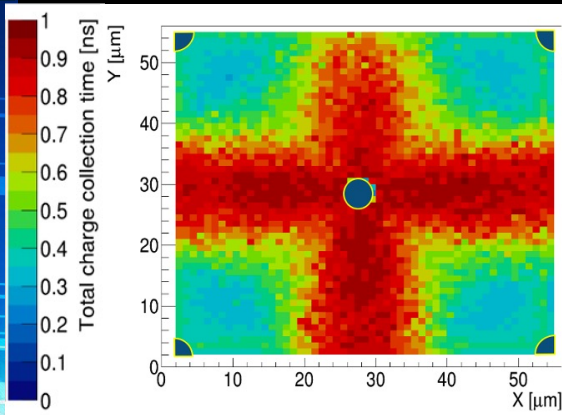
5/25/22



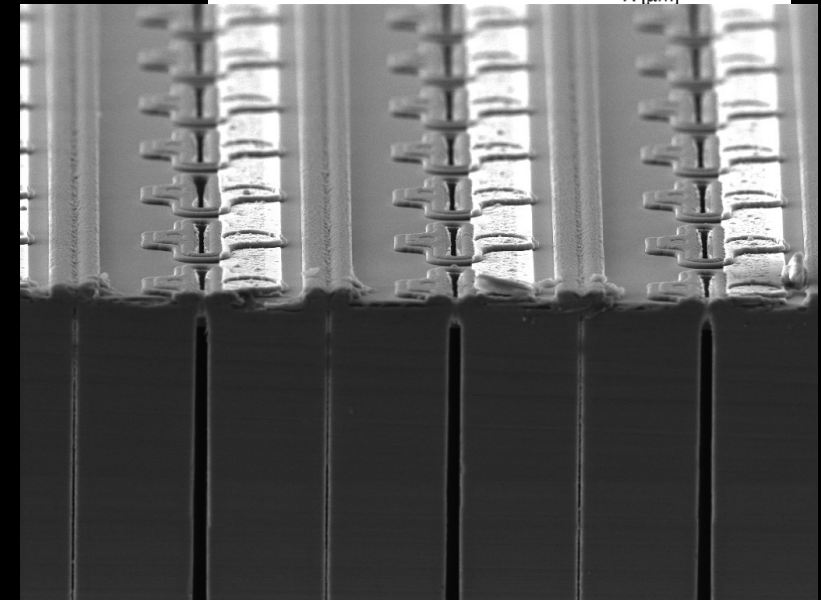
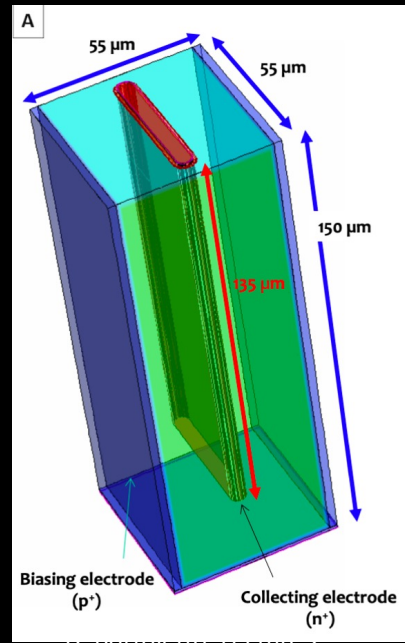
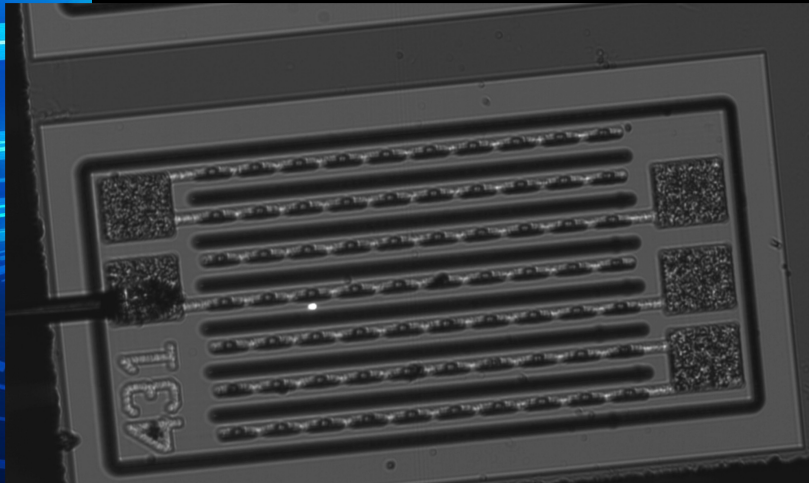
- G. Kramberger et al., NIMA 934 (2019) 26-32
- Squared geometry $L=50\ \mu\text{m}$. Depth = $300\ \mu\text{m}$. 50 V bias
- Tested under 90Sr β source. Room temperature.
- $\sigma_t = 75\ \text{ps}$



Timing with 3D sensors



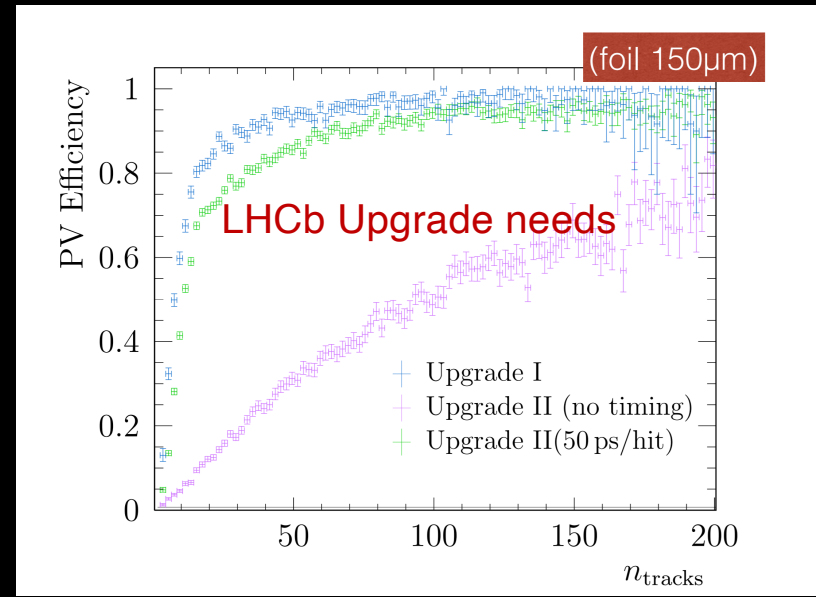
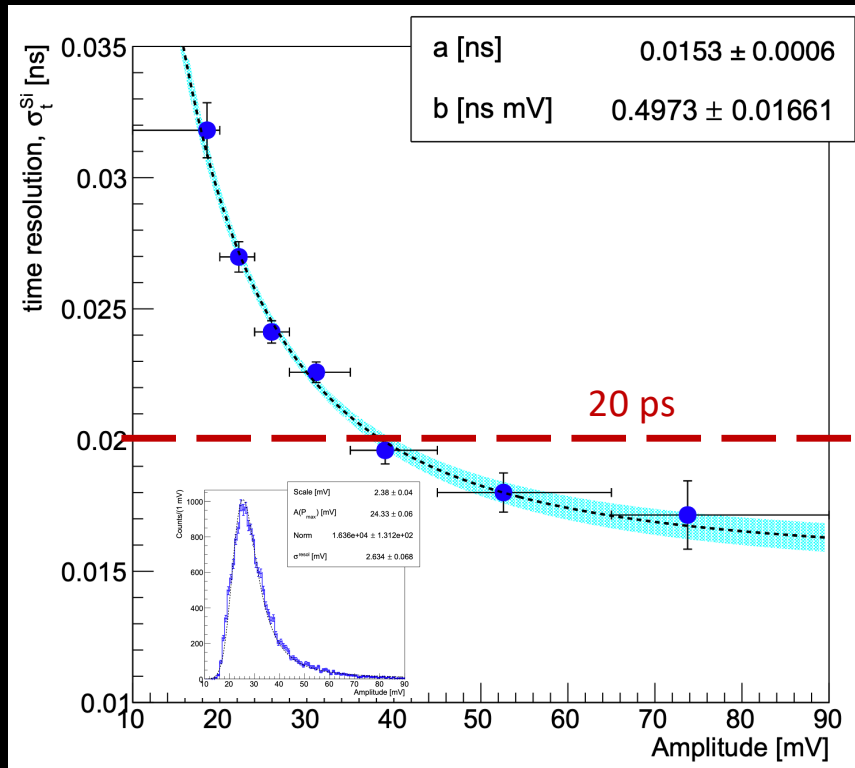
Column geometry (e.g. ATLAS IBL)



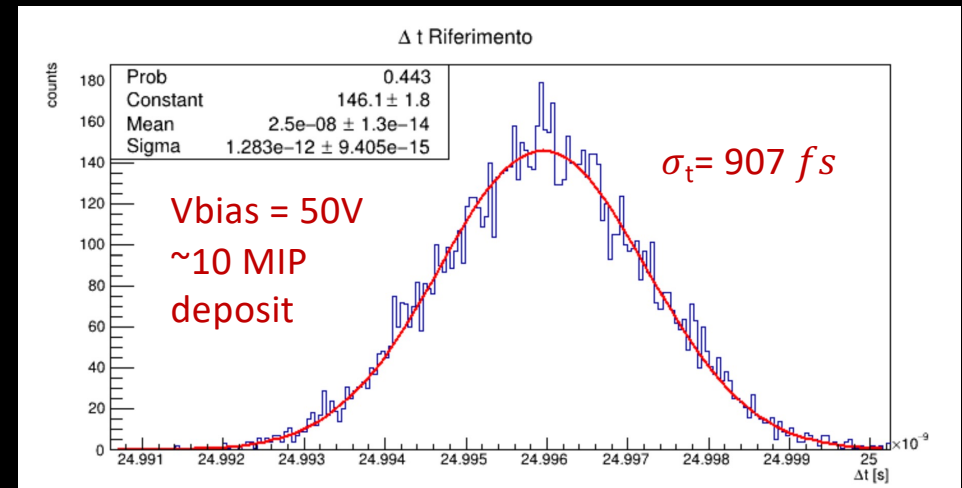
SEM HV: 10.0 kV	WD: 11.59 mm	VEGA3 TESCAN
View field: 176 μm	Det: SE	50 μm
SEM MAG: 1.57 kx	Date(m/d/y): 10/29/19	FBK Micro-nano Facility

TimeSpot

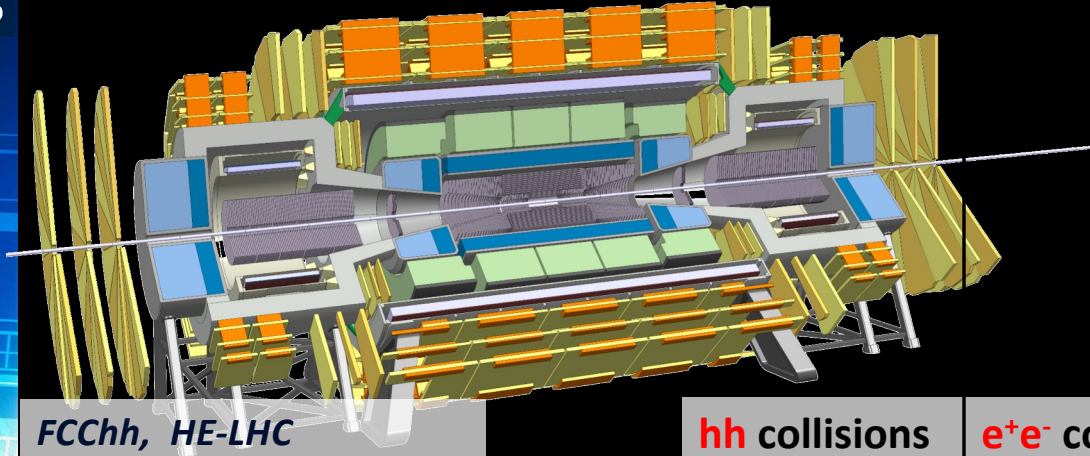
- Beam test results (270 MeV/c π^+ at PSI)
- Fast Front End Electronics (SiGe BJT)



In the lab with infrared laser



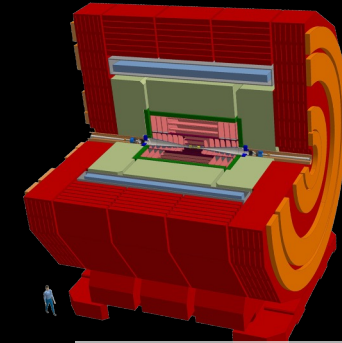
FUTURE COLLIDER DETECTORS



FCChh, HE-LHC

hh collisions

e⁺e⁻ collisions



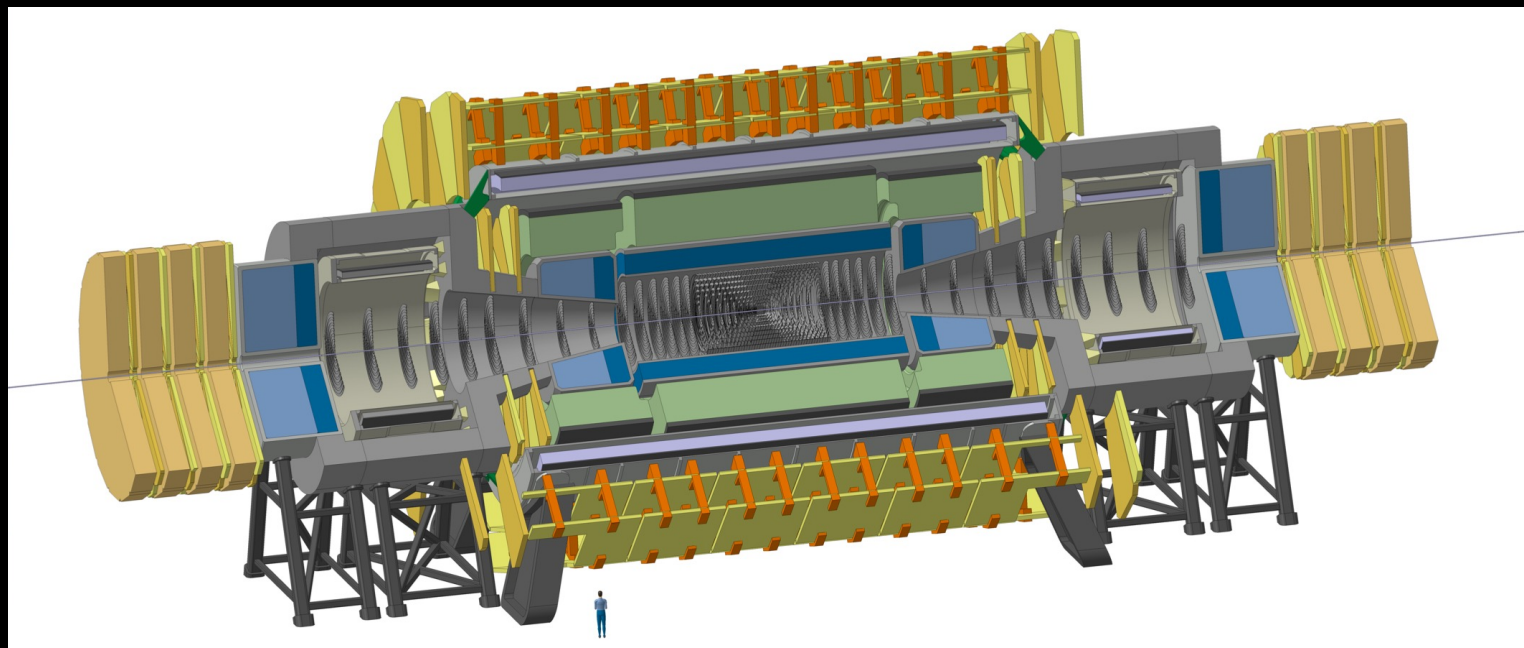
CLIC, FCCee, ILC, CEPC,...

- Large dimensions (50m)
- High radiation Level (up to 90MGy, $\approx 10^{18}$ /cm²)
- 4T 10m solenoid
- Forward solenoids 4T
- Silicon tracker Radius 1.6m, Length 32m
radiation damage is a concern
- Barrel ECAL LAr/ Barrel HCAL Fe/Sci
- Endcap HCAL/ECAL LAr
- Forward HCAL/ECAL LAr 2-4x better granularity than e.g. ATLAS Silicon ECAL and ideas for digital ECAL with MAPS
- Muon system

- Standard dimensions
- Low radiation Level
- 4T, 2T
- Silicon tracker unprecedented spatial resolution (1-5 μ m point resolution)
- very low material budget (0.1X%)
- Dissipated power (vertex) (<50mW/cm²)
- Radiation level NIEL (<4 $\times 10^{10}$ neq cm⁻²/yr)
- Radiation level TID (<200 Gy/yr)
- Barrel fine grained calorimeter
- Compact Forward calorimeter

FCC-hh Reference Detector

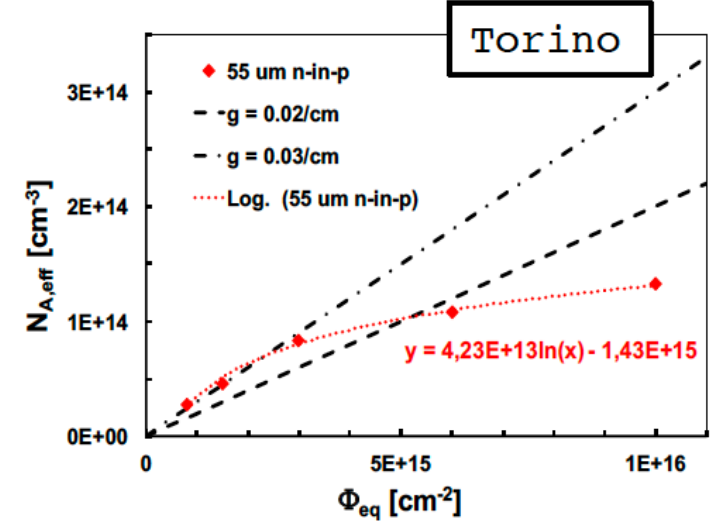
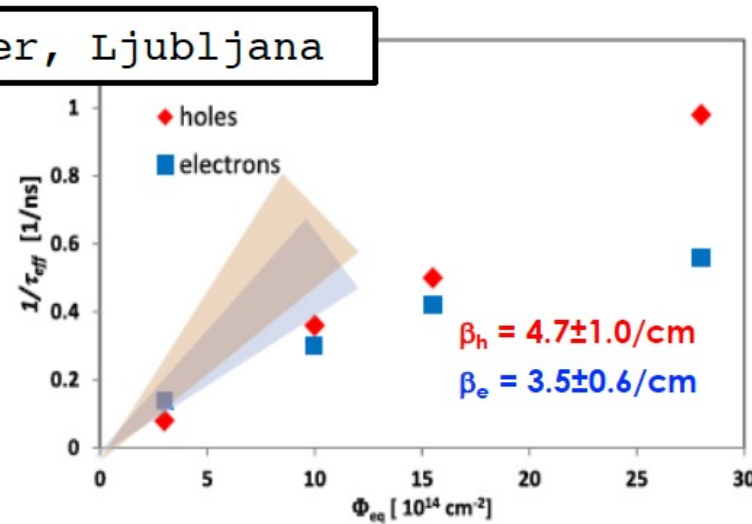
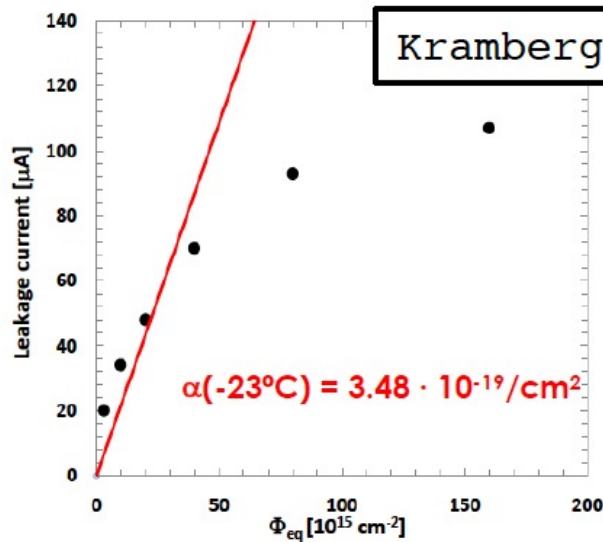
- 4T, 10m solenoid
- Forward solenoids
- Silicon tracker
- Barrel ECAL LAr
- Barrel HCAL Fe/Sci
- Endcap HCAL/ECAL LAr
- Forward HCAL/ECAL LAr



50m length, 20m diameter
similar to size of ATLAS

Silicon for the FCC-hh

about 400m² of silicon.



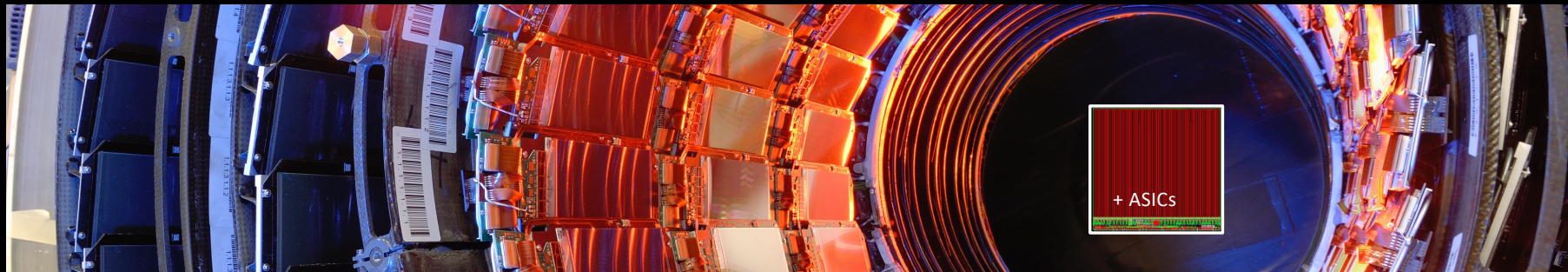
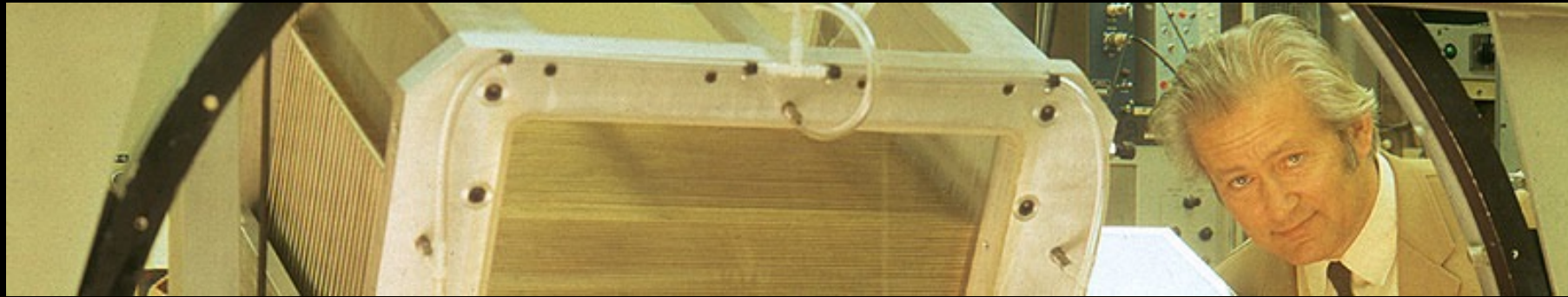
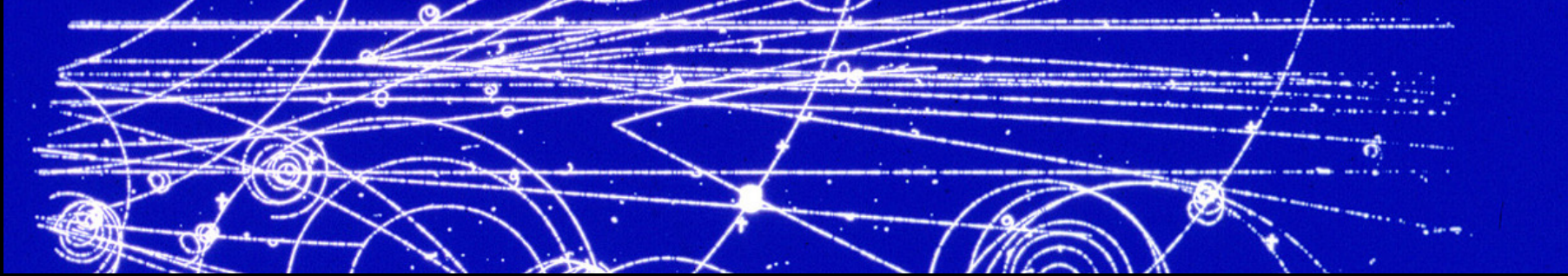
Dark current saturation
 $I = aV\phi$
 a from linear to logarithmic

Trapping probability saturation
 $1/\tau_{eff} = b\phi$
 b from linear to logarithmic

Acceptor creation saturation
 $N_{A,eff} = g c \phi$
 gc from linear to logarithmic

Good news! Silicon behaves better than expected at 1E16 – 1E17 n/cm²

Perspective

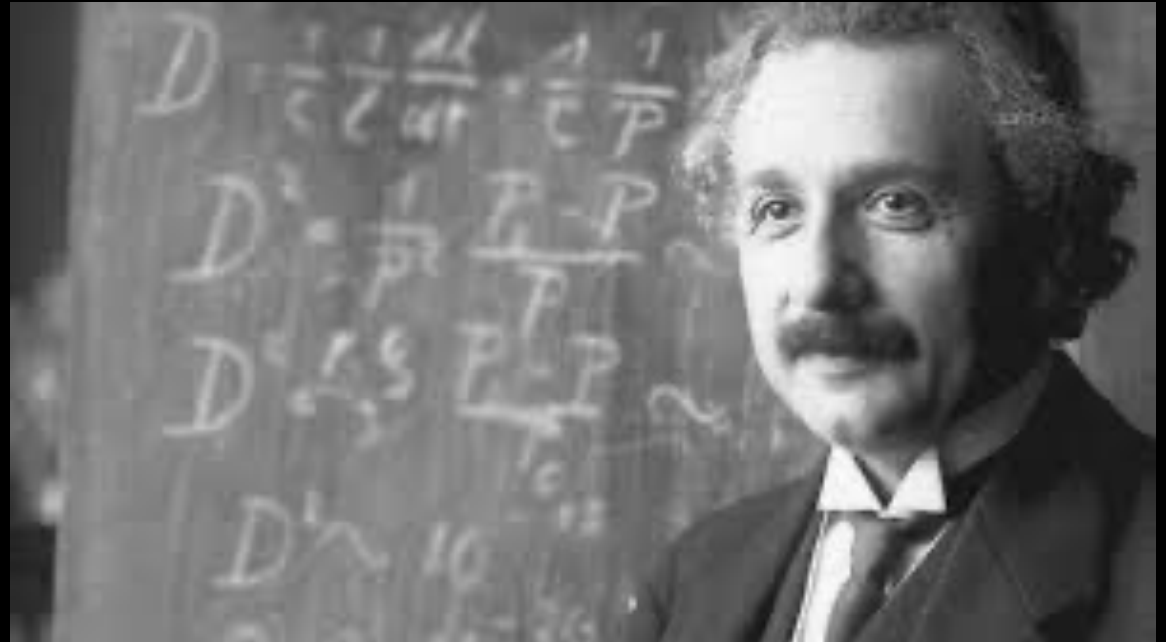


Conclusions

Imagination is more important than knowledge.

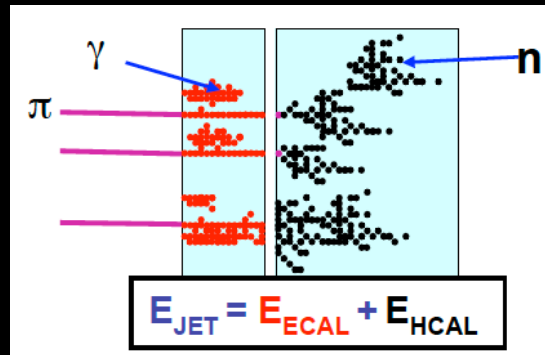
For knowledge is limited, whereas imagination embraces the entire world, stimulating progress, giving birth to evolution.

Albert Einstein, What Life Means to Einstein (1924)

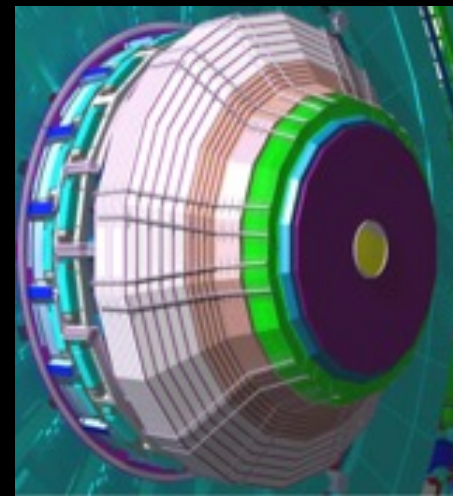
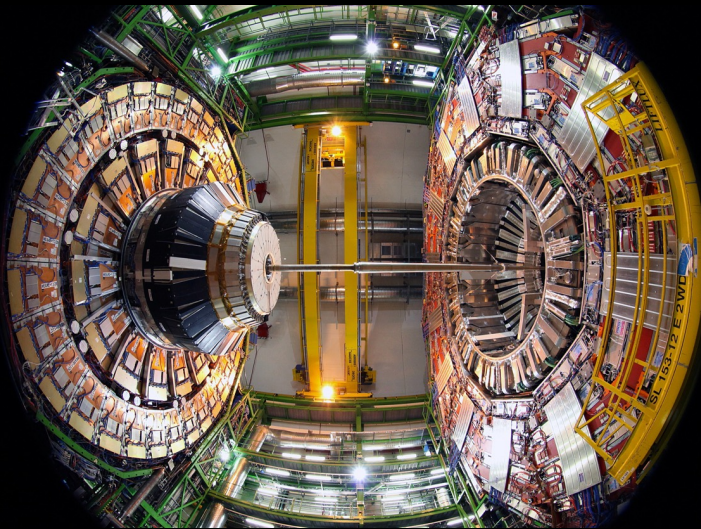
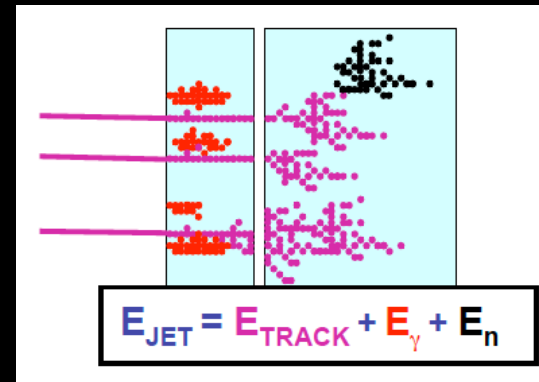


Imaging 5-D Calorimetry

- Standard calorimetry



- Particle Flow calorimetry

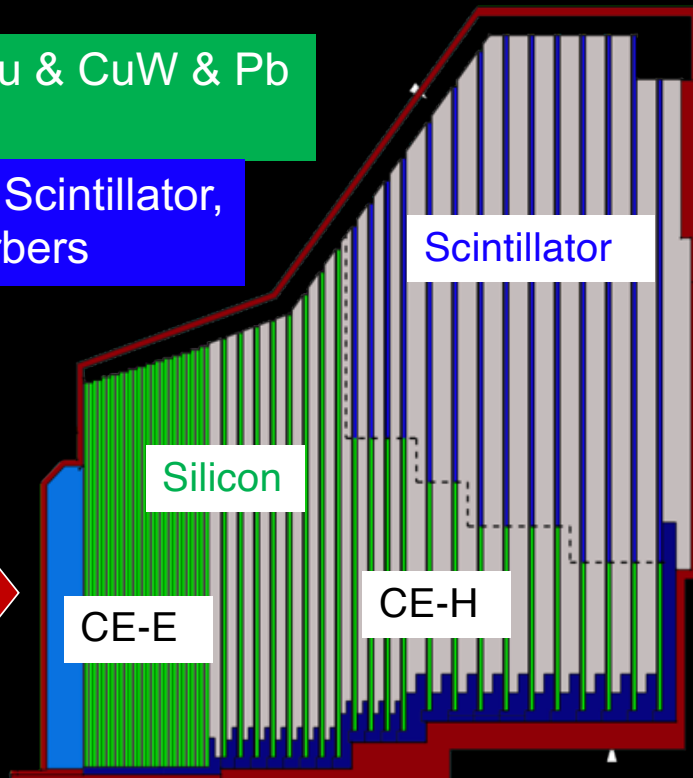


- High Granularity Calorimeter Replacing existing CMS endcap pre-shower, electromagnetic and hadronic calorimeter at HL-LHC
- Extremely challenging:
 - Fluence up to 10^{16} n/cm²
 - Dose up to 200 Mrad
 - -30°C

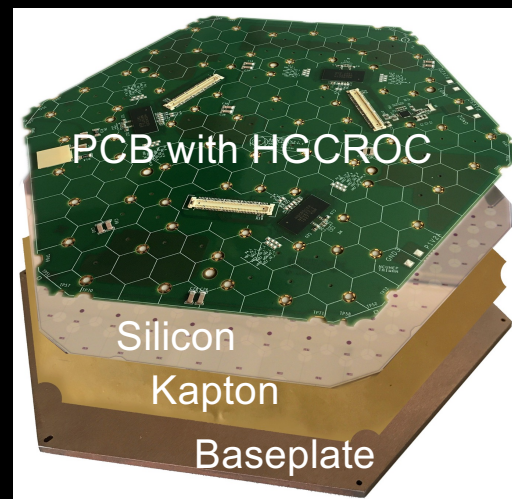
CMS High Granularity CALorimeter

CE-E: Si, Cu & CuW & Pb absorbers

CE-H: Si & Scintillator, Steel absorbers



Silicon sampling calorimeter

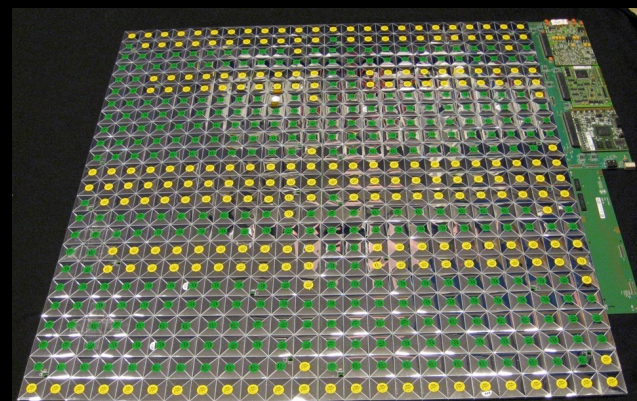


- HGCROC electronics both for SiPM and silicon (OMEGA)
 - Measures charge and time (TOA)
- Trigger data from ASICs fed through concentrators to the back-end system

R&D
ILC

ILC
CLIC, CepC
FCC

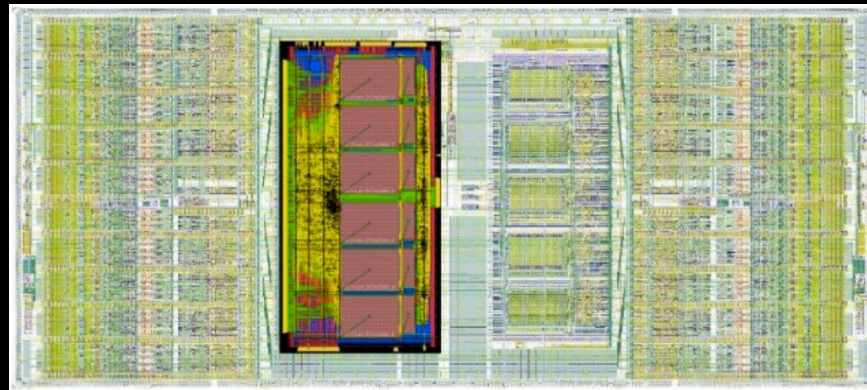
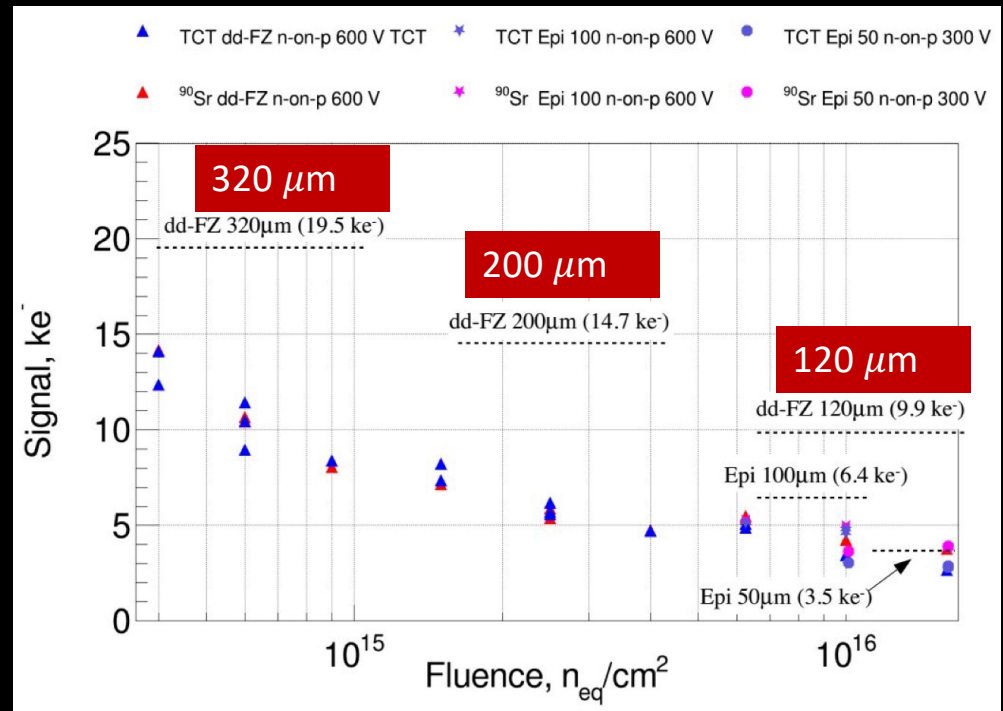
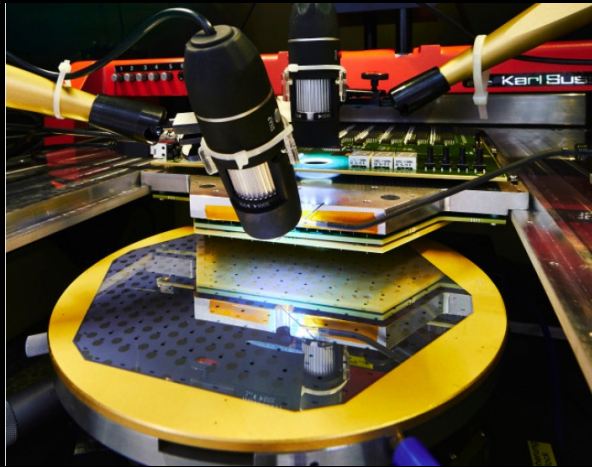
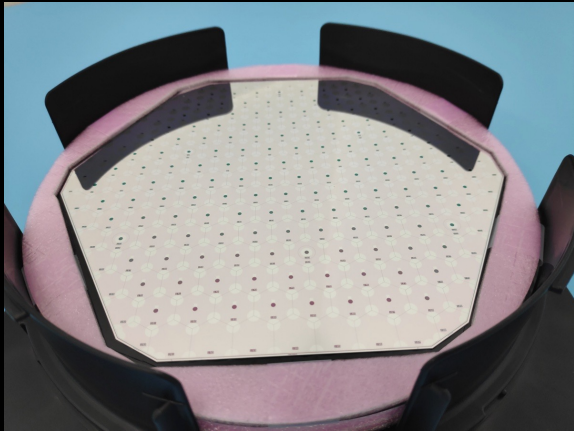
- Silicon: 620 m², 30K modules, 6M channels, 0.5/1 cm² cell size
- Scintillator: 400 m², 4K boards, 240k channels, 4-30 cm² size



Scintillator tiles with on-tile SiPM readout

CMS HGICAL

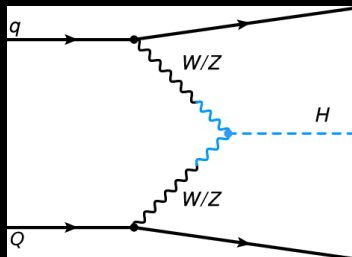
- 8" prototype sensor (HPK) p-type silicon



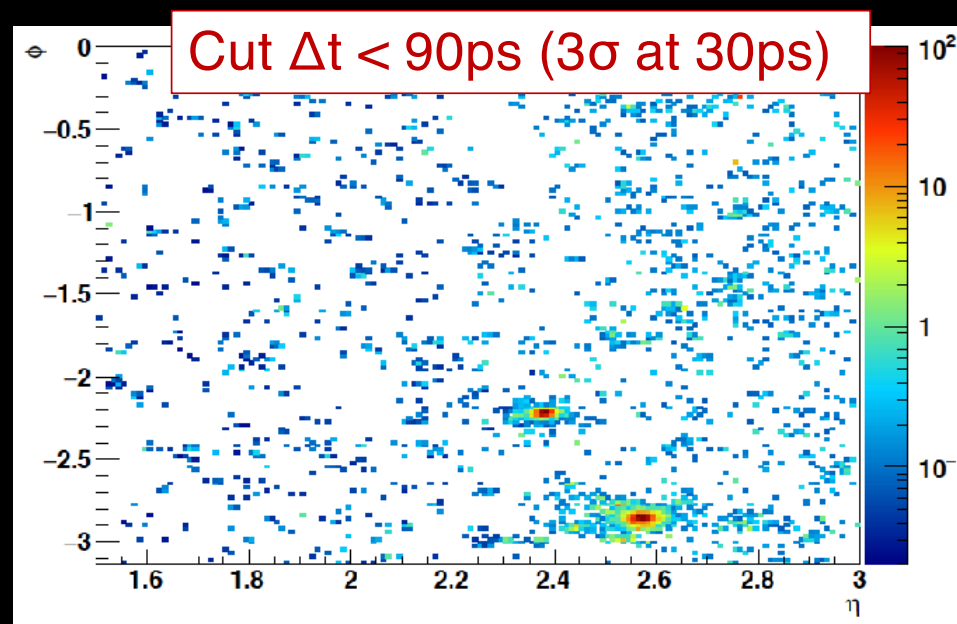
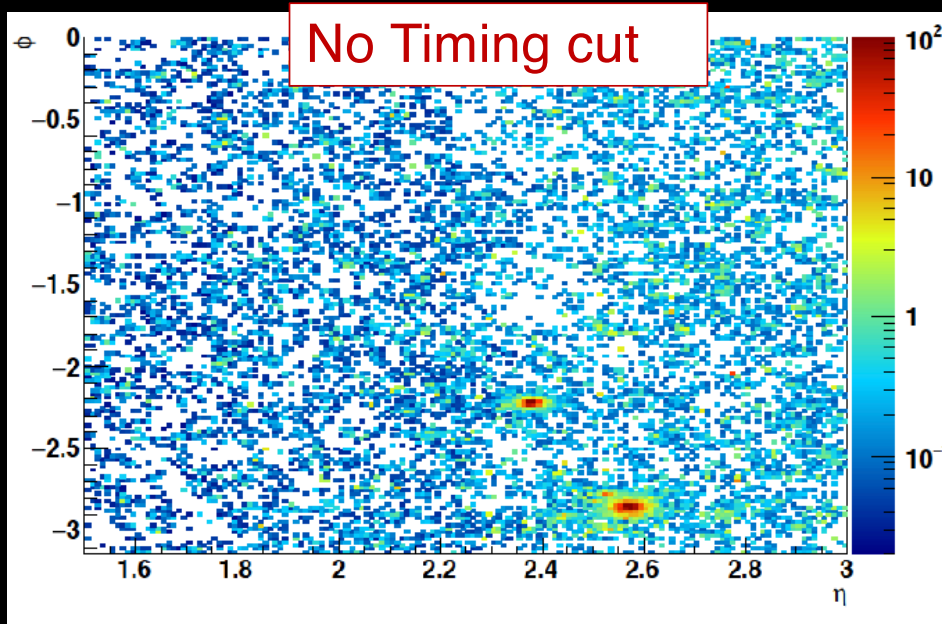
HGICAL FE electronics requirements:

- *Low noise* (<2500e)
- *high dynamic range* (0.2fC -10pC)
- *Timing to tens of picoseconds.*
- *Radiation tolerant*
- *<20mW per channel*

HGCAL 5D Power

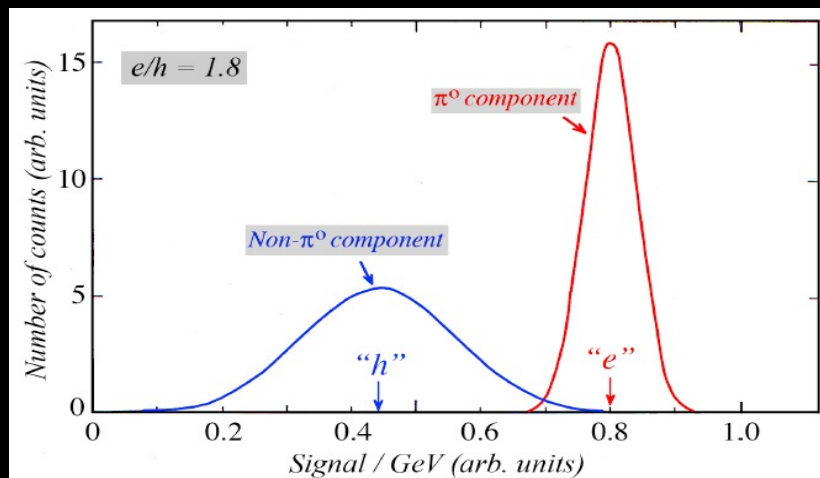


Vector Boson Fusion ($H \rightarrow \gamma\gamma$) event with one photon and one VBF jet in the same quadrant



- Cells with $Q > 12$ fC projected to the front face of the endcap calorimeter.
- Identify high-energy clusters, then make timing cut to retain hits of interest

DUAL readout calorimetry



- What if we could measure the two components separately and apply a separate scale factors to achieve compensation ?

- The response to the “hadronic” portion of a hadronic shower gives a lower response limiting hadronic calorimeter performance
- Many calorimeters tried to boost the non π^0 component – Compensating calorimeters:
 - uranium (D0 and ZEUS)

Is this just a DREAM?

<http://www.phys.ttu.edu/~dream/links/links.html>

RD52

Dual Readout

- Hadronic component: slowly moving protons and ions
- EM component: relativistic electrons.
- Relativistic particles can emit Cherenkov radiation.

$$\frac{d^2N}{dx d\lambda} = \frac{2\pi\alpha z^2}{\lambda^2} \left(1 - \frac{1}{\beta^2 n^2(\lambda)} \right) \cdot$$

- Measure EM component with Transparent material (high n)
 - Quartz
 - Clear plastic fibers
 - Crystals like BGO, PbWO4

C

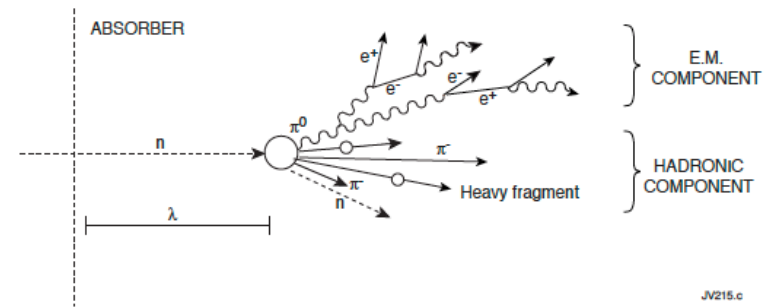
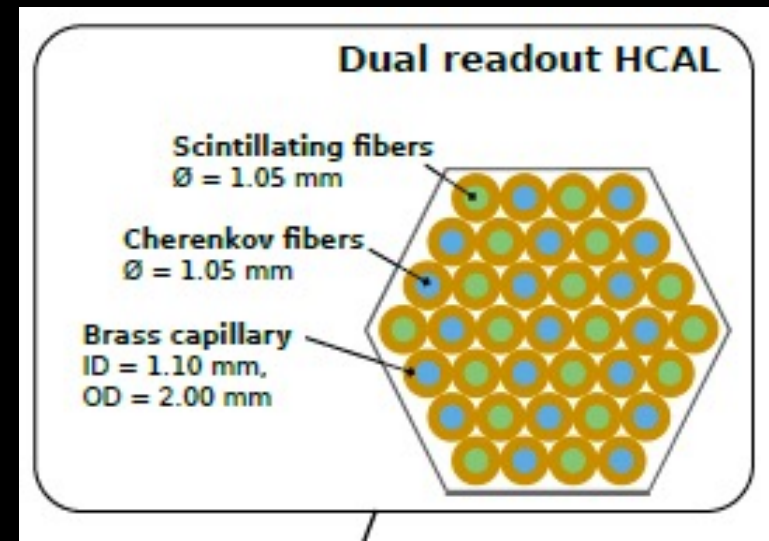


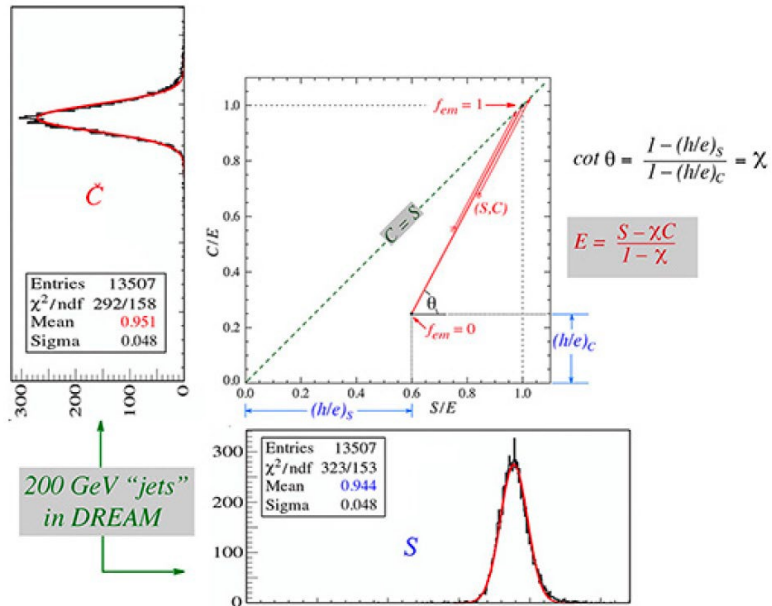
Fig. 9: Schematic of development of hadronic showers.



- Measure entire energy deposit with:
 - Plastic scintillator (sensitivity to neutrons)
 - Crystals like BGO, PbWO4

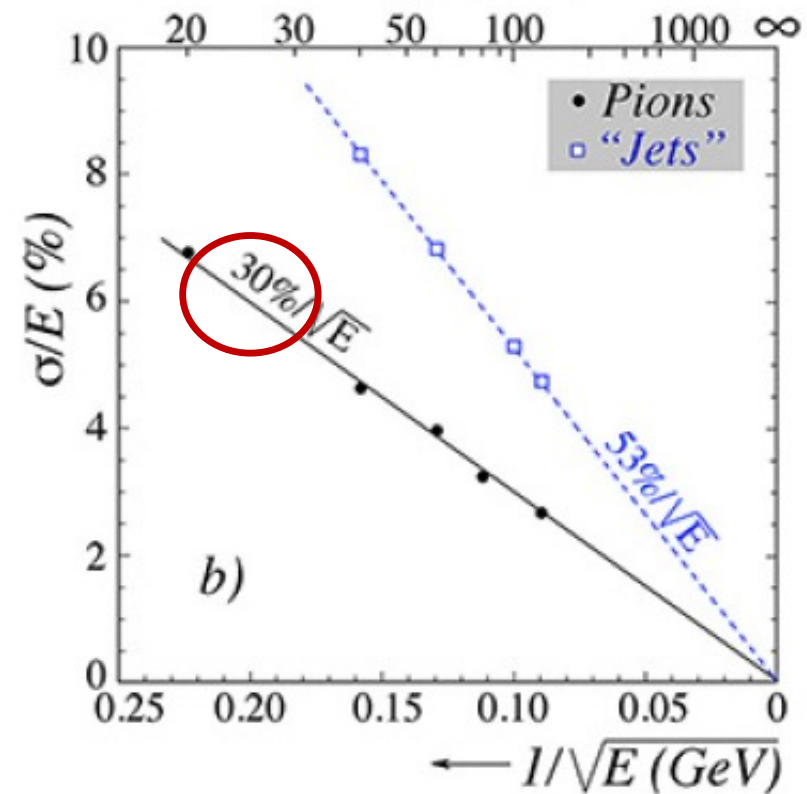
S

DREAM/RD52



$$S = E \left[f_{\text{em}} + \frac{1}{(e/h)_S} (1 - f_{\text{em}}) \right]$$

$$C = E \left[f_{\text{em}} + \frac{1}{(e/h)_C} (1 - f_{\text{em}}) \right]$$



┆ 2.5 mm ┆
┆ 4 mm ┆

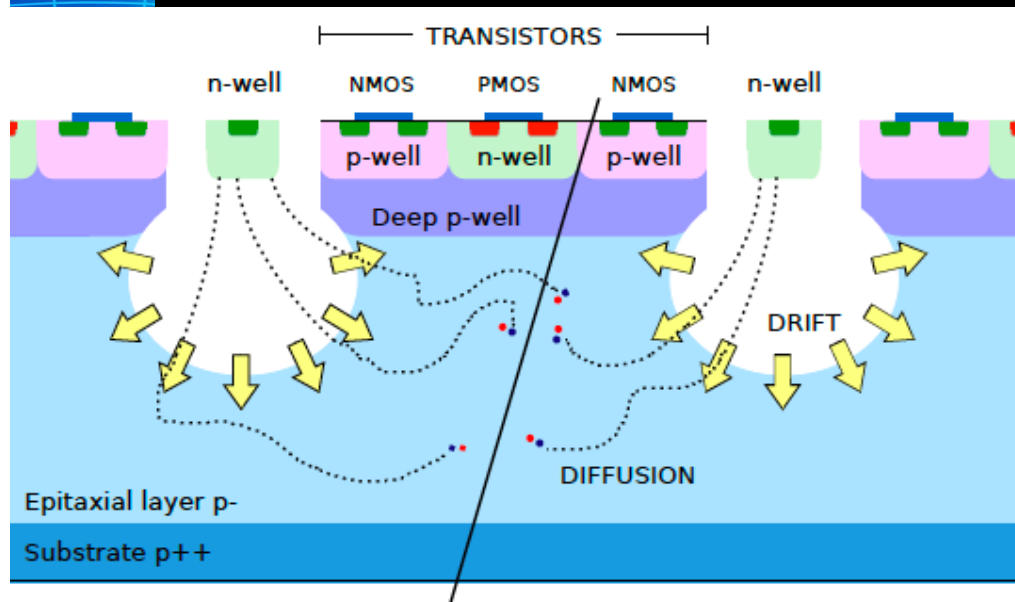
Separate readouts for scintillating and clear fibers

Useful References

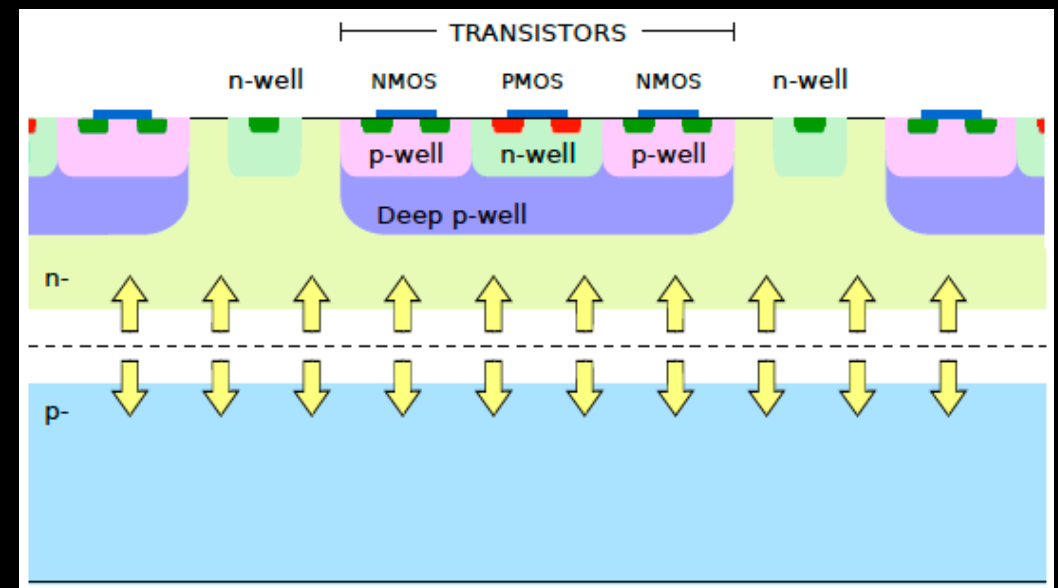
- Passage of Particles through Matter;
(<http://pdg.lbl.gov/2019/reviews/rpp2018-rev-passage-particles-matter.pdf>)

TowerJazz 180nm MALTA sensor

- Small collection electrode (few μm .)
- Small input capacitance ($<3\text{fF}$) allows for fast & low-power FE
- High S/N for a depletion depth of $\sim 20\ \mu\text{m}$
- To ensure full lateral depletion, uniform n-implant in the epi layer (modified process)



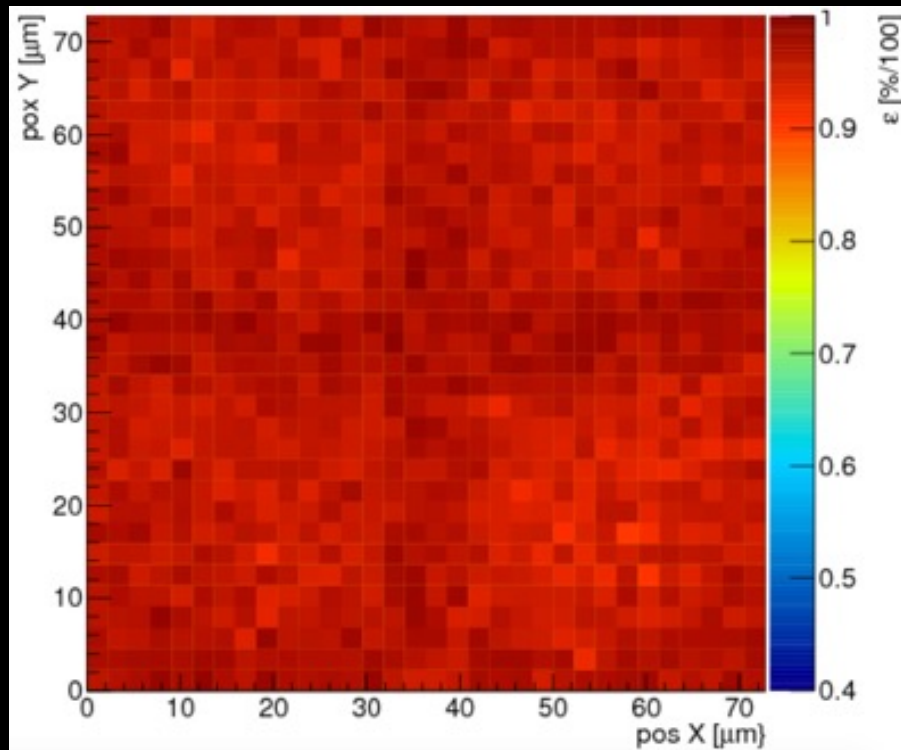
Standard Process



Modified Process: TowerJazz 180nm MALTA sensor
W. Snoeys et al. DOI 10.1016/j.nima.2017.07.046

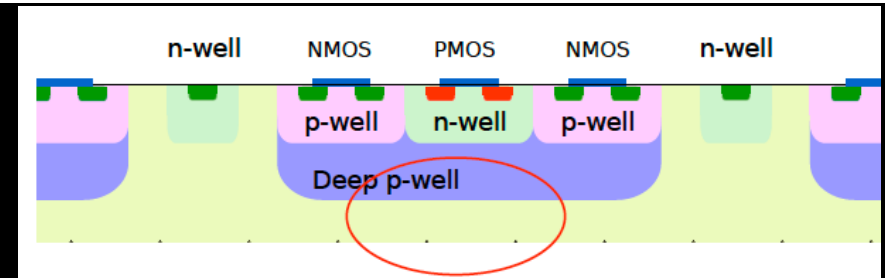
Radiation Hardness

- Unirradiated @ 250e⁻ threshold 2x2 pixel at 36 μm pitch

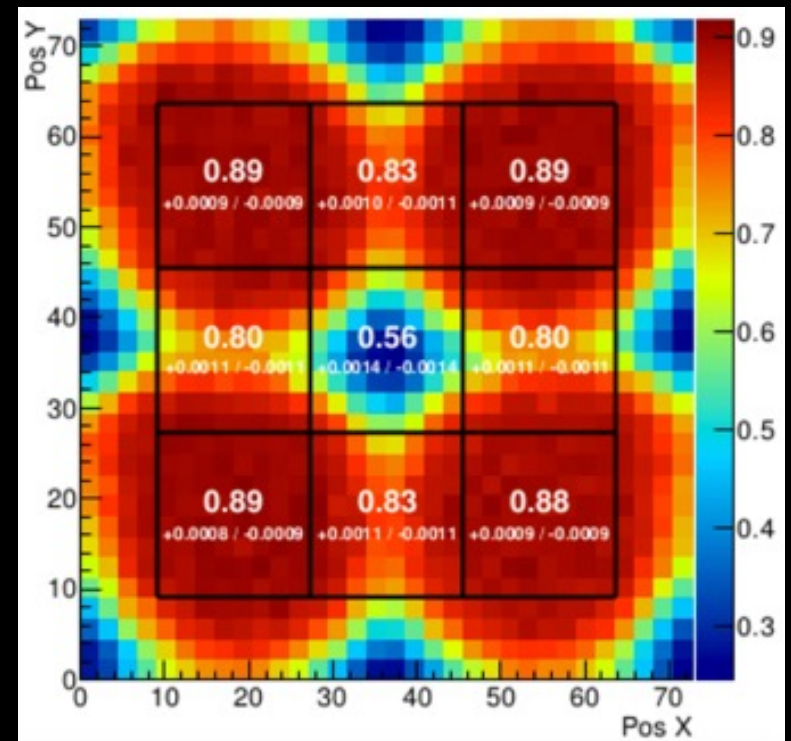


5/25/22

D. Bortoletto, Lecture 2

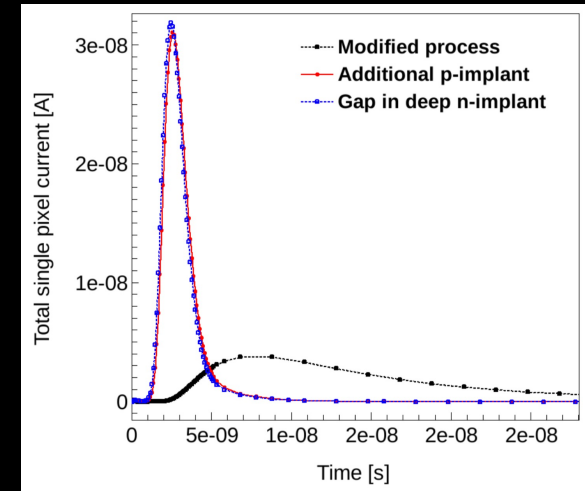
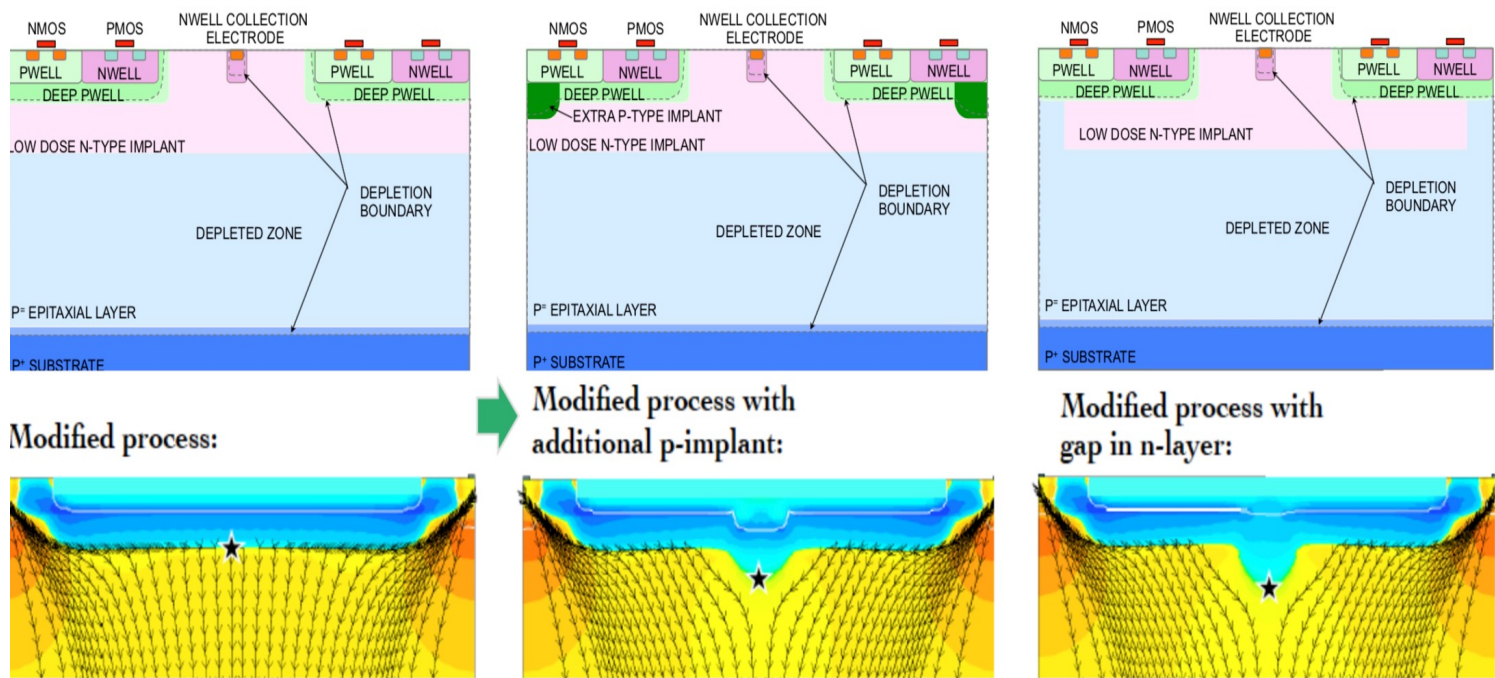


- Irradiated 10¹⁵n/cm² @ 350e⁻ threshold 2x2 pixel at 36 μm pitch



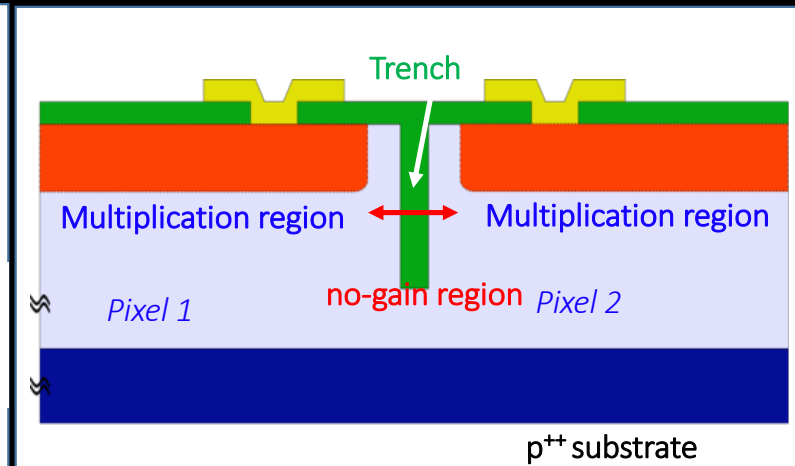
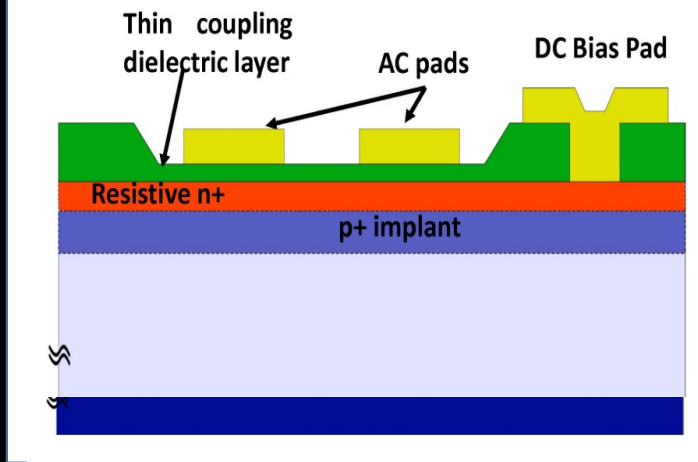
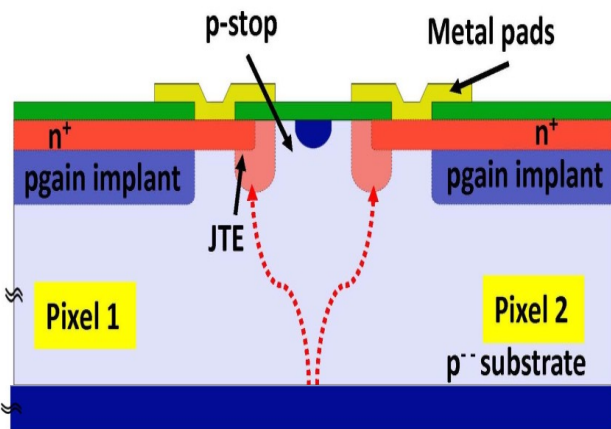
MINIMALTA

- Special layouts for deep p and n wells to optimize field configuration and charge collection
- Increase lateral field near pixel edge to “focus” charge to collection electrode



Electrostatic potential, streamlines and electric field minimum (*):

4 D tracking



LGADS

AC LGADS

Trench Isolated

- n++-implant more resistive

- p-stop & JTE replaced by a trench

- These are just examples
- Many other ideas under development
- Timing info essential for future colliders

*Deep Trenches
< 1 um*